



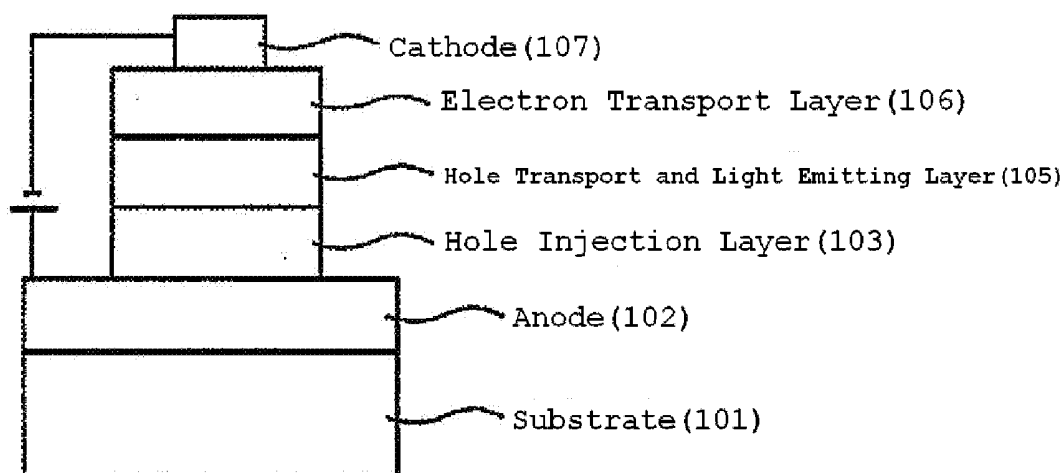
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Bae et al.(10) **Pub. No.: US 2011/0168992 A1**(43) **Pub. Date: Jul. 14, 2011**(54) **NOVEL COMPOUND, METHOD FOR
PREPARING SAME AND ORGANIC
ELECTRONIC DEVICE USING SAME**(30) **Foreign Application Priority Data**

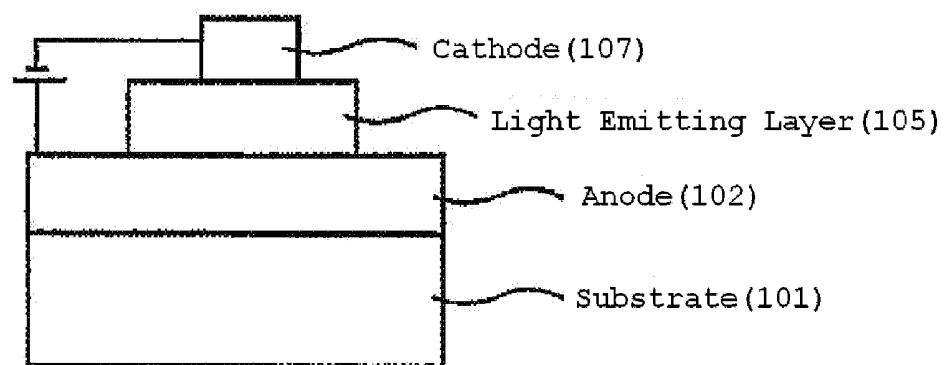
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Publication Classification(76) Inventors: **Jae-Soon Bae**, Daejeon
Metropolitan City (KR); **Ji-Eun
Kim**, Daejeon Metropolitan City
(KR); **Jeung-Gon Kim**, Daejeon
Metropolitan City (KR); **Jun-Gi
Jang**, Daejeon Metropolitan City
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C07D 307/92 (2006.01)(52) **U.S. Cl. 257/40; 549/43; 548/311.4; 548/440;
544/180; 546/101; 549/458; 549/42; 257/E51.041**(57) **ABSTRACT**

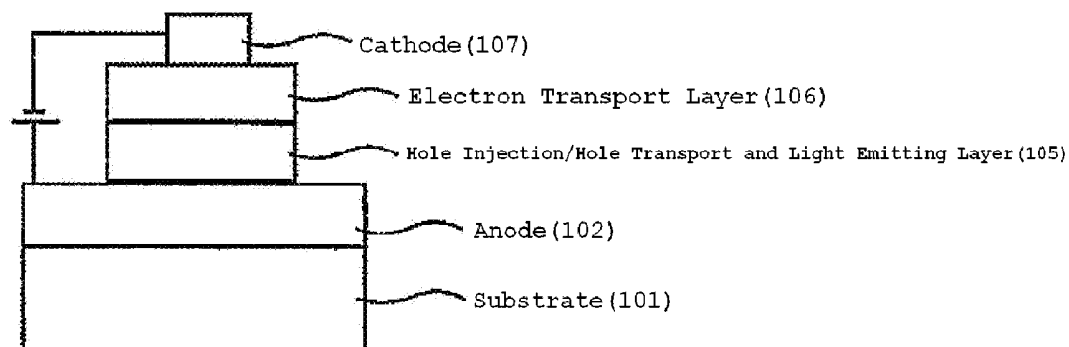
The present invention relates to a novel compound, a method for manufacturing the same, and an organic electronic device using the same, and the novel compound according to the present invention may act as a hole injection, hole transport, electron injection and transport, or light emitting material in an organic light emitting device and an organic electronic device, and the device according to the present invention shows excellent properties in terms of efficiency, a driving voltage, and stability.

(21) Appl. No.: **13/120,380**(22) PCT Filed: **Sep. 23, 2009**(86) PCT No.: **PCT/KR09/05431**§ 371 (c)(1),
(2), (4) Date: **Mar. 22, 2011**

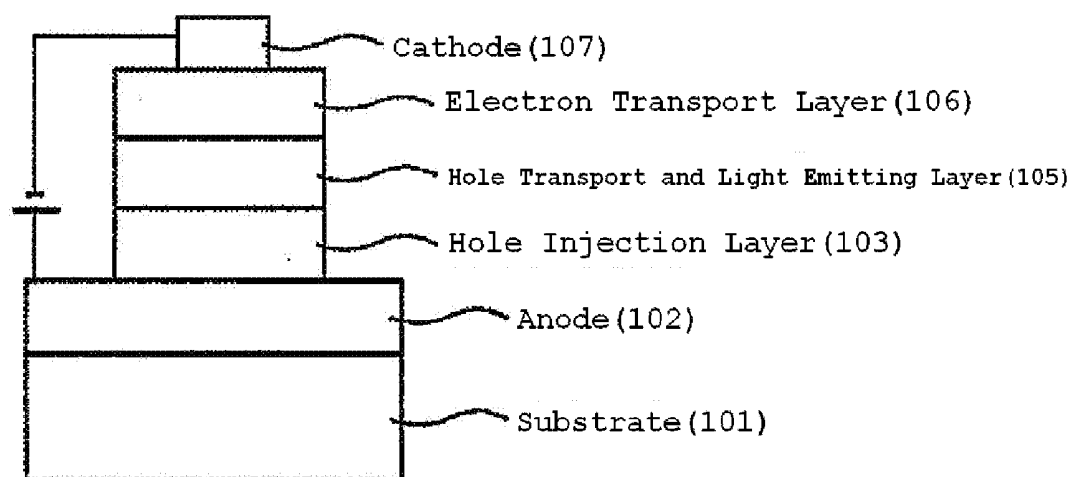
[Figure 1]



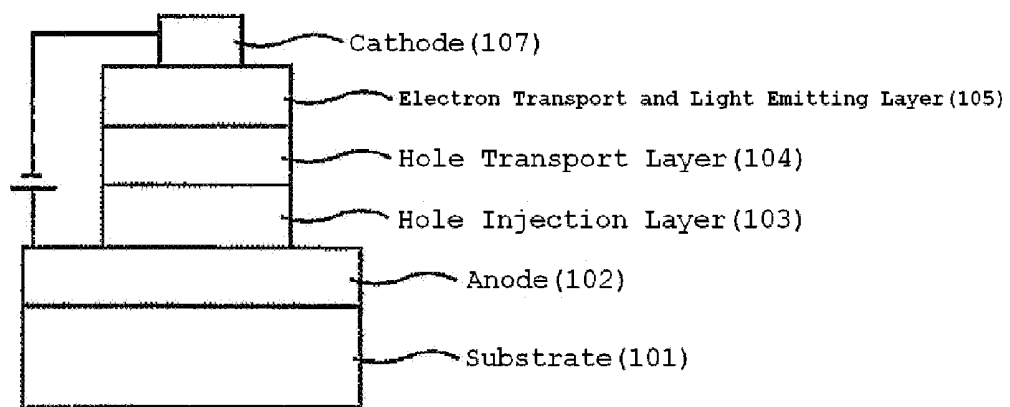
[Figure 2]



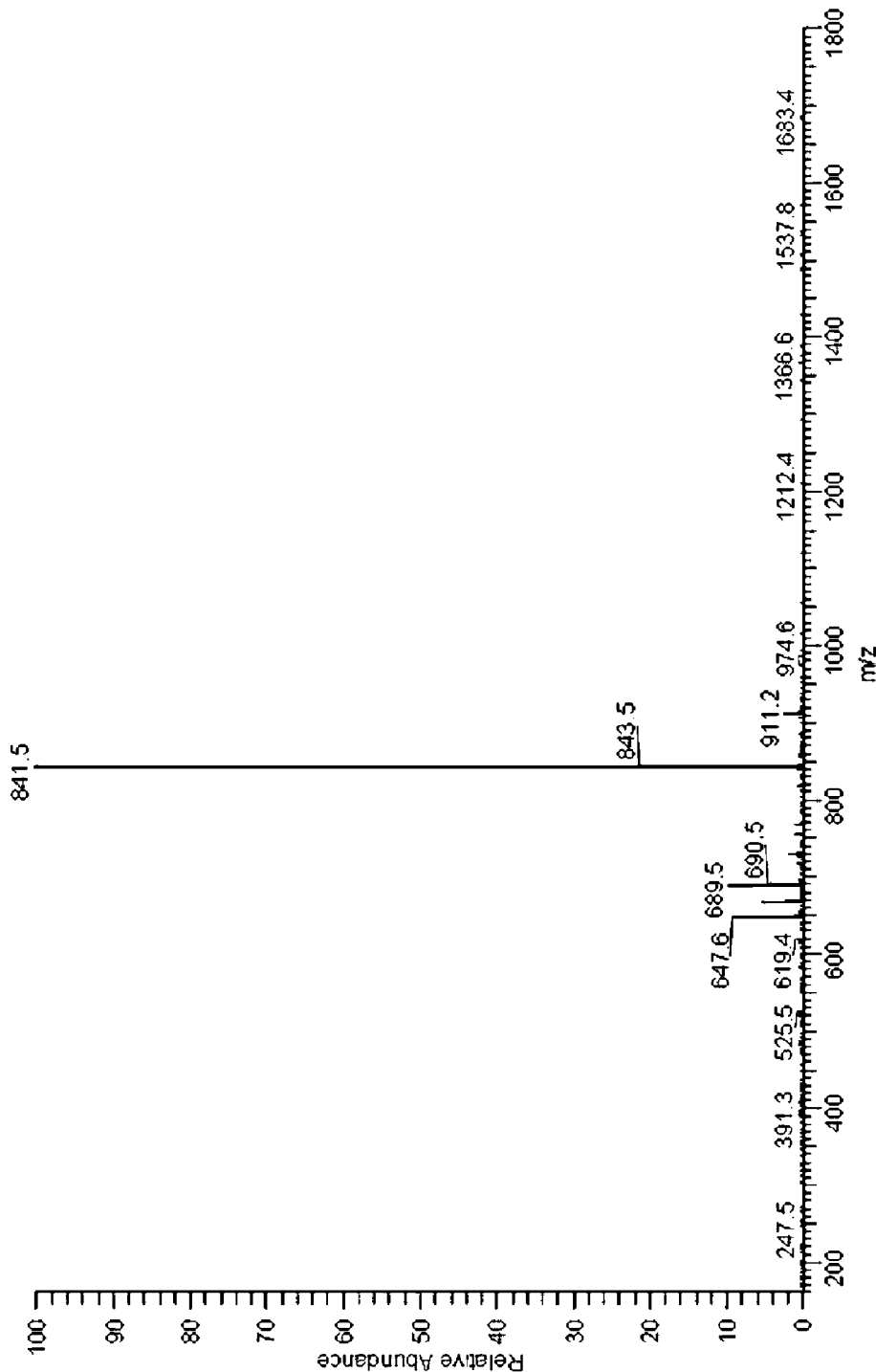
[Figure 3]



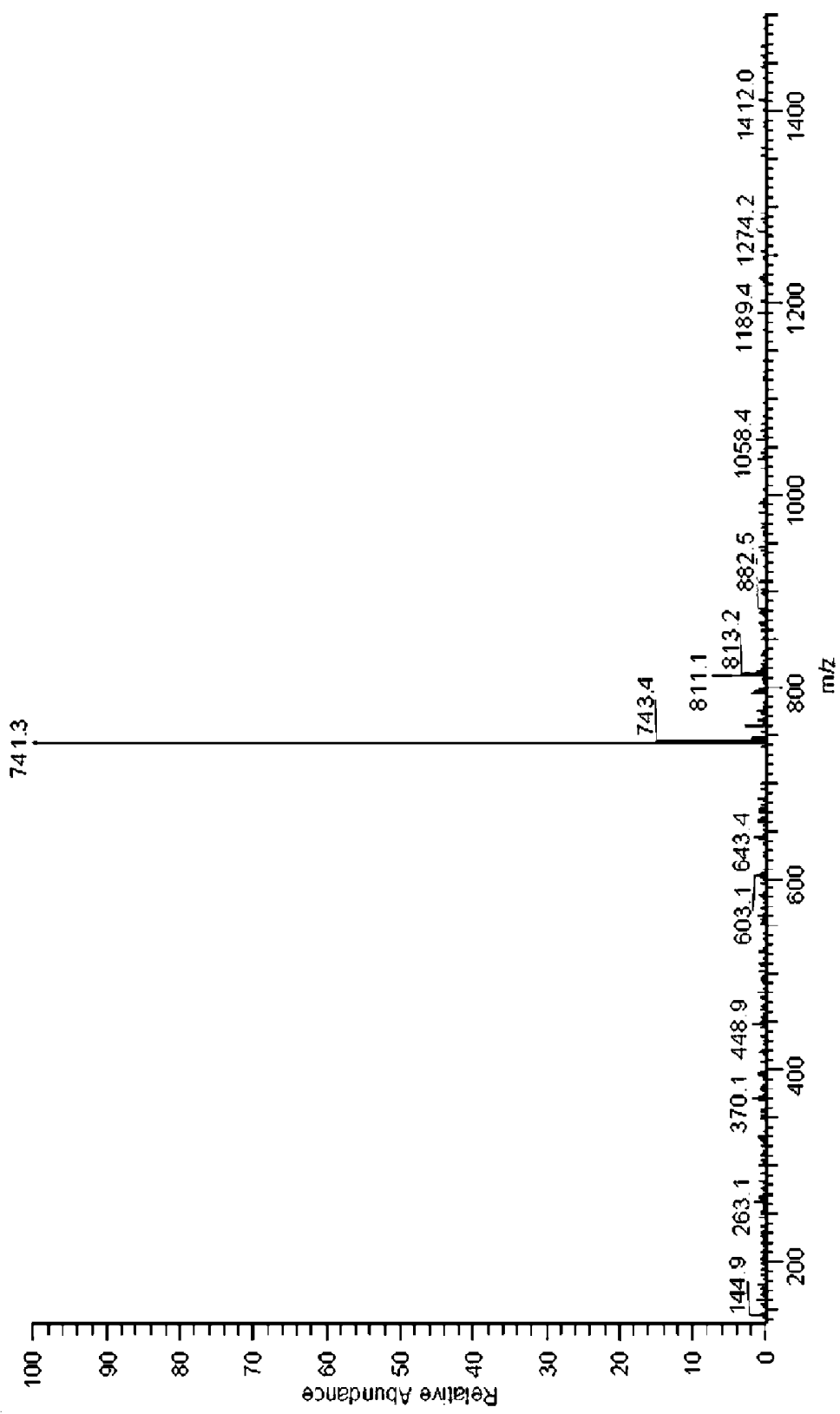
[Figure 4]



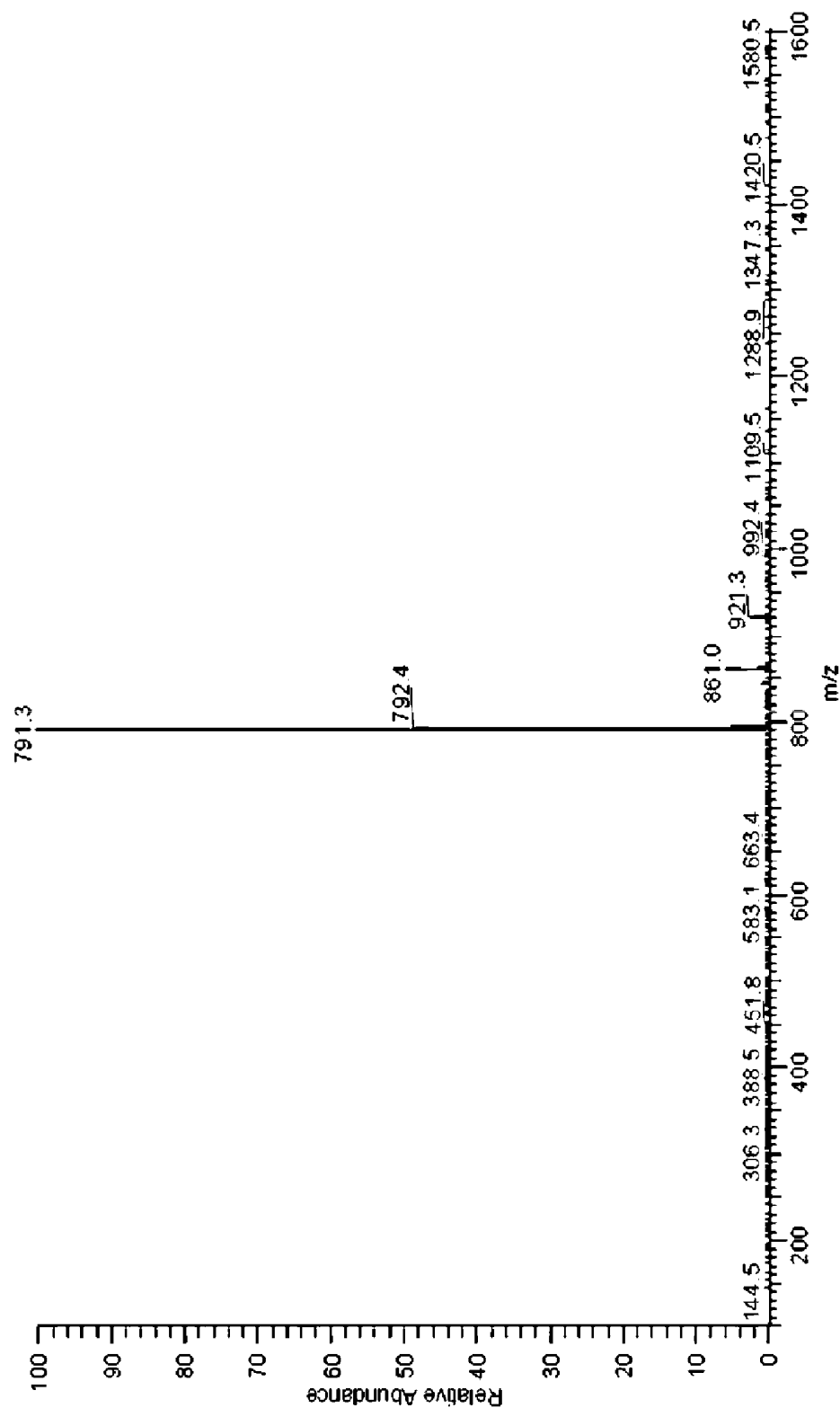
[Figure 5]



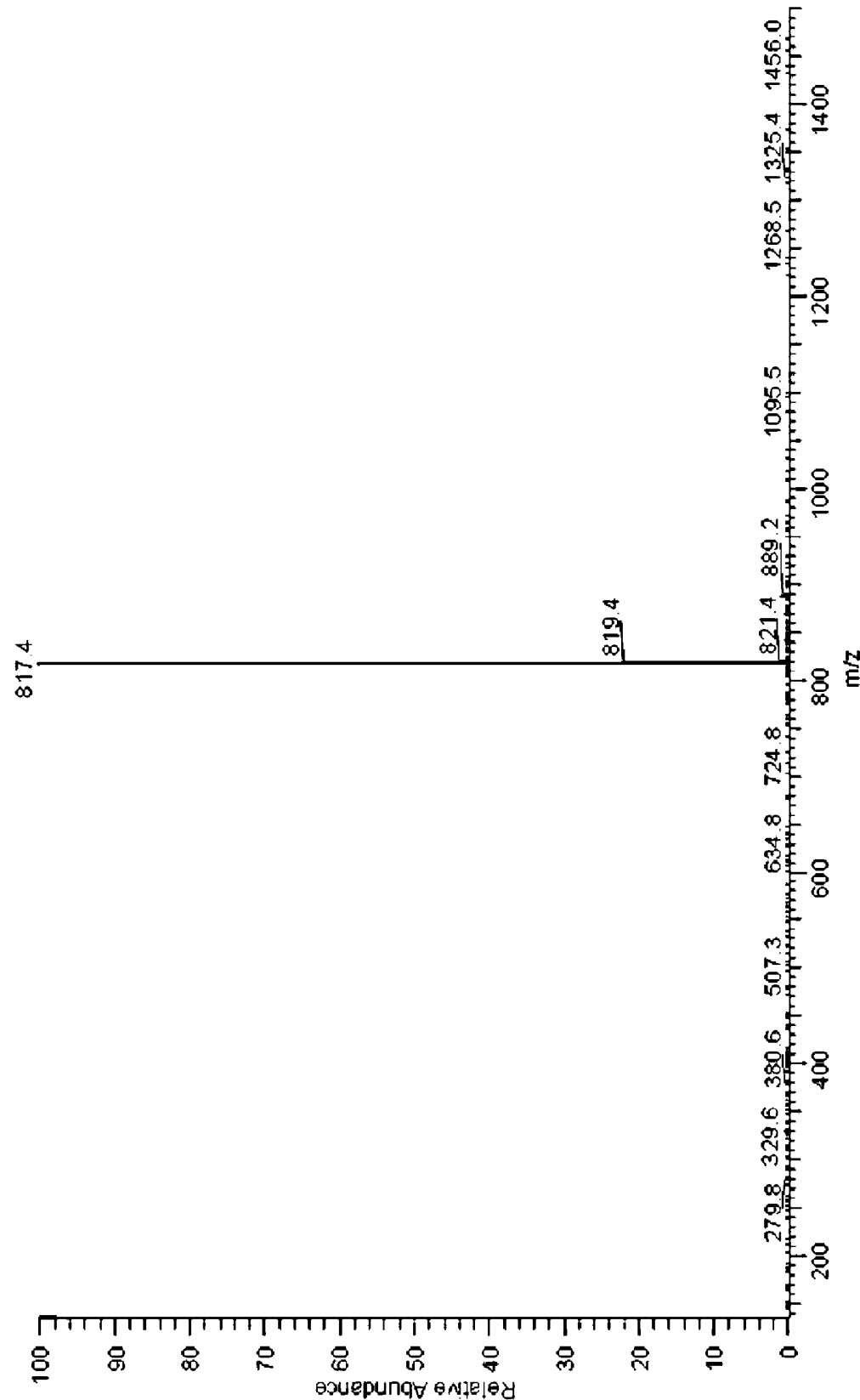
[Figure 6]



[Figure 7]



[Figure 8]



NOVEL COMPOUND, METHOD FOR PREPARING SAME AND ORGANIC ELECTRONIC DEVICE USING SAME

TECHNICAL FIELD

[0001] The present invention relates to a novel compound, a method for manufacturing the same, and an organic electronic device using the same. This application claims priority from Korean Patent Application No. 10-2008-0093440 filed on Sep. 23, 2008 in the KIPO, the disclosure of which is incorporated herein by reference in its entirety.

BACKGROUND ART

[0002] An organic electronic device means a device that requires exchanging of electric charges between electrodes using holes and/or electrons and organic materials. The organic electronic device may be largely divided into the following categories according to an operation principle. First, there is an electronic device in which an exciton is formed in an organic material layer by a photon that flows from an external light source to the device, the exciton is separated into electrons and holes, and the electrons and the holes are transferred to the other electrodes and used as a current source (voltage source). Second, there is an electronic device in which holes and/or electrons are injected into an organic material semiconductor forming an interface in respects to the electrode by applying a voltage or a current to two or more electrodes, and the device is operated by the injected electrons and holes.

[0003] As examples of the organic electronic device, there are an organic light emitting device, an organic solar cell, an organic photoconductor (OPC), an organic transistor and the like, and all of them require a hole injection or transport material, an electron injection or transport material or a light emitting material in order to drive the device. Hereinafter, an organic light emitting device will be mainly described in detail. However, in the organic electronic devices, all of the hole injection or transport material, an electron injection or transport material or a light emitting material are operated on the basis of the similar principle.

[0004] In general, an organic light emitting phenomenon means a phenomenon that converts electric energy into light energy by using an organic material. The organic light emitting device using the organic light emitting phenomenon has a structure which generally includes an anode, a cathode, and an organic layer that is disposed between them. Herein, most organic layers have a multilayered structure that includes different materials in order to increase efficiency and stability of the organic light emitting device, and for example, it may include a hole injection layer, a hole transport layer, a light emitting layer, an electron transport layer, an electron injection layer and the like. In the organic light emitting device structure, if a voltage is applied between two electrodes, holes are injected from an anode and electrons are injected from a cathode to the organic material layer, and when the injected holes and the electrons meet each other, an exciton is formed, and light is emitted when the exciton falls to a bottom state. It is known that this organic light emitting device has properties such as magnetic light emission, high brightness, high efficiency, low driving voltage, a wide viewing angle, high contrast, high speed response and the like.

[0005] In the organic light emitting device, the material that is used in the organic material layer may be classified into a

light emitting material and an electric charge material, for example, a hole injection material, a hole transport material, an electron transport material, an electron injection material according to a function thereof. In addition, the light emitting material may be classified into blue, green, and red light emitting materials and yellow and orange light emitting materials in order to realize better natural colors according to the emission color. Meanwhile, in the case of when only one material is used as a light emitting material, by interaction between molecules, there are problems in that the maximum light emitting wavelength moves to the long wavelength, the color purity is lowered, or efficiency of the device is lowered because of reduced effect of light emission. Therefore, in order to increase color purity and increase emission efficiency through transferring of energy, a host/dopant system may be used as the light emitting material.

[0006] In order to sufficiently show excellent properties of the above organic light emitting device, a material constituting the organic material layer in the device, for example, the hole injection material, the hole transport material, the light emitting material, the electron transport material, the electron injection material and the like should be supported by stable and efficient materials. However, the development of a stable and efficient organic material layer material for organic light emitting devices has not yet been made. Therefore, there is a demand for developing a novel material, and the demand for developing the novel material is similarly applied to the other organic electronic device.

DISCLOSURE

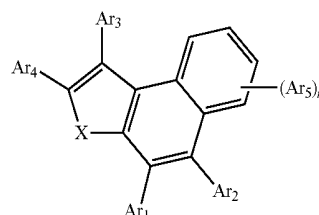
Technical Problem

[0007] Therefore, the present inventors have synthesized a novel compound, and found the fact that when the compound acts as a hole injection, hole transport, electron injection and transport, or light emitting material in an organic electronic device, an interfacial property and electric charge transport ability are excellent, thereby accomplishing the present invention.

[0008] It is an object of the present invention to provide a novel compound that is capable of being used in an organic electronic device, a method for manufacturing the same, and an organic electronic device using the same.

Technical Solution

[0009] In order to accomplish the above object, a first aspect of the present invention provides the following novel compound.



[Formula 1]

[0010] wherein the substituent group will be described in detail below.

[0011] In order to accomplish the above object, a second aspect of the present invention provides an organic electronic device using the above novel compound.

Advantageous Effects

[0012] A novel compound according to the present invention may act as a hole injection, hole transport, electron injection and transport, or light emitting material in an organic light emitting device and an organic electronic device, and the device according to the present invention shows excellent properties in terms of efficiency, a driving voltage, and stability.

DESCRIPTION OF DRAWINGS

[0013] FIGS. 1 to 4 are views that illustrate a structure of an organic light emitting device that is capable of being applied to the present invention;

[0014] FIG. 5 is a mass spectrum of the compound 1-2-9;

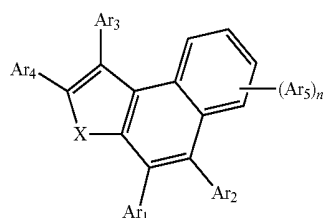
[0015] FIG. 6 is a mass spectrum of the compound 1-3-1;

[0016] FIG. 7 is a mass spectrum of the compound 1-1-7; and

[0017] FIG. 8 is a mass spectrum of the compound 1-2-10.

BEST MODE

[0018] The novel compound according to the present invention is characterized in that it is represented by the following Formula 1:



[Formula 1]

[0019] wherein X is S or O,

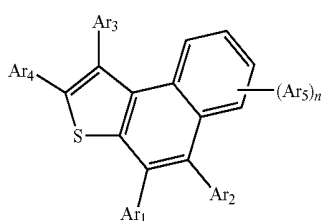
[0020] n is an integer in the range of 0 to 4,

[0021] Ar₁, Ar₂, Ar₃, Ar₄, and Ar₅ may be the same as or different from each other, and each independently selected from the group consisting of hydrogen atom; heavy hydrogen atom; halogen group; amino group; nitrile group; nitro group; amide group; C₁~C₃₀ alkoxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₃₀ aryloxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₁~C₃₀ alkylthioxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group,

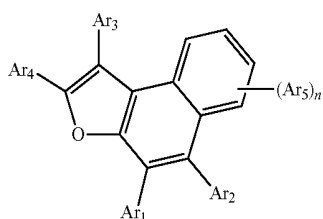
nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₃₀ arylthioxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₁~C₃₀ alkylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ aralkylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ aryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, substituted or unsubstituted C₁~C₃₀ alkylaminyl group, substituted or unsubstituted C₁~C₃₀ aralkylaminyl group, substituted or unsubstituted C₆~C₆₀ arylaminyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₃~C₆₀ heteroaryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₆~C₃₀ aryloxy group, C₁~C₃₀ alkylthioxy group, C₆~C₃₀ arylthioxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, substituted or unsubstituted C₁~C₃₀ alkylaminyl group, substituted or unsubstituted C₁~C₃₀ aralkylaminyl group, substituted or unsubstituted C₆~C₆₀ arylaminyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; boron group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; silyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group,

C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; and ester group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group, or may form an aliphatic, aromatic, aliphatic hetero or aromatic hetero condensed ring or a spiro bond in conjunction with an adjacent group.

[0022] In addition, it is preferable that the compound that is represented by Formula 1 according to the present invention is represented by the following Formula 2 or 3:



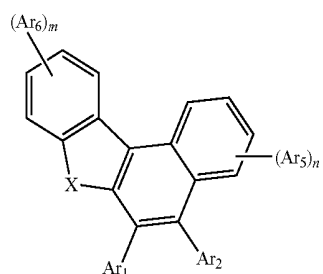
[Formula 2]



[Formula 3]

[0023] wherein, Ar₁ to Ar₅ and n are the same as those defined in Formula 1.

[0024] In addition, it is preferable that the compound that is represented by Formula 1 according to the present invention is represented by the following Formula 4:



[Formula 4]

[0025] wherein X is S or O,

[0026] m and n are each independently 0 to 4,

[0027] Ar₁, Ar₂, Ar₅ and Ar₆ and n are the same as definition of Ar₁ to Ar₅ of Formula 1.

[0028] In the compound that is represented by Formula 1, it is preferable that Ar₁ is C₆~C₆₀ aryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group,

nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₆~C₃₀ aryloxy group, C₁~C₃₀ alkylthioxy group, C₆~C₃₀ arylthioxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, substituted or unsubstituted C₁~C₃₀ alkylaminyl group, substituted or unsubstituted C₁~C₃₀ aralkylaminyl group, substituted or unsubstituted C₆~C₆₀ arylaminyl group, substituted or unsubstituted C₆~C₆₀ aryl group and substituted or unsubstituted C₃~C₆₀ heteroaryl group.

[0029] In addition, in the compound that is represented by Formula 1, it is preferable that Ar₁ is C₆~C₆₀ heteroaryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₆~C₃₀ aryloxy group, C₁~C₃₀ alkylthioxy group, C₆~C₃₀ arylthioxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, substituted or unsubstituted C₁~C₃₀ alkylaminyl group, substituted or unsubstituted C₁~C₃₀ aralkylaminyl group, substituted or unsubstituted C₆~C₆₀ arylaminyl group, substituted or unsubstituted C₆~C₆₀ aryl group and substituted or unsubstituted C₃~C₆₀ heteroaryl group.

[0030] In addition, in the compound that is represented by Formula 1, it is preferable that Ar₂ to Ar₅ may be the same as or different from each other, and each independently C₆~C₆₀ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₃₀ heteroaryl group.

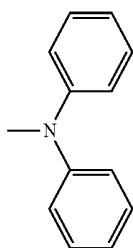
[0031] In addition, in the compound that is represented by Formula 1, it is preferable that Ar₂ to Ar₅ may be the same as or different from each other, and each independently C₆~C₆₀ aryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₆~C₃₀ aryloxy group, C₁~C₃₀ alkylthioxy group, C₆~C₃₀ arylthioxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, substituted or unsubstituted C₁~C₃₀ alkylaminyl group, substituted or unsubstituted C₁~C₃₀ aralkylaminyl group, substituted or unsubstituted C₆~C₆₀ arylaminyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group.

[0032] In addition, in the compound that is represented by Formula 1, it is preferable that Ar₂ to Ar₅ may be the same as or different from each other, and each independently C₃~C₆₀ heteroaryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₆~C₃₀ aryloxy group, C₁~C₃₀ alkylthioxy group, C₆~C₃₀ arylthioxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, substituted or unsubstituted C₁~C₃₀ alkylaminyl group, substituted or unsubstituted C₁~C₃₀ aralkylaminyl group, substituted or unsubstituted C₆~C₆₀ arylaminyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group.

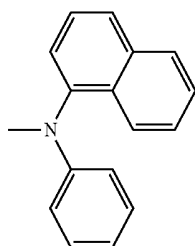
[0033] In addition, in the compound that is represented by Formulas 2 to 4, it is preferable that Ar₁ to Ar₆ may be the same as or different from each other, and each independently

selected from the group consisting of $C_6\sim C_{60}$ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, $C_1\sim C_{30}$ alkyl group, $C_2\sim C_{30}$ alkenyl group, $C_1\sim C_{30}$ alkoxy group, $C_3\sim C_{30}$ cycloalkyl group, $C_2\sim C_{30}$ heterocycloalkyl group, $C_6\sim C_{60}$ aryl group and $C_3\sim C_{30}$ heteroaryl group; $C_6\sim C_{60}$ aryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, $C_1\sim C_{30}$ alkyl group, $C_2\sim C_{30}$ alkenyl group, $C_1\sim C_{30}$ alkoxy group, $C_6\sim C_{30}$ aryloxy group, $C_1\sim C_{30}$ alkylthioxy group, $C_6\sim C_{30}$ arylthioxy group, $C_3\sim C_{30}$ cycloalkyl group, $C_2\sim C_{30}$ heterocycloalkyl group, substituted or unsubstituted $C_1\sim C_{30}$ alkylaminyl group, substituted or unsubstituted $C_1\sim C_{30}$ aralkylaminyl group, substituted or unsubstituted $C_6\sim C_{60}$ arylaminyl group, $C_6\sim C_{60}$ aryl group and $C_3\sim C_{60}$ heteroaryl group; and $C_3\sim C_{60}$ heteroaryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, $C_1\sim C_{30}$ alkyl group, $C_2\sim C_{30}$ alkenyl group, $C_1\sim C_{30}$ alkoxy group, $C_6\sim C_{30}$ aryloxy group, $C_1\sim C_{30}$ alkylthioxy group, $C_6\sim C_{30}$ arylthioxy group, $C_3\sim C_{30}$ cycloalkyl group, $C_2\sim C_{30}$ heterocycloalkyl group, substituted or unsubstituted $C_1\sim C_{30}$ alkylaminyl group, substituted or unsubstituted $C_1\sim C_{30}$ aralkylaminyl group, substituted or unsubstituted $C_6\sim C_{60}$ arylaminyl group, $C_6\sim C_{60}$ aryl group and $C_3\sim C_{60}$ heteroaryl group.

[0034] In Formula 1, the arylaminyl group is an amine group that is substituted by the above-mentioned aryl group, and is preferably the following groups but is not limited thereto.

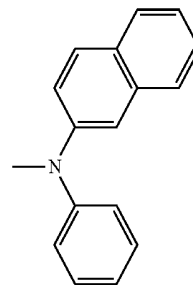


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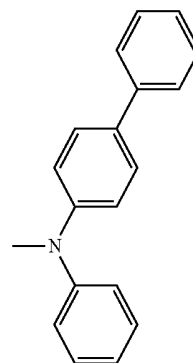


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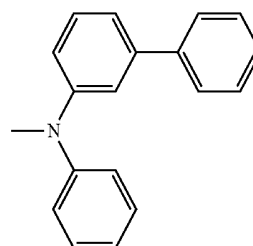
-continued



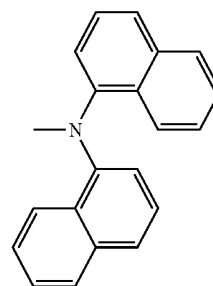
3



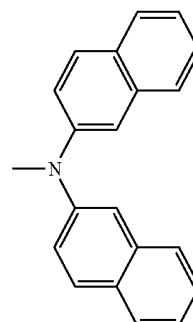
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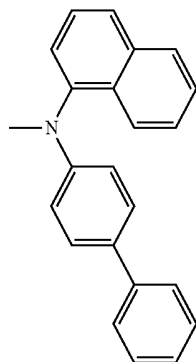


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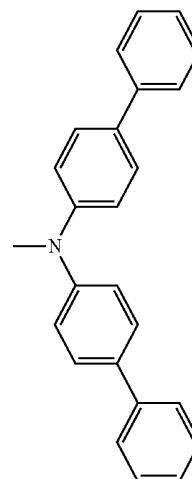
7

-continued

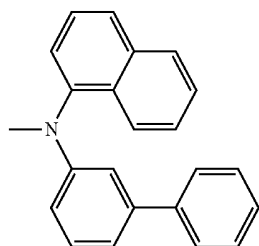


8

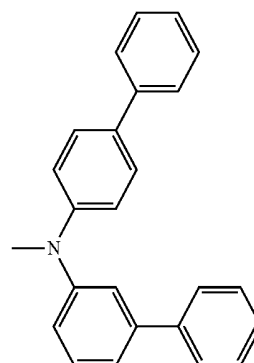
-continued



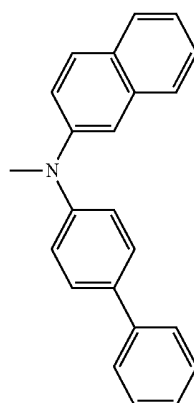
12



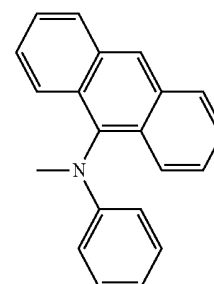
9



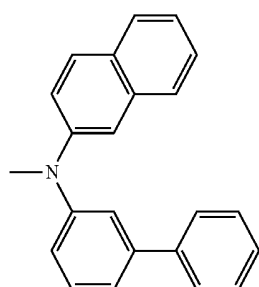
13



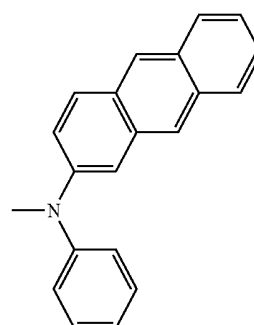
10



14

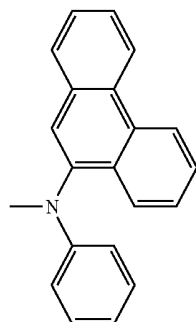


11

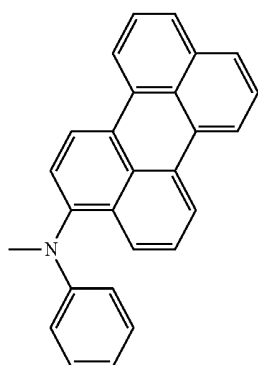


15

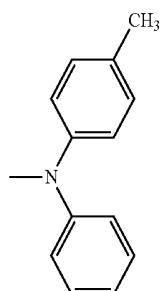
-continued



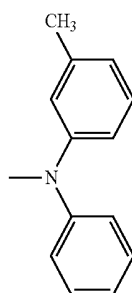
16



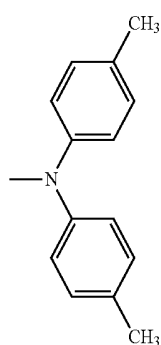
17



18

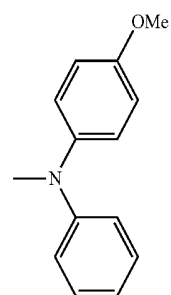


19

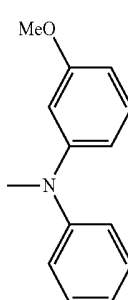


20

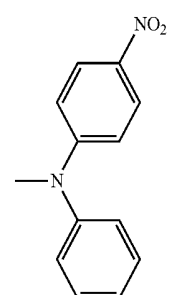
-continued



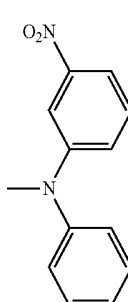
21



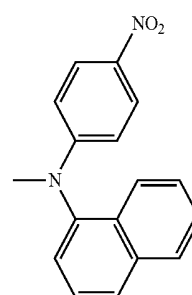
22



23

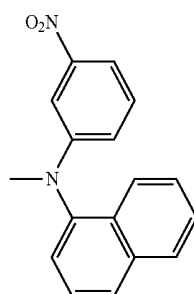


24

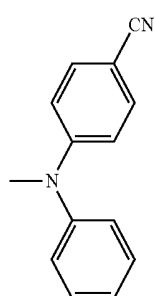


25

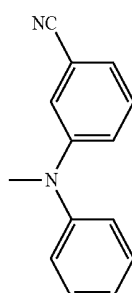
-continued



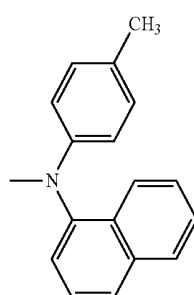
26



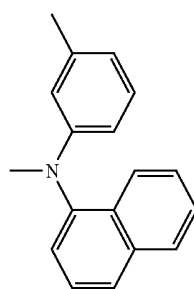
27



28

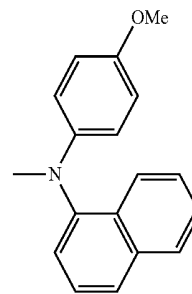


29

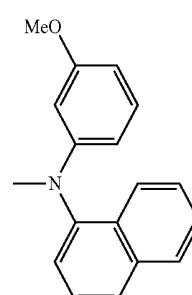


30

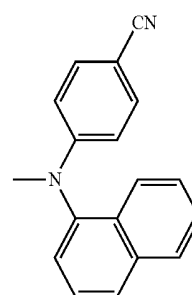
-continued



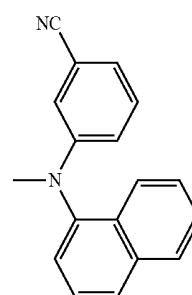
31



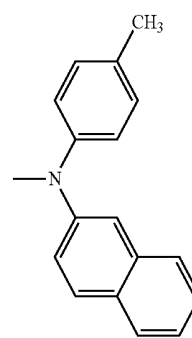
32



33

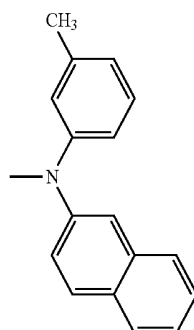


34



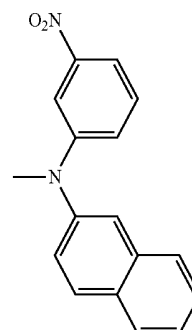
35

-continued

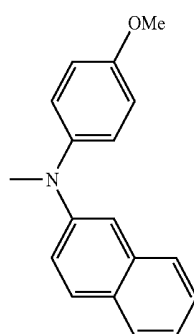


36

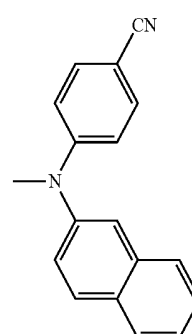
-continued



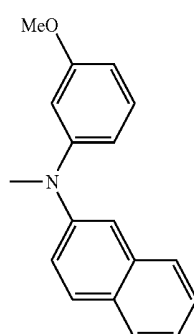
40



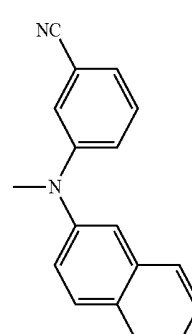
37



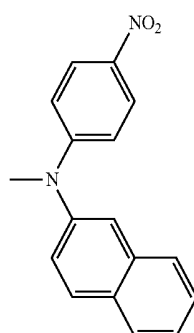
41



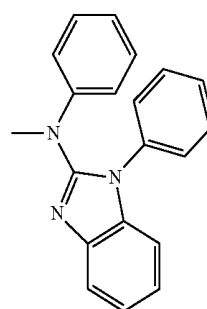
38



42

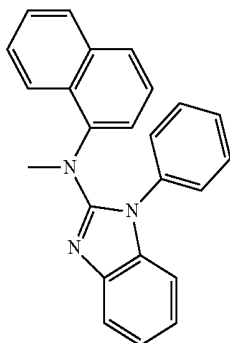


39



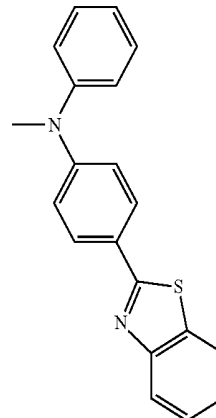
43

-continued

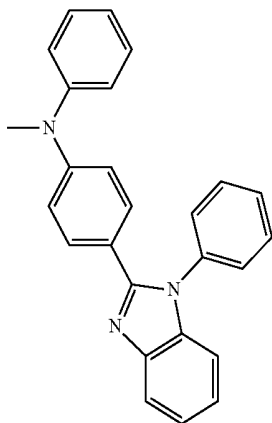


44

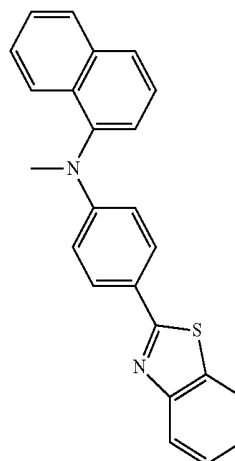
-continued



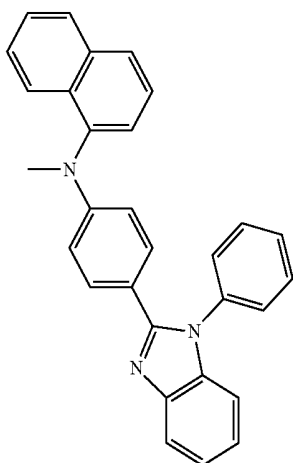
47



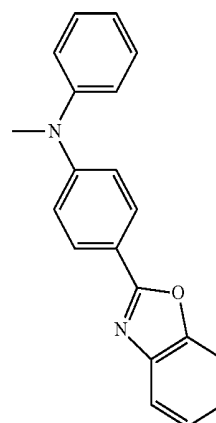
45



48

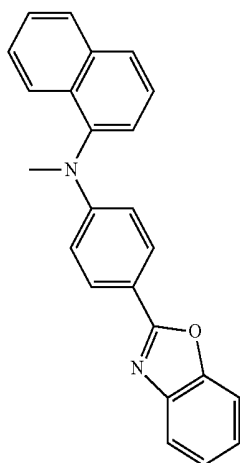


46



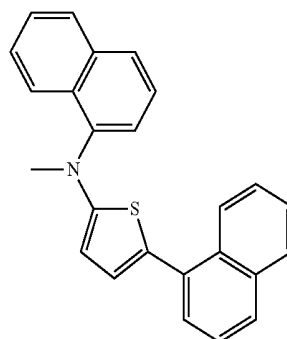
49

-continued

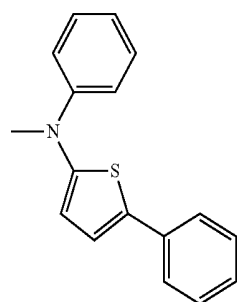


50

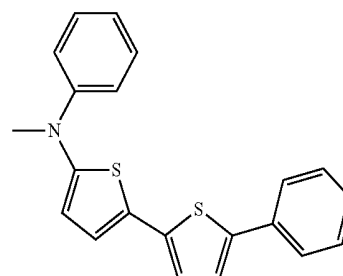
-continued



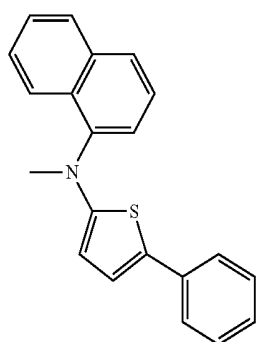
54



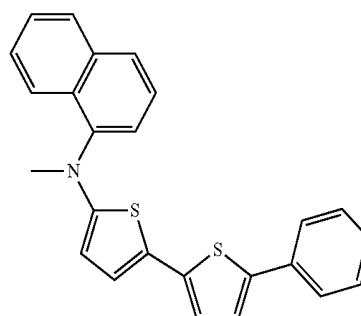
51



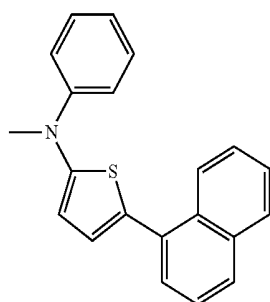
55



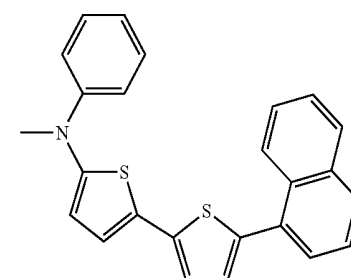
52



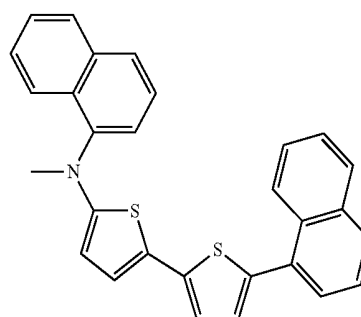
56



53

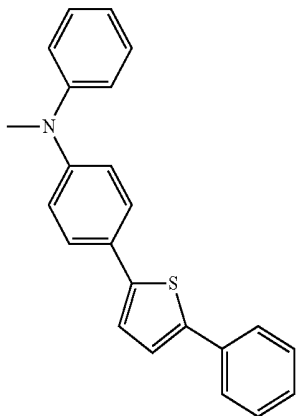


57



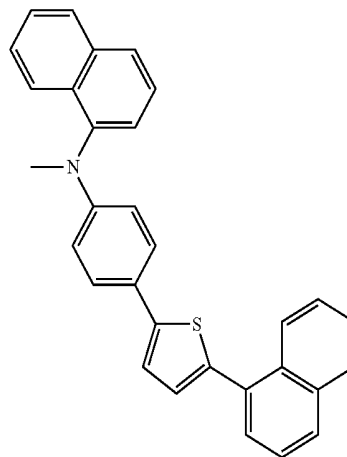
58

-continued

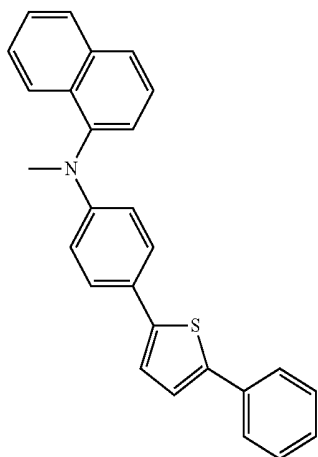


59

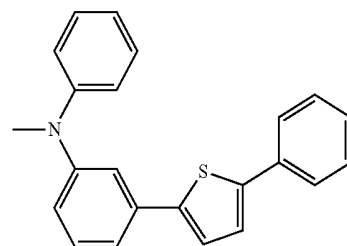
-continued



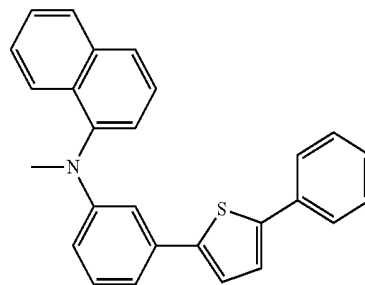
62



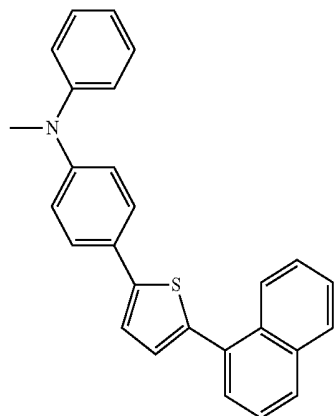
60



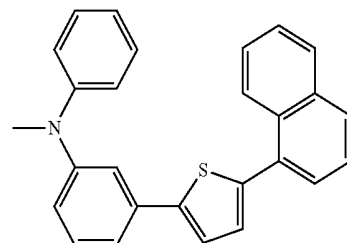
63



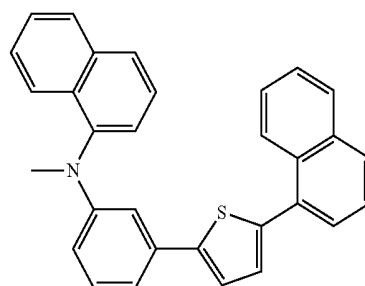
64



61

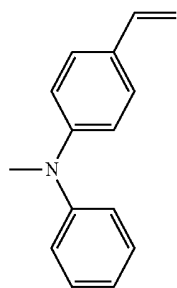


65

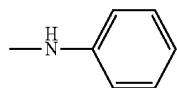


66

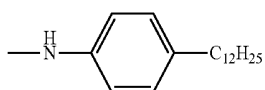
-continued



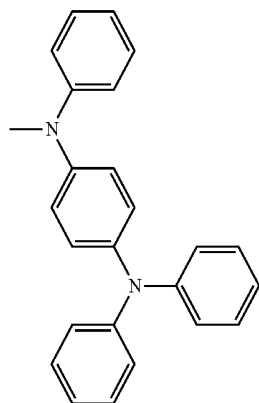
67



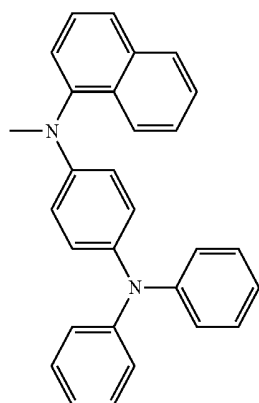
68



69

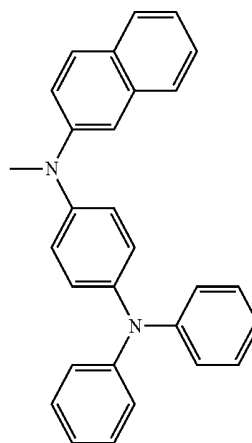


70

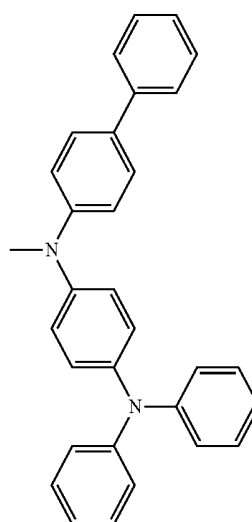


71

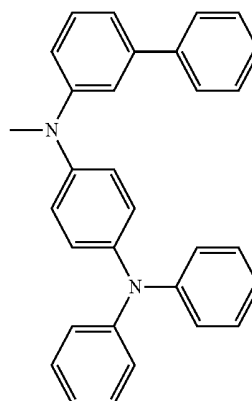
-continued



72

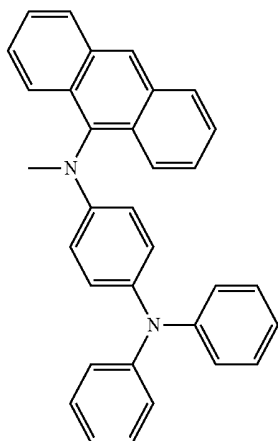


73



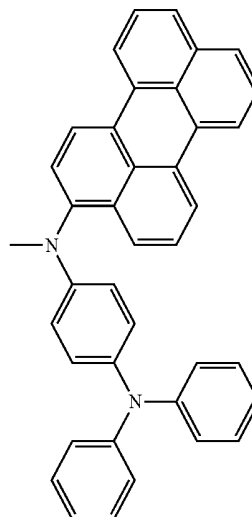
74

-continued

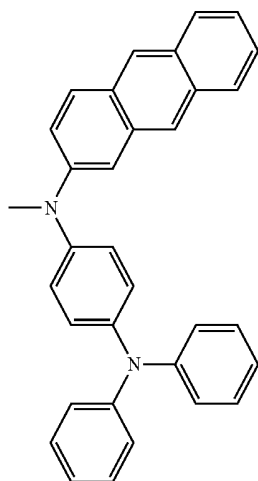


75

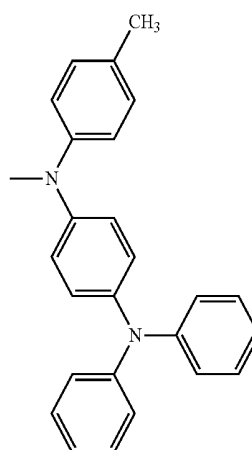
-continued



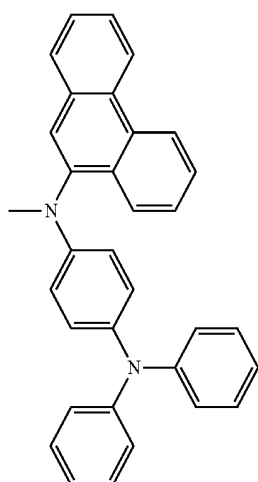
78



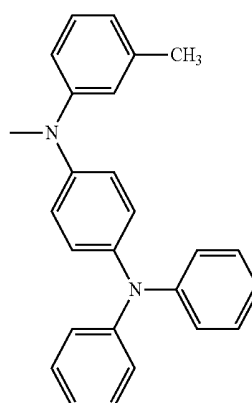
76



79

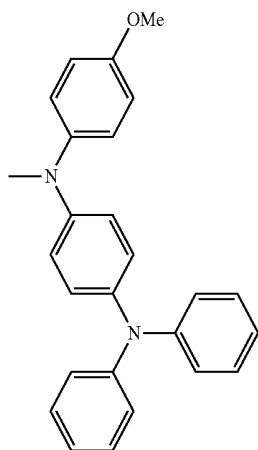


77



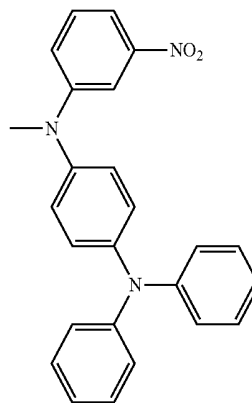
80

-continued

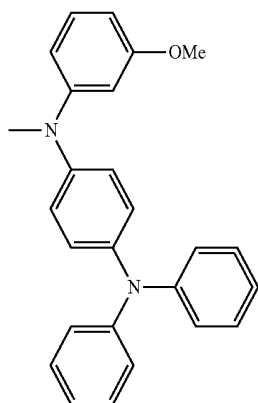


81

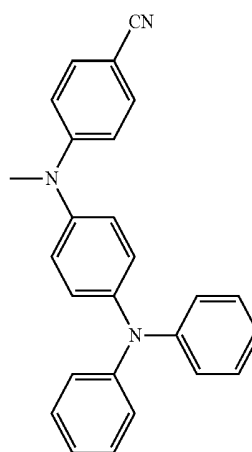
-continued



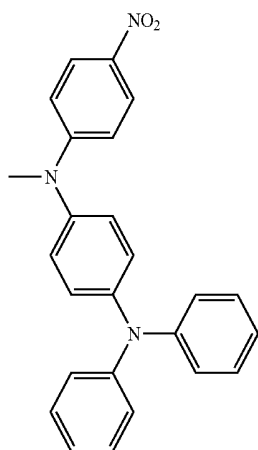
84



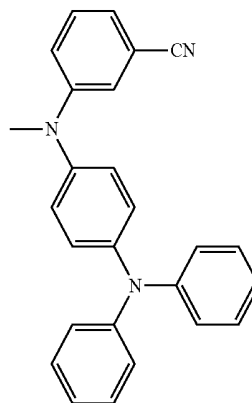
82



85

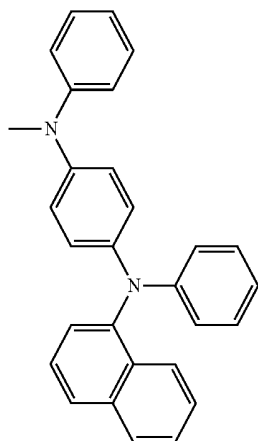


83



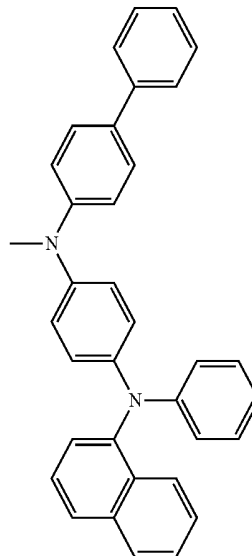
86

-continued



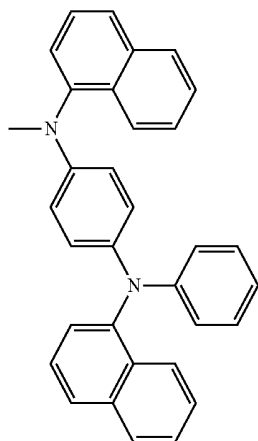
87

-continued

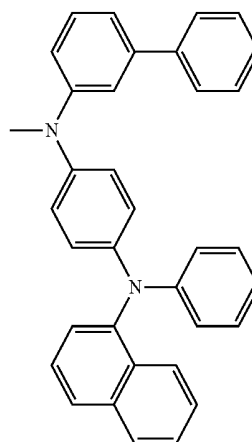


90

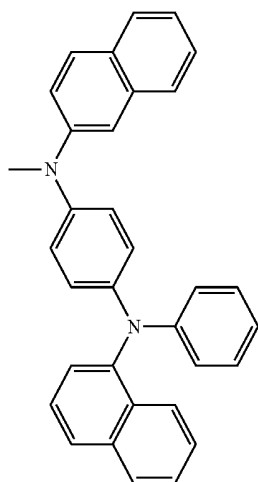
88



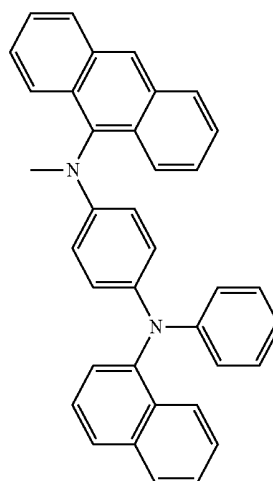
89



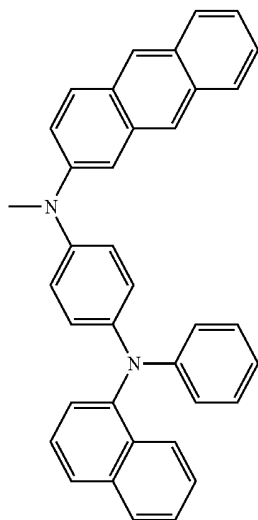
91



92

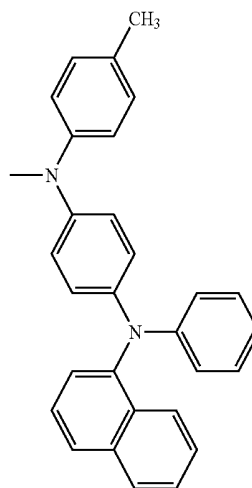


-continued

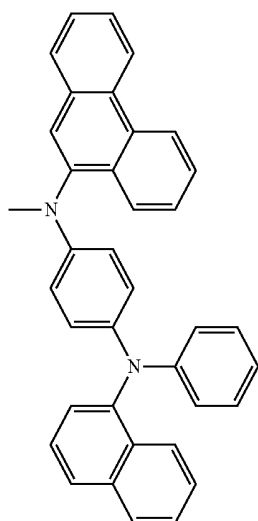


93

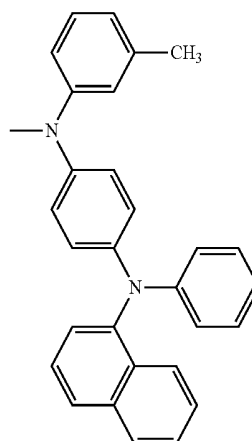
-continued



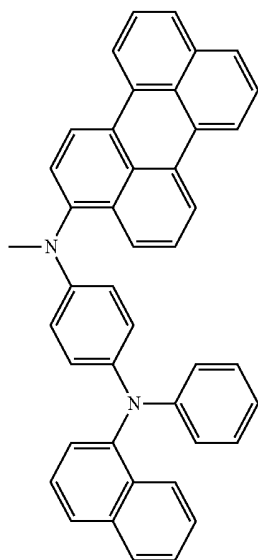
96



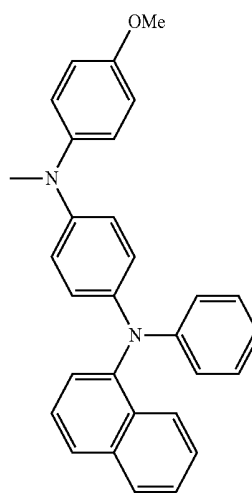
94



97

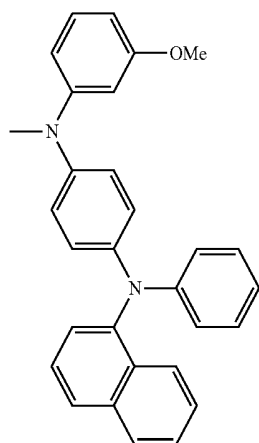


95



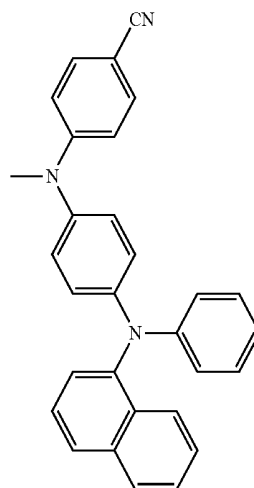
98

-continued



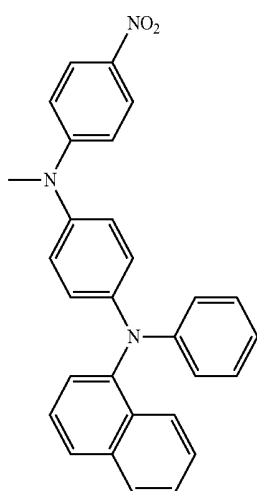
99

-continued

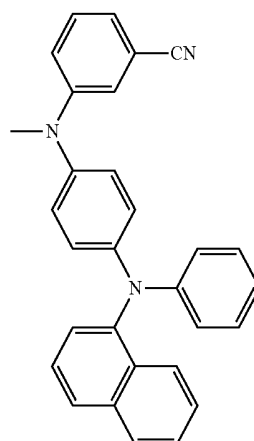


102

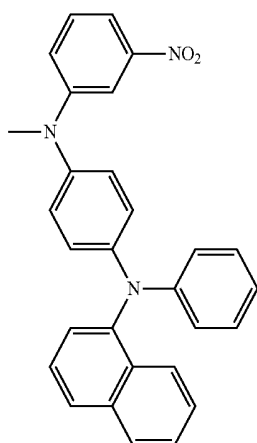
100



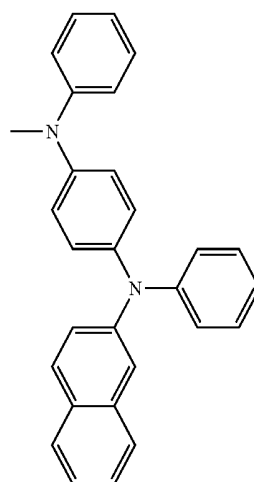
103



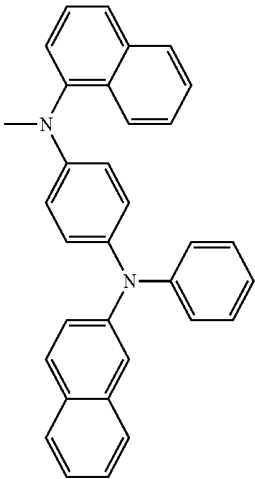
101



104

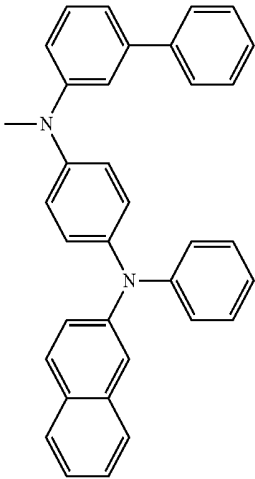


-continued

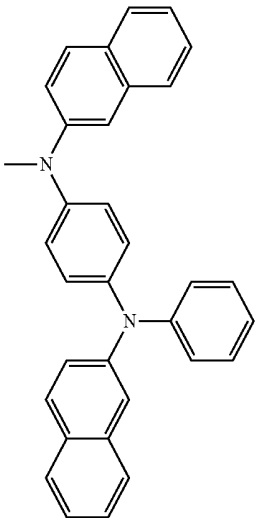


105

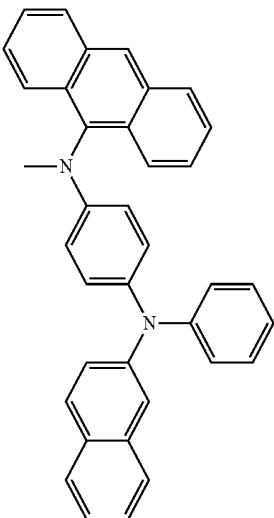
-continued



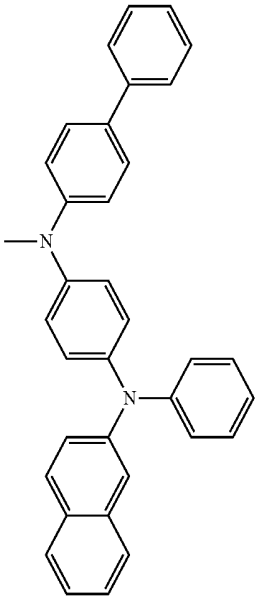
108



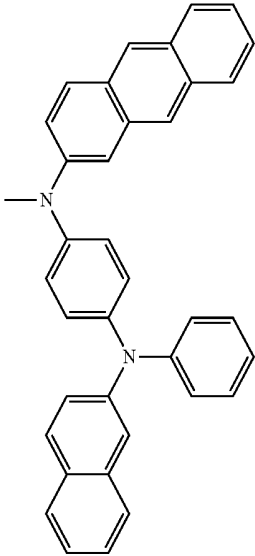
106



109

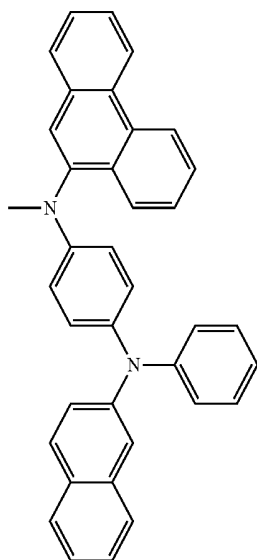


107



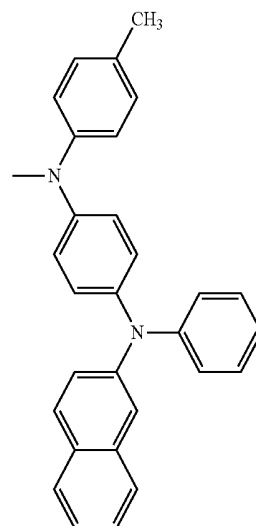
110

-continued

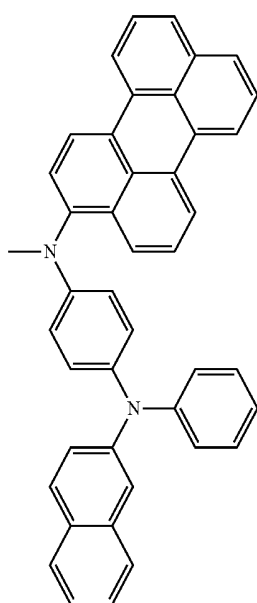


111

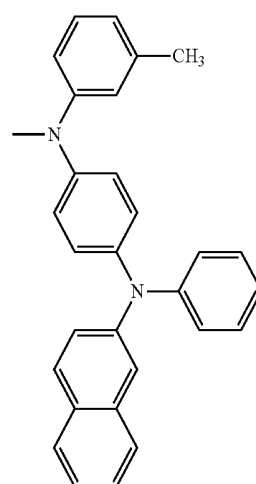
-continued



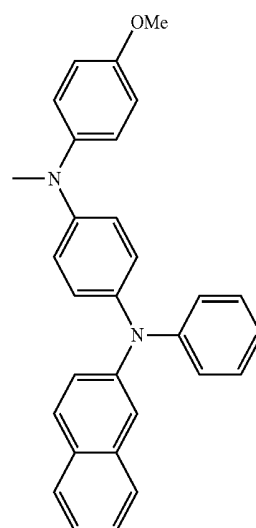
113



112

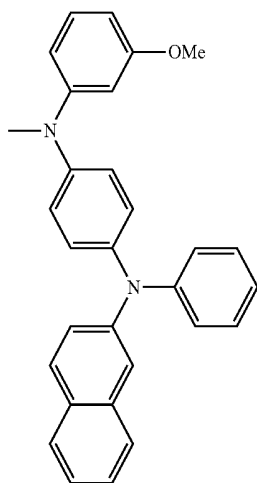


114



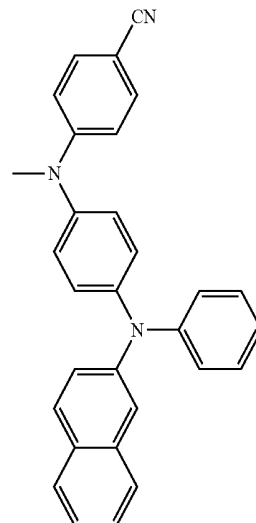
115

-continued

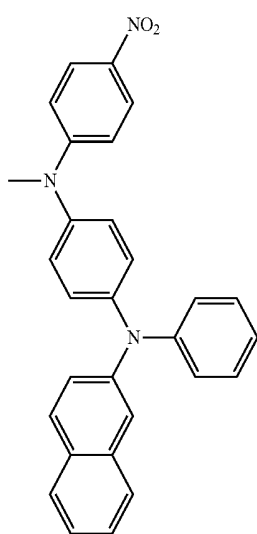


116

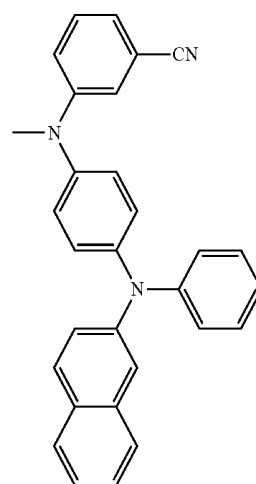
-continued



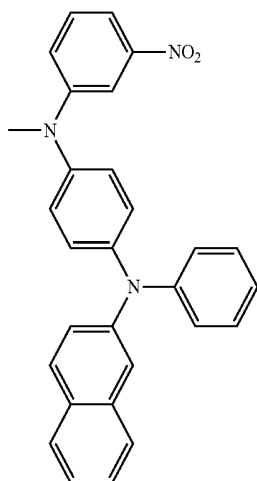
119



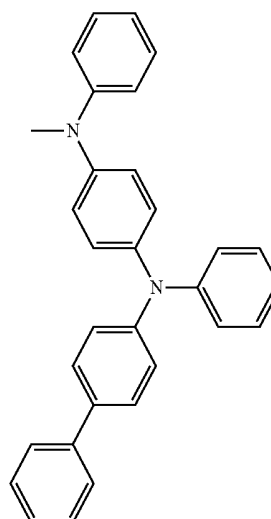
117



120

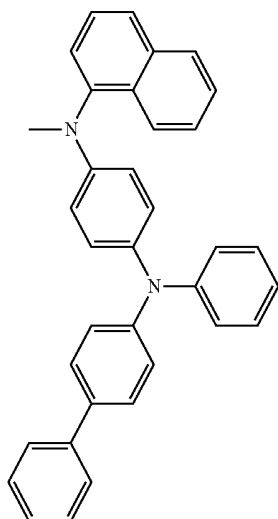


118



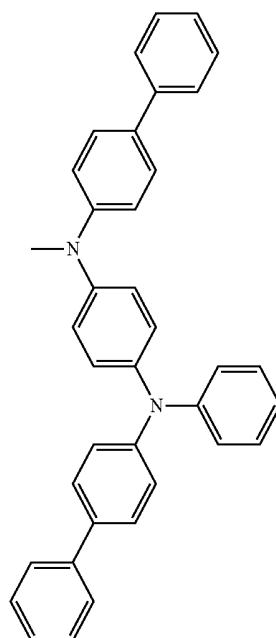
121

-continued



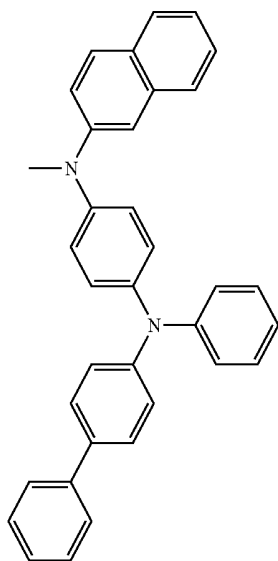
122

-continued

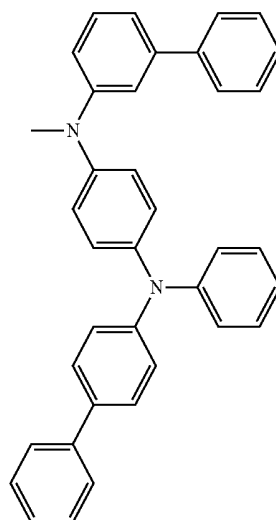


124

123

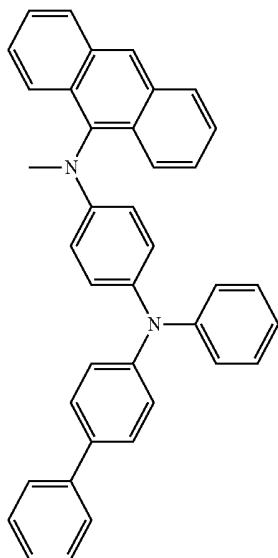


125



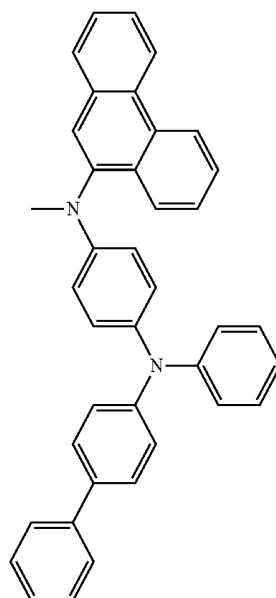
-continued

126

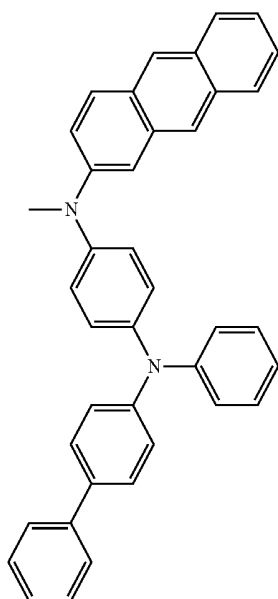


-continued

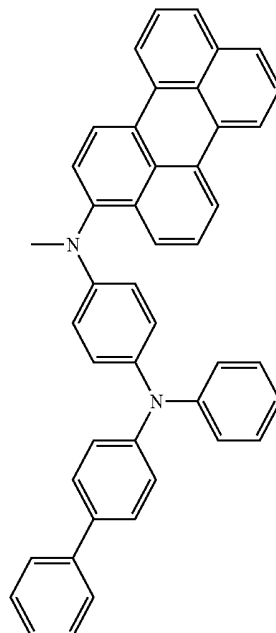
128



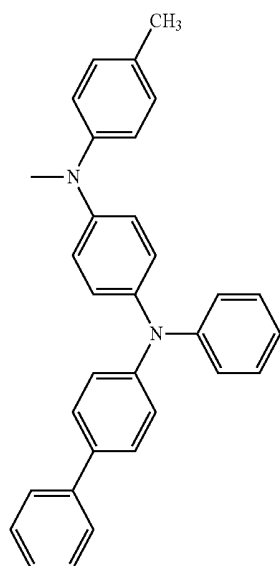
127



129

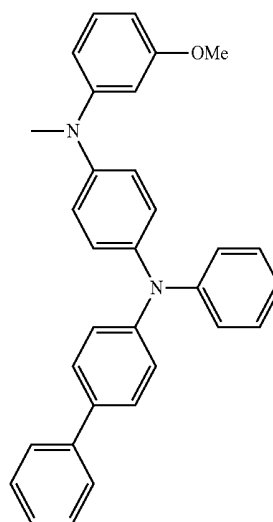


-continued

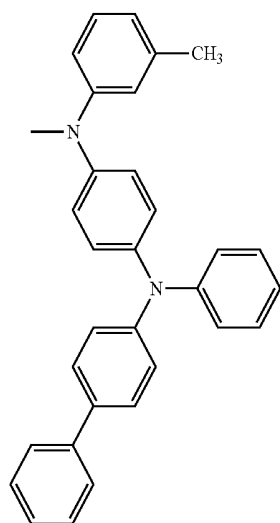


130

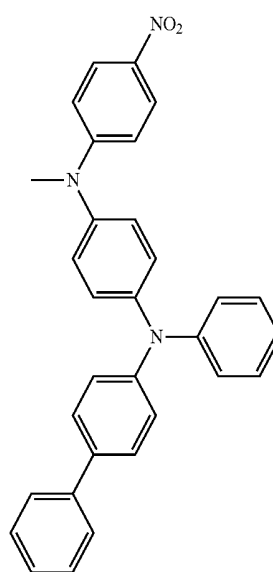
-continued



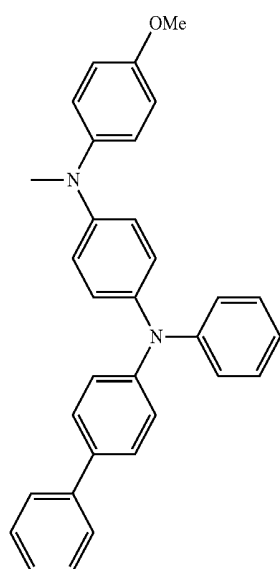
133



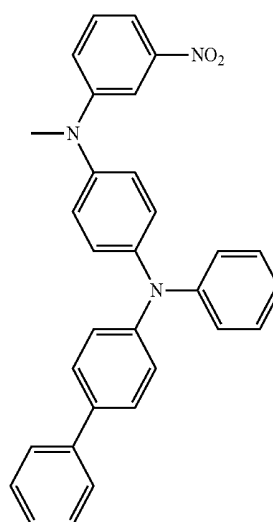
131



134

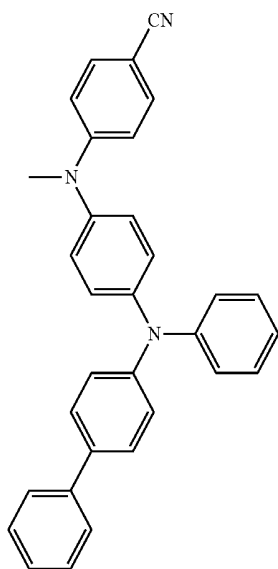


132



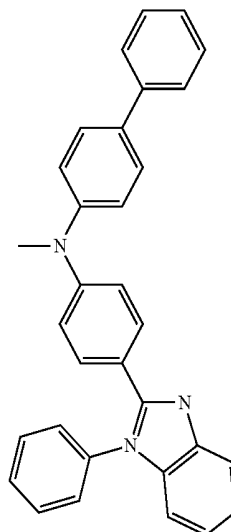
135

-continued

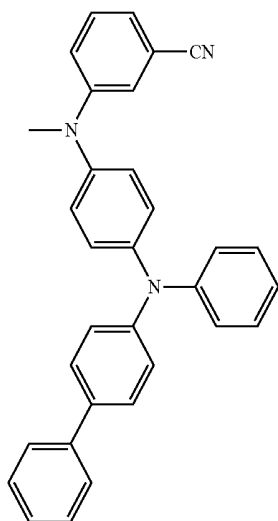


136

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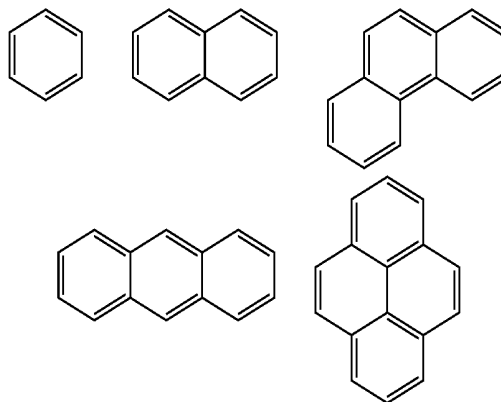


139

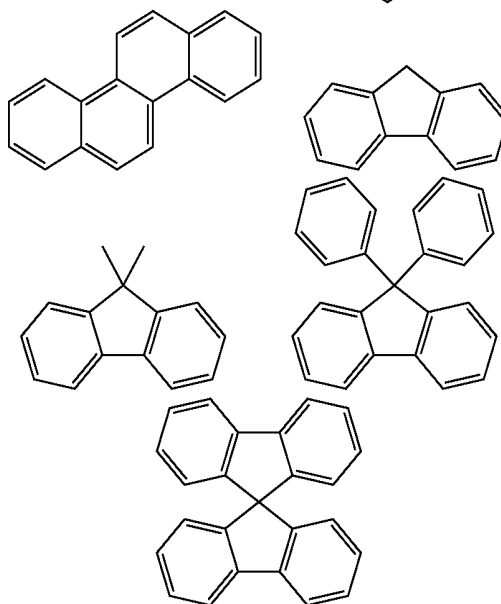
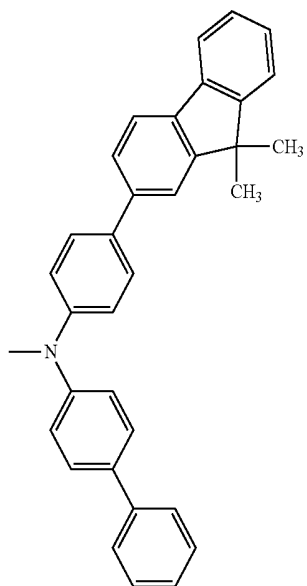


137

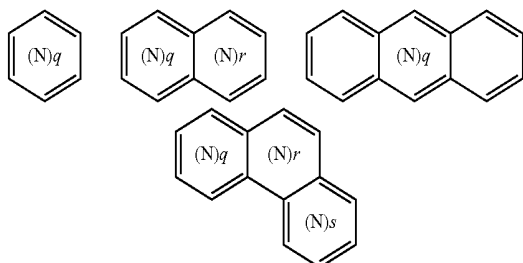
[0035] Preferable examples of the aryl group may be selected from the groups that are represented by the following Structural Formulas:



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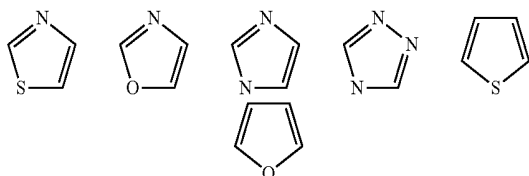


[0036] Preferable examples of the heteroaryl group may be selected from the groups that are represented by the following Structural Formulas:



[0037] In the above Formulas, (N)q, (N)r and (N)s means that at least one nitrogen atoms exist instead of a carbon atom in a benzene ring. In (N)q, (N)r and (N)s, q, r and s are each an integer in the range of 1 to 3.

[0038] In addition, it may be selected from the compounds or condensated ring compounds thereof having the following structure including at least one of N, S, or O in the ring.



[0039] The substituent group that is used in the present invention may be defined by the following description.

[0040] The alkyl group, alkoxy group, and alkenyl group may be a straight chain or a branched chain, and the number of carbon atoms is not particularly limited but it is preferable that it is in the range of 1 to 30. In particular, in the case of when the substituent group of Formula 1 is the alkyl group, the number of carbon atoms of the alkyl group does not affect a conjugation length of the compound, but affects an application method to the organic light emitting device of the compound, for example, application of a vacuum deposition method or a solution coating method. Accordingly, the number of carbon atoms of the alkyl group is not particularly limited.

[0041] As examples of the alkyl group, there are methyl group, ethyl group, propyl group, isopropyl group, butyl group, t-butyl group, pentyl group, hexyl group and heptyl group, but it is not limited thereto.

[0042] As examples of the alkenyl group, there is the alkenyl group that is bonded with the aryl group, such as the styryl group, the styrenyl group and the like.

[0043] The aryl group may be a monocycle or a polycycle, and the number of carbon atoms is not particularly limited, but it is preferable that it is in the range of 6 to 60. As examples of the monocyclic aryl group, there are the phenyl group, the biphenyl group, the terphenyl group, fluorene group, stilbene and the like, and as examples of the polycyclic aryl group, there are the naphthyl group, the anthracenyl group, the phenanthryl group, the pyrenyl group, the perylenyl group, the crycenyl group and the like, but the scope of the present invention is not limited thereto.

[0044] The heteroaryl group may be a monocycle or a polycycle, a heteroatom, and a ring group that includes O, N or S, and the number of carbon atoms is not particularly limited, but it is preferable that the number of carbon atoms is in the range of 3 to 60.

[0045] It is preferable that the number of carbon atoms of the cycloalkyl group is in the range of 3 to 30, which is the range that does not provide sterical hindrance, and as detailed examples thereof, cyclopentyl group or cyclohexyl group is more preferable.

[0046] As examples of the halogen group, there are fluorine, chlorine, bromine, or iodine.

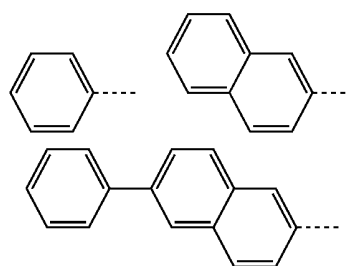
[0047] The spiro bond means a ring structure that realizes bonding through one atom, and the ring structure may be a monocycle or a polycycle.

[0048] In the present specification, "substituted or unsubstituted" means that it is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, $C_1\sim C_{30}$ alkyl group, $C_2\sim C_{30}$ alkenyl group, $C_1\sim C_{30}$ alkoxy group, $C_3\sim C_{30}$ cycloalkyl group, $C_2\sim C_{30}$ heterocycloalkyl group, $C_6\sim C_{60}$ aryl group and $C_3\sim C_{60}$ heteroaryl group.

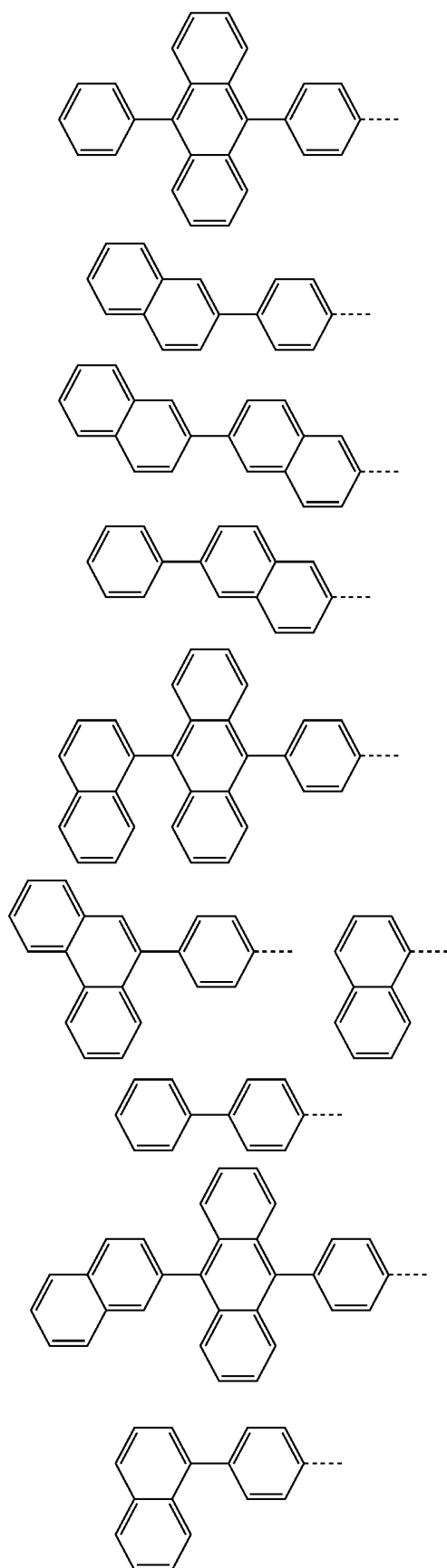
[0049] In Formula 1, it is preferable that Ar_1 is hydrogen, substituted or unsubstituted aryl group, or substituted or unsubstituted heteroaryl group, and in detail, it is preferable that it is hydrogen, substituted or unsubstituted phenyl group, substituted or unsubstituted naphthyl group, substituted or unsubstituted phenanthryl group, substituted or unsubstituted pyridyl group. At this time, as the substituent group, heavy hydrogen, halogen atoms such as fluorine, chlorine, and bromine, hydroxy group, nitrile group, nitro group, amino group, substituted amino group, alkoxy group such as methoxy group, alkyl group such as methyl group, ethyl group, tert-butyl group, and carbonyl group are preferable. It is more preferable that Ar_1 is hydrogen or phenyl group.

[0050] In Formula 1, it is preferable that Ar_2 , Ar_3 and Ar_4 are in detail the substituent groups described in the following Table, and the following groups may be substituted by one or more groups of heavy hydrogen atom, halogen atoms such as fluorine, chlorine, iodine and the like, nitrile group, heteroaryl group, aryl group in which the heavy hydrogen atom is substituted, nitrile group substituted aryl group, arylaminyl group and arylaminyl group substituted aryl group.

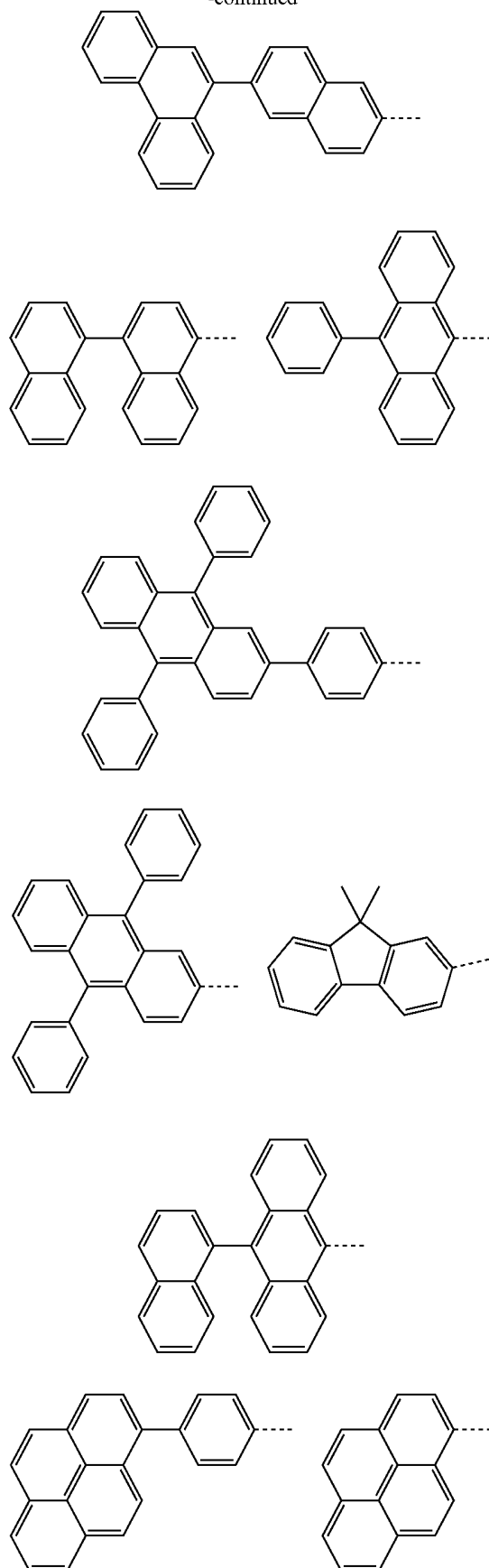
[0051] However, the scope of the present invention is not limited to the following examples.



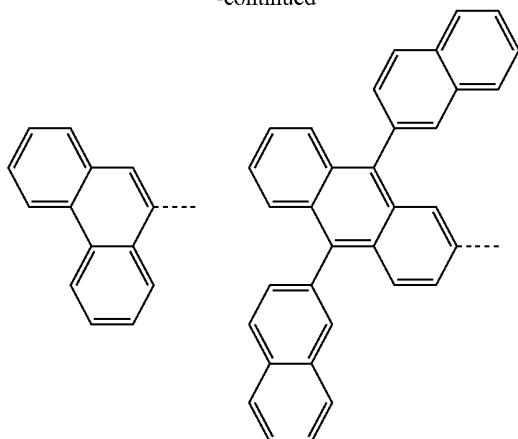
-continued



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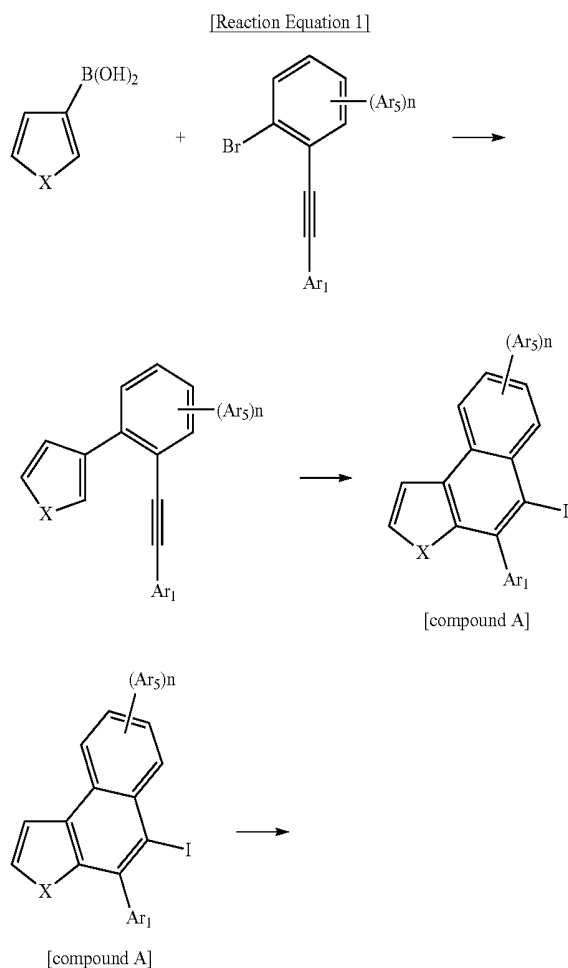


-continued

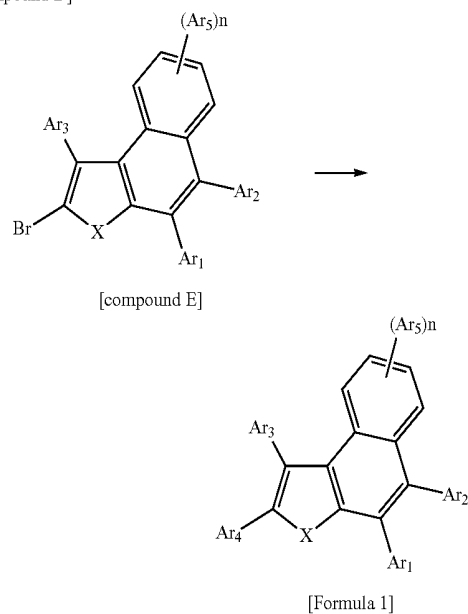
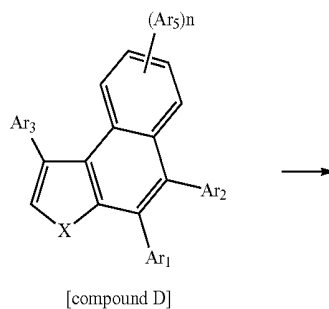
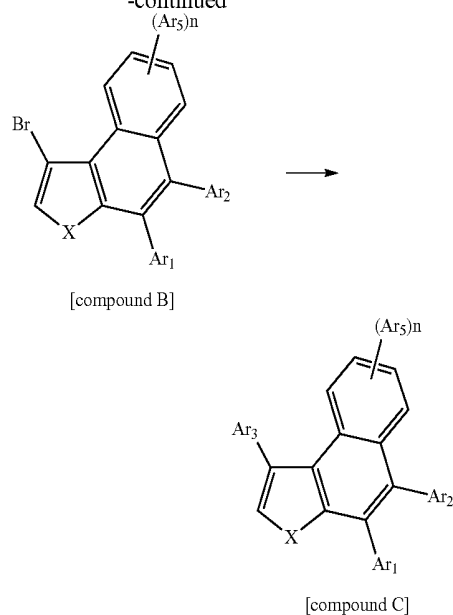


[0052] In addition, the present invention provides a method for manufacturing the derivative that is represented by Formula 1.

[0053] According to an embodiment of the present invention, in Formula 1, the manufacturing method of Formula 1 may be carried out in the same sequence as the following Reaction Equation 1, but is not limited thereto.



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[0054] In Reaction Equation 1, Ar₁ to Ar₅ are the same as those defined in Formula 1.

[0055] According to Reaction Equation 1, pentagonal heteroaryl boronic acid is subjected to Suzuki coupling in conjunction with the alkyne compound to which the halogen group is introduced under the Pd catalyst. To the manufactured compound, the mixture in which ICl₁ is dissolved in

CH_2Cl_2 is dropped and agitated according to the manufacturing method that is described in the document [Journal of Organic Chemistry 2005, 70(9), 3511-3517], such that the compound A to which the iodo group is introduced is obtained in a solid form. By the manufacturing method that includes the method in which under the Pd catalyst, after the boronic acid or boron ester reactants are subjected to Suzuki Coupling and Ar_2 is introduced, the bromo group is introduced by NBS or Br_2 , and while under the Pd catalyst, the Suzuki coupling and the bromination reaction are repeated, Ar_3 , Ar_4 are sequentially introduced, the compound of Formula 1 according to the present invention may be manufactured.

[0056] According to another embodiment of the present invention, in Reaction Equation 1, by using pentagonal 5-heteroaryl boronic acid in which the benzene ring is condensed instead of the pentagonal heteroaryl boronic acid, the compound of Formula 4 may be manufactured.

[0057] As shown in Reaction Equations 1-1 to 1-4, Ar_1 may be introduced from the substituted or unsubstituted acetylene group. In detail, in the case of Ar_1 , the phenyl group is introduced from the substituted or unsubstituted phenylacetylene, and the naphthyl group may be introduced from the substituted or unsubstituted naphthylacetylene. In addition, from the substituted or unsubstituted phenanthrylacetylene, the phenanthryl group may be introduced, and from the substituted or unsubstituted pyridylacetylene, the pyridyl group may be introduced. Ar_1 may be substituted by Ar_140 , Ar_1 may introduce the other substituent groups by a general known reaction. The possible acetylene compound is shown in Table 2.

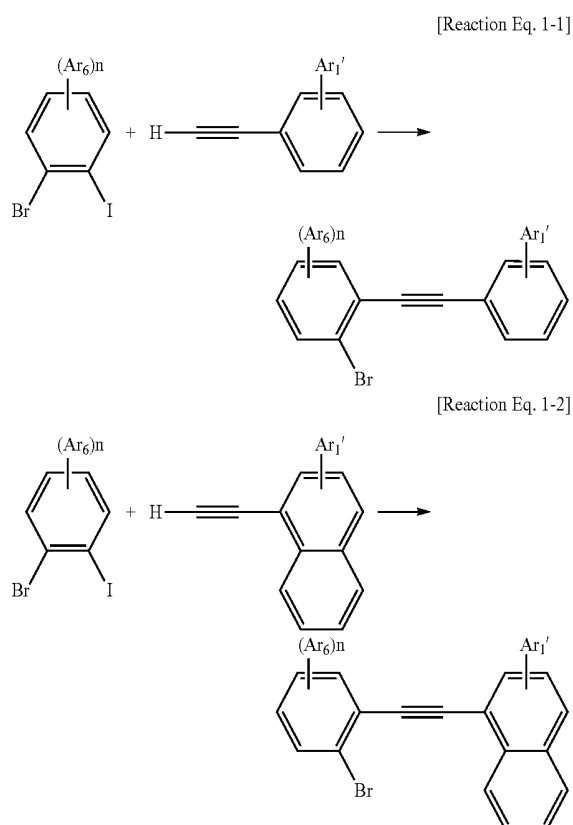


TABLE 2

Reactant

TABLE 2-continued

Reactant

TABLE 2-continued

Reactant

[0058] In Table 2, p is an integer in the range of 0 to 5.

[0059] In Reaction Equations 1-1 to 1-4 and Table 2,

[0060] Ar₁ is preferably substituted or unsubstituted phenyl group, substituted or unsubstituted naphthyl group, substituted or unsubstituted phenanthryl group, substituted or unsubstituted pyridyl group, and more preferably phenyl group.

[0061] At this time, as the substituent group, as shown in Table 2, heavy hydrogen, halogen atoms such as fluorine, chlorine, and bromine, hydroxy group, nitrile group, nitro group, amino group, substituted amin group, alkoxy group such as methoxy group, alkyl group such as methyl group, ethyl group, tert-butyl group, and carbonyl group are preferable.

[0062] In addition, at this time, as the substituent group, when the substituent group Ar_1' introduced to the acetylene group is $Br-$, $TfO-$, since the substituent group such as aryl group, heteroaryl group, arylamin group is easily introduced under the Pd catalyst, as defined in Formula 1, Ar_1 may be aryl group or heteroaryl group introduced as various substituent groups.

[0063] In addition, at this time, as the substituent group, when the substituent group Ar_1' which is introduced to the acetylene group is $-CHO$ (formyl group), by a known reaction, since the heteroaryl group such as imidazole group, oxazole group, thiazole group including N, O or S may be manufactured, as defined in Formula 1, Ar_1 may be the aryl group to which the heteroaryl group is introduced.

[0064] In Formulas 1 to 4, Ar_2 is preferably hydrogen, heavy hydrogen, iodo group, boronic acid, silyl group, and alkyl group. This is because Ar_2 introduced by the iodo may introduce hydrogen, heavy hydrogen, silyl group, alkyl group by lithiation.

[0065] In addition, Ar_2 may be substituted by substituted or unsubstituted aryl group, substituted or unsubstituted heteroaryl group, or substituted or unsubstituted arylamin group and the like. These substituents may be introduced under the Pd catalyst through Suzuki coupling or arylamin coupling.

[0066] The preferable aryl group is phenyl group, biphenyl group, terphenyl group, fluorene group, naphthyl group, phenanthryl, pyrenyl, anthracenyl group.

[0067] The preferable heteroaryl group is carbazole group, triazine group, quinoline group, imidazole group, quinazoline group, thiophenyl group, imidazole group, oxazole group, thiazole group and the like.

[0068] The preferable arylamino group is amino group that is substituted by aryl group, arylamino group that is substituted by aryl group, arylamino group that is substituted by heteroaryl group, and arylamino group that is substituted by alkylaryl group.

[0069] Since Ar_3 is introduced by using the same manufacturing method as Ar_2 , it is preferably hydrogen, heavy hydrogen, bromo group, boronic acid, silyl group, alkyl group, aryl group, heteroaryl group, arylamin group and the like.

[0070] Since Ar_4 is introduced by using the same manufacturing method as Ar_2 , it is preferably hydrogen, heavy hydrogen, bromo group, boronic acid, silyl group, alkyl group, aryl group, heteroaryl group, arylamin group and the like.

[0071] In addition, the present invention provides an organic electronic device which includes a first electrode, a second electrode, and one or more organic material layers that are disposed between the first electrode and the second electrode, wherein one or more layers of the organic material layers include the compound that is represented by Formula 1.

[0072] The organic electronic device according to the present invention may be manufactured by using a manufacturing method and a material of a general organic electronic device, except that one or more organic material layers are formed by using the above compounds.

[0073] It is preferable that the organic material layer includes a hole injection layer or a hole transport layer, and the hole injection layer or hole transport layer includes the compound of Formula 1.

[0074] In addition, the hole injection layer or hole transport layer may further include a dopant material.

[0075] It is preferable that the organic material layer includes a light emitting layer, and the light emitting layer includes the compound of Formula 1.

[0076] In addition, the light emitting layer may further include a fluorescent dopant material or phosphorescent dopant material.

[0077] In addition, it is preferable that the organic material layer includes an electron injection layer or an electron transport layer, and the electron injection layer or electron transport layer includes the compound of Formula 1.

[0078] In addition, the electron injection layer or electron transport layer may further include a dopant material.

[0079] It is preferable that the organic electronic device may be selected from the group consisting of an organic light emitting device, an organic solar cell, an organic photoconductor (OPC) drum and an organic transistor, and the organic light emitting device is the most preferable example.

[0080] Hereinafter, the organic light emitting device will be described.

[0081] The compound of Formula 1 may be used as an organic material layer in the organic light emitting device because of peculiarity of the structure.

[0082] In an embodiment of the present invention, the organic light emitting device may have a structure that includes a first electrode, a second electrode, and an organic material layer that is disposed between them. The organic light emitting device may be manufactured by using a manufacturing method and a material of a general organic electronic device, except that the compound according to the present invention is used in one or more layers of the organic material layer of the organic light emitting device. The organic material layer of the organic light emitting device according to the present invention may have a single layer structure including one layer and a multilayered structure that includes two or more layers including a light emitting layer. In the case of when the organic material layer of the organic light emitting device according to the present invention has the multilayered structure, for example, this may be a structure in which hole injection layer, hole transport layer, light emitting layer, electron transport layer and the like are layered. However, the structure of the organic light emitting device is not limited to this, but may comprise a smaller number of organic material layers. In the organic material layer having a multilayered structure, the compound of Formula 1 may be included in a light emitting layer, a layer that performs simultaneously hole injection/hole transport and light emission, a layer that performs simultaneously hole transport and light emission, or a layer that performs simultaneously electron transport and light emission.

[0083] For example, the structure of the organic light emitting device may have a structure shown in FIGS. 1 to 4, but is not limited thereto.

[0084] FIG. 1 illustrates a structure of the organic light emitting device in which an anode 102, a light emitting layer 105 and a cathode 107 are sequentially layered on a substrate 101. In this structure, the compound of Formula 1 may be included in the light emitting layer 105.

[0085] FIG. 2 illustrates a structure of the organic light emitting device in which an anode 102, a hole injection/hole transport and light emitting layer 105, an electron transport layer 106 and a cathode 107 are sequentially layered on a substrate 101. In this structure, the compound of Formula 1 may be included in the hole injection/hole transport and light emitting layer 105.

[0086] FIG. 3 illustrates a structure of the organic light emitting device in which a substrate **101**, an anode **102**, a hole injection layer **103**, a hole transport and light emitting layer **105**, an electron transport layer **106** and a cathode **107** are sequentially layered. In this structure, the compound of Formula 1 may be included in the hole injection/hole transport and light emitting layer **105**.

[0087] FIG. 4 illustrates a structure of the organic light emitting device in which a substrate **101**, an anode **102**, a hole injection layer **103**, a hole transport layer **104**, an electron transport and light emitting layer **105** and a cathode **107** are sequentially layered. In this structure, the compound of Formula 1 may be included in the electron transport and light emitting layer **105**.

[0088] For example, the organic light emitting device according to the present invention may be manufactured by forming an anode by depositing metal or metal oxides having the conductivity or an alloy thereof on a substrate by using a PVD (physical vapor deposition) method such as sputtering or e-beam evaporation, forming the organic material layer that includes hole injection layer, hole transport layer, light emitting layer and electron transport layer thereon, and depositing the material that is capable of being used as a cathode thereon. In addition to this method, an organic light emitting device may be manufactured by sequentially depositing a cathode, an organic material layer, and an anode material on a substrate.

[0089] The organic material layer may have a multilayered structure that includes a hole injection layer, a hole transport layer, a light emitting layer, and an electron transport layer, but is not limited thereto and may have a single layer structure. The organic material layer may be manufactured in a smaller number of layer by using various polymer materials and by using not a deposition method but a solvent process, for example, spin coating, dip coating, doctor blading, screen printing, inkjet printing, heat transferring method and the like.

[0090] As the anode material, in general, it is preferable to use the material having the large work function so as to smoothly perform hole injection into the organic material layer. As examples of the anode material that is capable of being used in the present invention, there are metal or alloy thereof such as vanadium, chrome, copper, zinc, gold and the like; metal oxides such as zinc oxides, indium oxides, indium tin oxides (ITO), indium zinc oxides (IZO) and the like; a combination of metal and oxides such as ZnO:Al or SnO₂:Sb; conductive polymers such as poly(3-methyl compound), poly[3,4-(ethylene-1,2-dioxy) compound](PEDT), polypyrrole and polyaniline, but it is not limited thereto.

[0091] As the cathode material, in general, it is preferable to use the material having the small work function so as to smoothly perform electron injection into the organic material layer. As detailed examples of the cathode material, there are metal such as magnesium, calcium, sodium, potassium, titanium, indium, yttrium, lithium, gadolinium, aluminium, silver, tin, and lead or an alloy thereof; a multilayered structure material such as LiF/Al or LiO₂/Al, but it is not limited thereto.

[0092] The hole injection material is a material that is capable of well receiving holes from the anode at a low voltage, and it is preferable that the HOMO (highest occupied molecular orbital) of the hole injection material is a value between the work function of the anode material and the HOMO of the organic material layer around them. As detailed examples of the hole injection material, there are metal porphyrine, oligo compound, arylamine-based organic material, hexanitrihexaazatriphenylene-based organic material,

quinacridone-based organic material, perylene-based organic material, anthraquinone and polyaniline and poly compound-based conductive polymers, but it is not limited thereto.

[0093] The hole transport material is a material that receives the holes from the anode or the hole injection layer and transfer them to the light emitting layer, and it is preferable to use the material having the large mobility to the holes. As detailed examples thereof, there are arylamine-based organic material, a conductive polymer, and a block copolymer in which a conjugate portion and a conjugate portion are simultaneously included, but it is not limited thereto.

[0094] The light emitting material is a material that receives the holes and the electrons from the hole transport layer and the electron transport layer, combines them, such that light at a range of visible rays is emitted, and it is preferable to use the material having excellent photon efficiency to fluorescence or phosphorescence. As detailed examples thereof, there are a 8-hydroxy-quinoline aluminium complex (Alq₃); a carbazole-based compound; a dimerized styryl compound; BALq; 10-hydroxybenzoquinoline-metal compound; a benzoxazole, benzthiazole and benzimidazole-based compound; a poly(p-phenylenevinylene) (PPV)-based polymer; a Spiro compound; polyfluorene, lubrene, anthracene, pyrene and the like, but it is not limited thereto.

[0095] The electron transport material is a material that receives the electrons from the cathode and transfer them to the light emitting layer, and it is preferable to use the material having the large mobility to the electrons. As detailed examples thereof, there are a 8-hydroxyquinoline Al complex; a complex including Alq₃; an organic radical compound; a hydroxyflavone-metal complex; oxazole, thiazole and imidazole-based compound and condensated ring compound thereof; quinoline and quinoline condensated ring compound; phenanthroline and phenanthroline condensated ring compound; quinazoline and quinazoline condensated ring compound and the like, but it is not limited thereto.

[0096] The organic light emitting device according to the present invention may be a front side light emitting type, a rear side light emitting type, or a both sides light emitting type according to the used material.

[0097] The compound according to the present invention may be operated in a principle that is similar to a principle applied to the organic light emitting device in organic solar cell, organic photoconductor, organic transistor, and organic electronic device.

Mode for Invention

[0098] Hereinafter, preferable Preparation Examples will be described in order to help understanding of the present invention. However, the following Preparation Examples are set forth to illustrate the present invention, but the scope of the present invention is not limited thereto.

[0099] The compound of Formula 1 according to the present invention can be manufactured with multistage chemical reactions. The above compounds may be manufactured by using the methods described in the following Preparation Examples. As described in the following Synthesis Examples, the compounds of Formula 1 may be manufactured from the following intermediate compounds. In the intermediate compounds, Br may be substituted by any other reactive atom or functional group.

[0100] Table 1 shows reactants that were used in the manufacturing of Formula 1, and the reactants were synthesized by using a general or known method, or used by purchasing commercial product.

TABLE 1

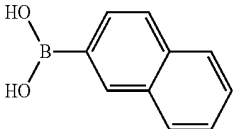
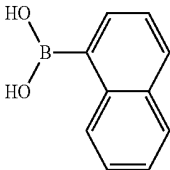
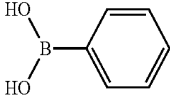
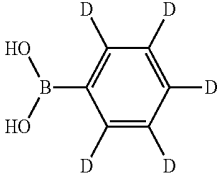
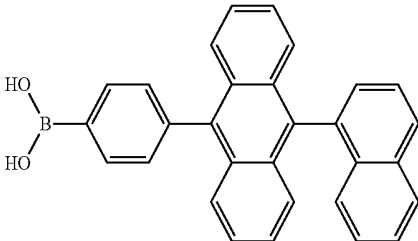
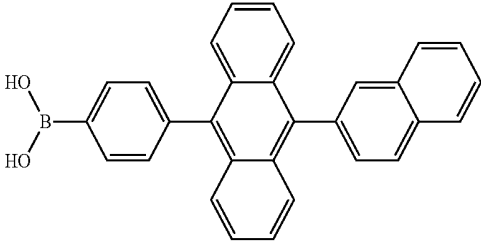
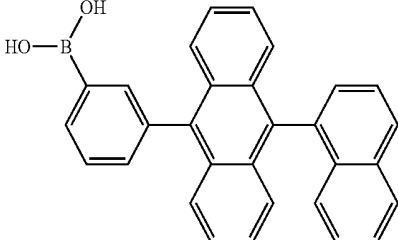
No.	Reactant
S-1	
S-2	
S-3	
S-4	
S-5	
S-6	
S-7	

TABLE 1-continued

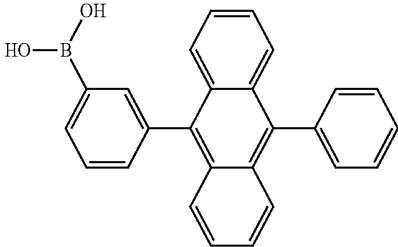
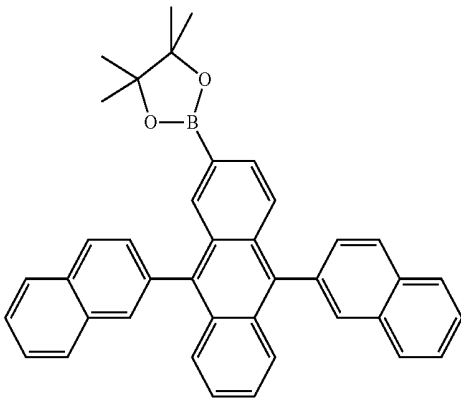
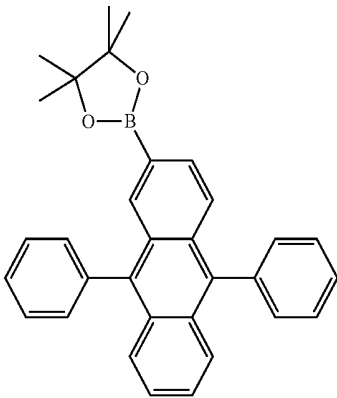
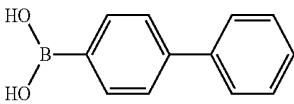
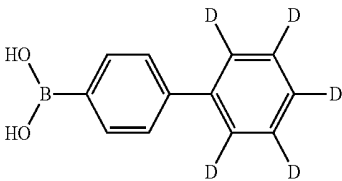
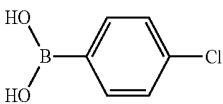
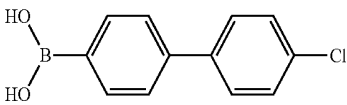
No.	Reactant
S-8	
S-9	
S-10	
S-11	
S-12	
S-13	
S-14	

TABLE 1-continued

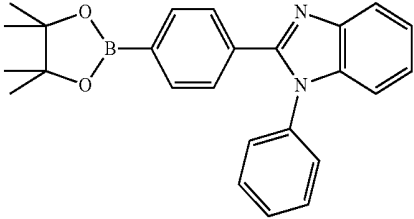
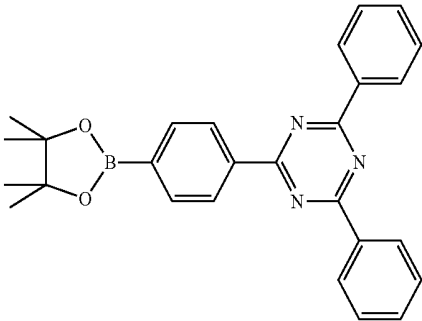
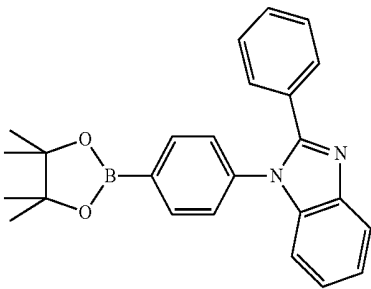
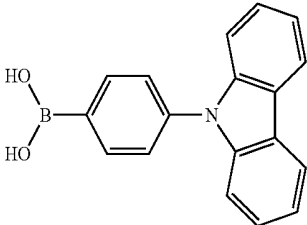
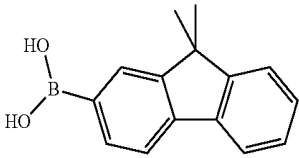
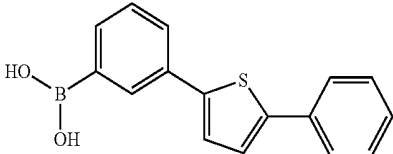
No.	Reactant
S-15	
S-16	
S-17	
S-18	
S-19	
S-20	

TABLE 1-continued

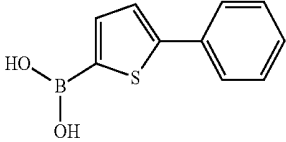
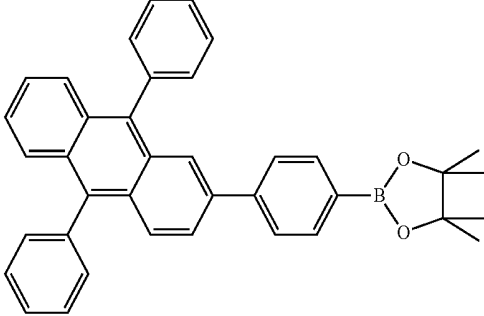
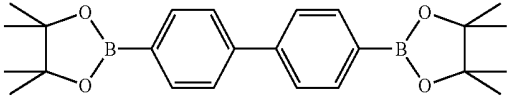
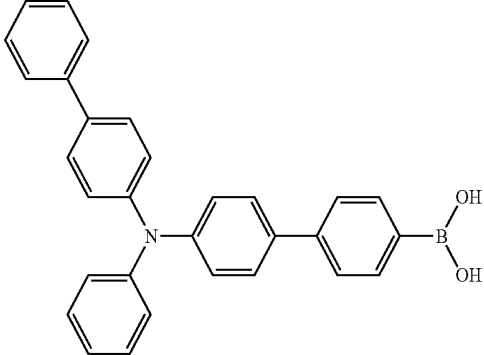
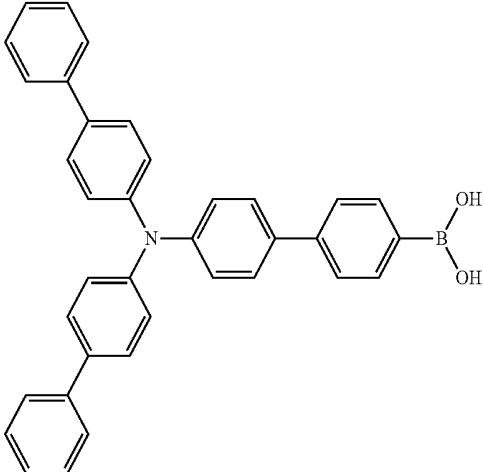
No.	Reactant
S-21	
S-22	
S-23	
S-24	
S-25	

TABLE 1-continued

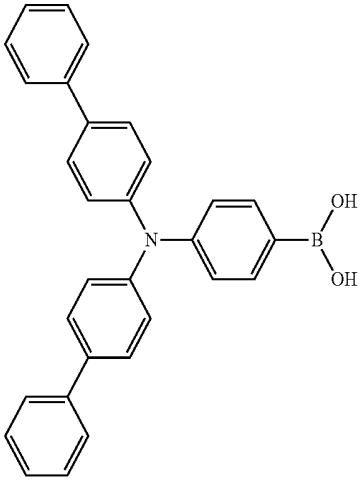
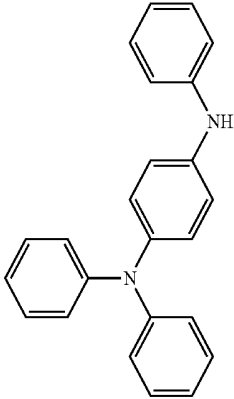
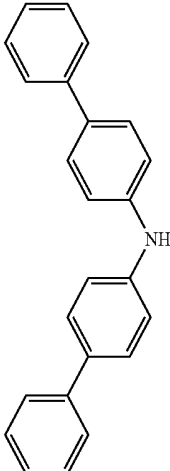
No.	Reactant
S-26	
S-27	
S-28	

TABLE 1-continued

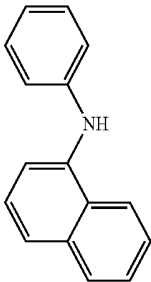
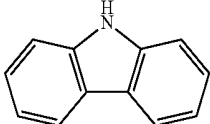
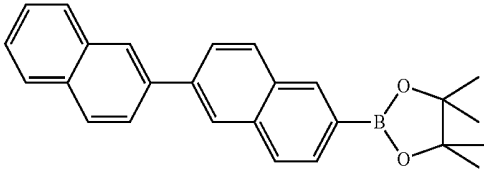
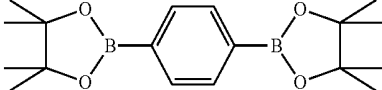
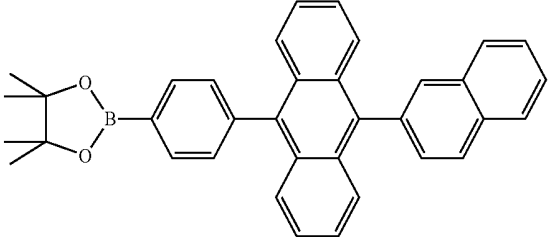
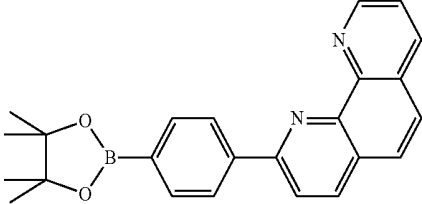
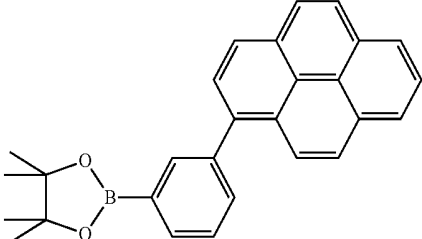
No.	Reactant
S-29	
S-30	
S-31	
S-32	
S-33	
S-34	
S-35	

TABLE 1-continued

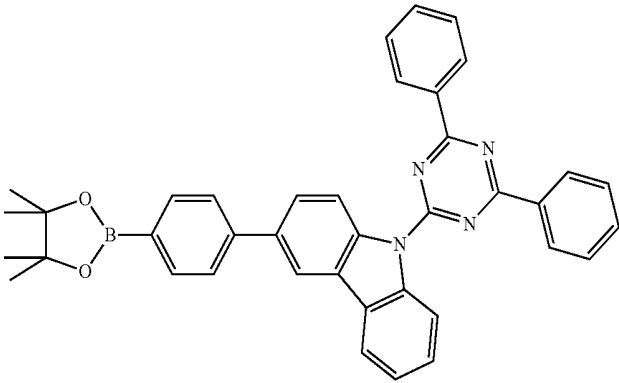
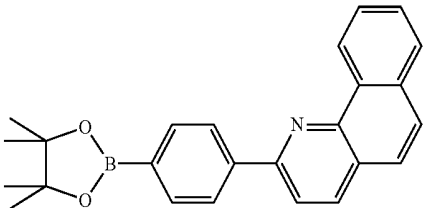
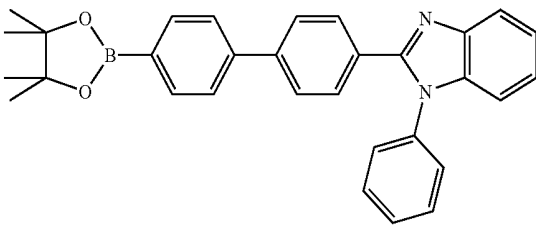
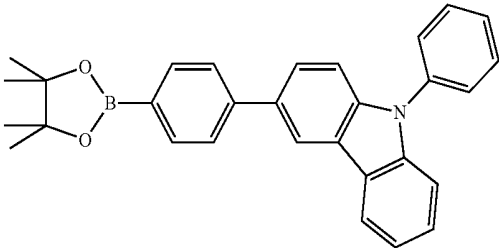
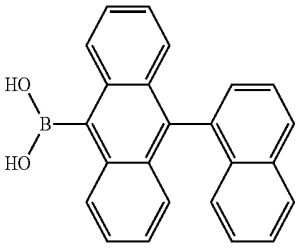
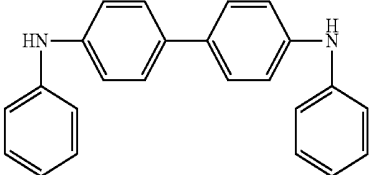
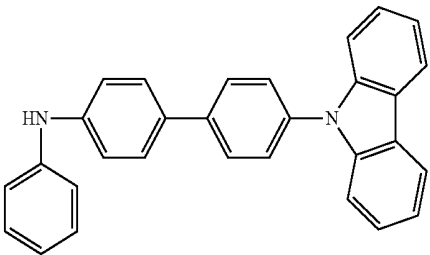
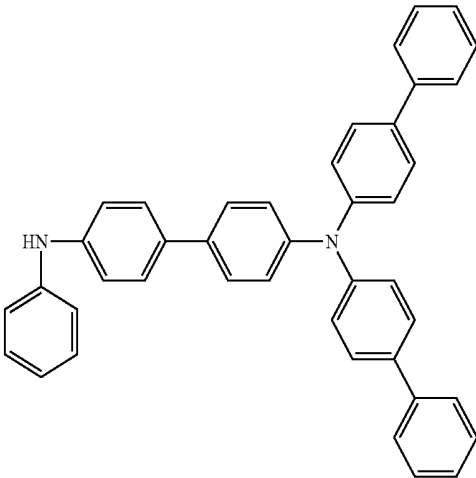
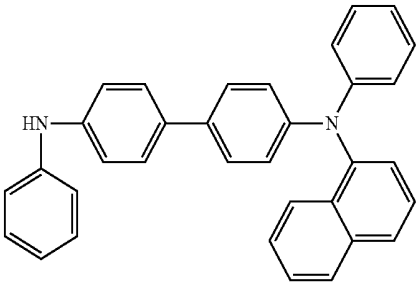
No.	Reactant
S-36	
S-37	
S-38	
S-39	
S-40	
S-41	

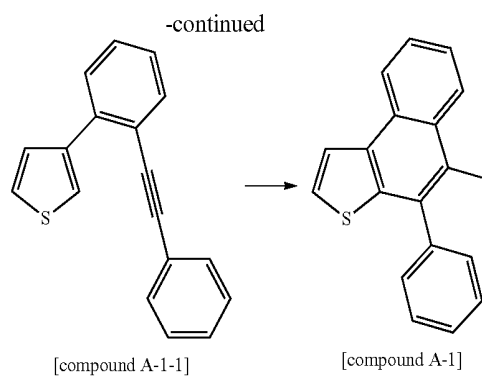
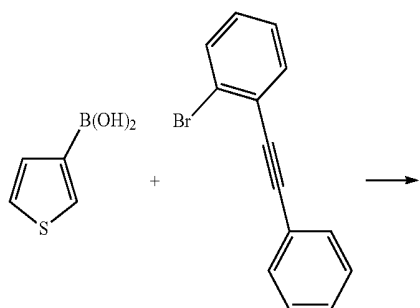
TABLE 1-continued

No.	Reactant
S-42	
S-43	
S-44	

SYNTHESIS EXAMPLE 1

Synthesis of the Compound A-1

[0101] 1-1. Synthesis of the Compound A-1-1

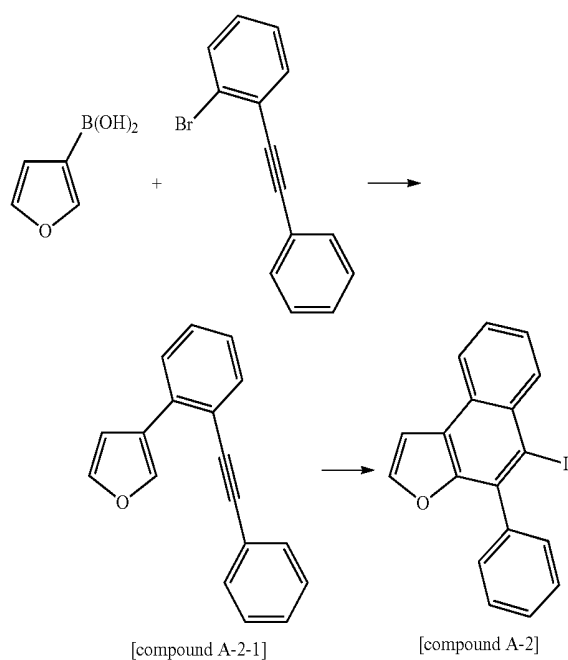


[0102] 1-bromo-2-(2-phenylethynyl)-benzene (16.3 g, 63.5 mmol), thiophen-3-yl-3-boronic acid (9.75 g, 76.2 mmol), and sodium carbonate (21.1 g, 152.4 mmol) were suspended in the mixture of toluene (200 mL), ethanol (100

[0106] MS $[M]^+ = 386$

Synthesis of the Compound A-2

[0107] 2-1. Synthesis of the Compound A-2-1

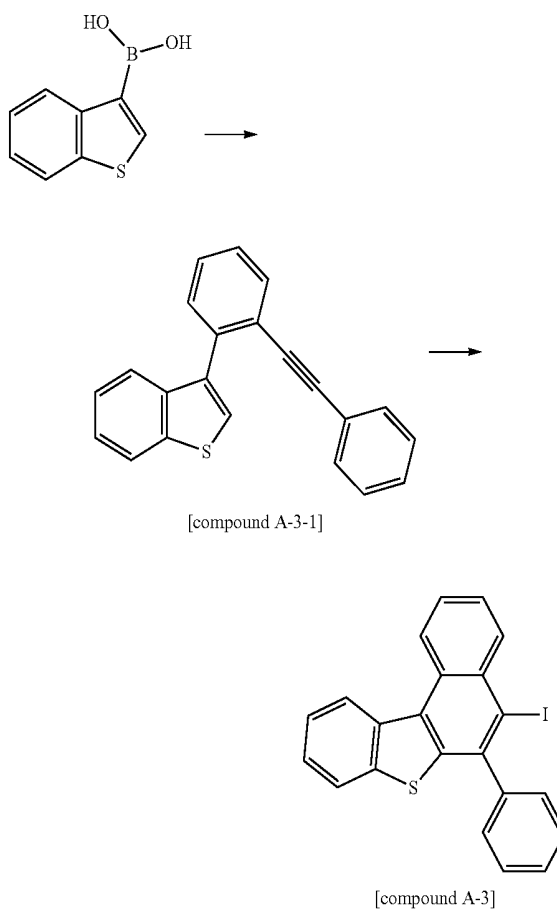


[0109] MS [M+H]⁺=245

[0112] MS [M]⁺=370

Synthesis of the Compound A-3

[0113] 3-1. Synthesis of the Compound A-3-1

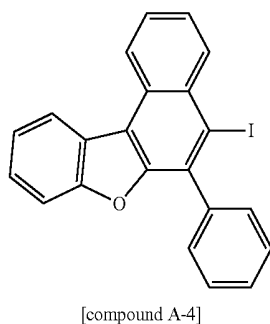
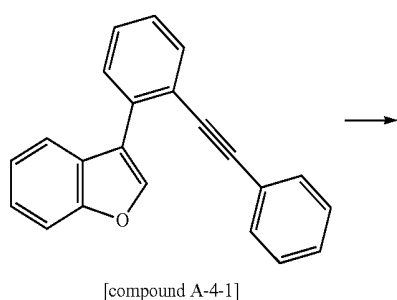
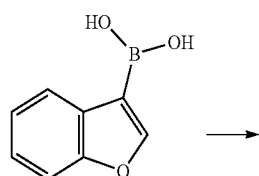


[0118] MS $[M]^+ = 436$

SYNTHESIS EXAMPLE 4

Synthesis of the Compound A-4

[0119] 4-1. Synthesis of the Compound A-4-1



[0120] In the synthesis of the compound A-1-1, the compound A-4-1 (9.1 g, yield 62%) was synthesized by using the same method as the compound A-1-1, except that benzofu-

ran-3-yl-3-boronic acid (8.1 g, 50.0 mmol) was used instead of thiophene-3-boronic acid, and 1-bromo-2-(2-phenylethynyl)-benzene (13.4 g, 52.0 mmol), and sodium carbonate (15.8 g, 153 mmol) were used.

[0121] MS [M+H]⁺=295

[0122] 4-2. Synthesis of the Compound A-4

[0123] After the compound A-4-1 (9.1 g, 30.9 mmol) was dissolved in CHCl₃ (80 mL), ICl (5.4 g, 33.0 mmol) was dissolved in CHCl₃ 20 mL, slowly dropped, and agitated for 12 hours. The formed yellow solid was filtered, washed with hexane, and dried to synthesize the compound A-4 (8.3 g, yield 64%).

[0124] MS [M]⁺=420

SYNTHESIS EXAMPLE 1-1-No.

Synthesis of the Compound 1B-1-No

[0125] The compound A-1, and 1 to 1.5 equivalents of the substituted or unsubstituted arylboronic acid (or arylboron ester) or the substituted or unsubstituted heteroarylboronic acid (or arylboron ester) like the reactant S-No. described in Table 1-1 were put, dissolved in THF, 0.02 equivalents of Pd(PPh₃) and 2 equivalents or more of 2M K₂CO₃/H₂O aqueous solution were added, and heated and agitated for 3 to 16 hours. The reaction mixture was cooled to normal temperature, filtered or extracted with the organic solvent, separated, purified, and dried to synthesize the 1B-1-No compound, and the results thereof are described in Table 1-1-1.

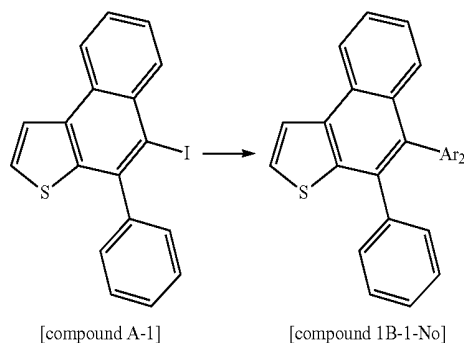
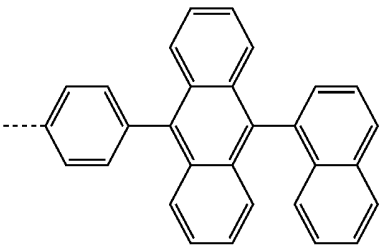
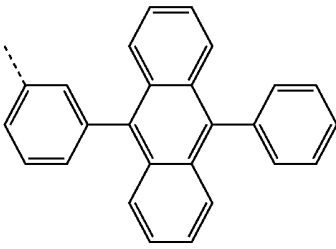
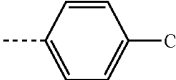
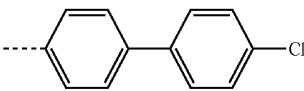
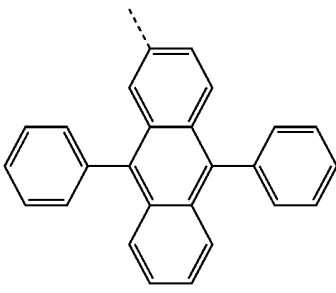
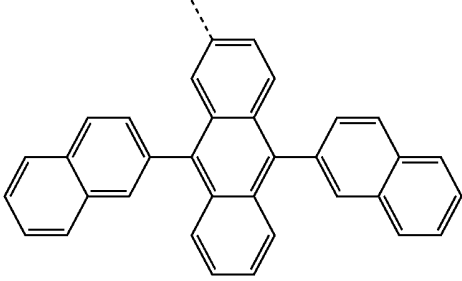


TABLE 1-1-1

Syn. Ex.	Product	Reactant	Ar2	MS [M + H] ⁺
1-1-No	1B-1-No			
1-1-1	compound S-1 1B-1-1			387
1-1-2	compound S-3 1B-1-2			337

TABLE 1-1-1-continued

Syn. Ex. 1-1-No	Product 1B-1-No	Reactant Ar2	MS [M + H] ⁺
1-1-3	compound S-5 1B-1-3		639
1-1-4	compound S-8 1B-1-4		589
1-1-5	compound S-13 1B-1-5		370
1-1-6	compound S-14 1B-1-6		446
1-1-7	compound S-10 1B-1-7		589
1-1-8	compound S-9 1B-1-8		689

SYNTHESIS EXAMPLE 1-1-1

Synthesis of the Compound 1B-1-1

[0126] Naphthalen-2-yl-2-boronic acid (1.6 g, 9.3 mmol) that was the reactant S-1 of Table 1, the compound A-1 (3 g, 7.8 mmol), and sodium carbonate (2.4 g, 15.5 mmol) were suspended in the mixture of toluene (100 mL), ethanol (10 mL) and water (20 mL).

[0127] To the suspension solution, tetrakis(triphenylphosphine)palladium (0.2 g, 1.6 mmol) was applied. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The organic material layer was separated, washed with water, and the aqueous layer was extracted with chloroform. The organic extract was dried on magnesium sulfate and concentrated under the vacuum to synthesize the compound 1B-1-1 (2.3 g, yield 77%).

[0128] MS [M+H]⁺=387

SYNTHESIS EXAMPLE 1-1-2

Synthesis of the Compound 1B-1-2

[0129] In Synthesis Example 1-1-1, it was synthesized by using the same method to synthesize the compound 1B-1-2, except that phenylboronic acid S-3 was used instead of naphthalene-2-yl-2-boronic acid.

[0130] MS: $[M+H]^+=337$

SYNTHESIS EXAMPLE 1-1-3 to 1-1-8

Synthesis of the Compound 1B-1-3 to 1B-1-8

[0131] In Synthesis Example 1-1-1, it was synthesized by using the same method to synthesize the compounds 1B-1-3, 1B-1-4, 1B-1-5, 1B-1-6, 1B-1-7, and 1B-1-8, except that the reactants S-5, S-8, S-13, S-14, S-10, and S-9 were used instead of naphthalene-2-yl-2-boronic acid.

SYNTHESIS EXAMPLE 1-2-No.

Synthesis of the Compound 1C-1-No

[0132] The compound 1B-1-No was dissolved in chloroform, and 1 equivalent of N-bromo succinimide was added

thereto, and agitated for 3 to 8 hours at normal temperature. Distilled water was put into the reaction solution, the termination of the reaction was carried out, and the organic material layer was extracted. The reaction solution was concentrated, and recrystallized with EtOH to synthesize the compound 1C-1-No, and the results are described in Table 1-2-1.

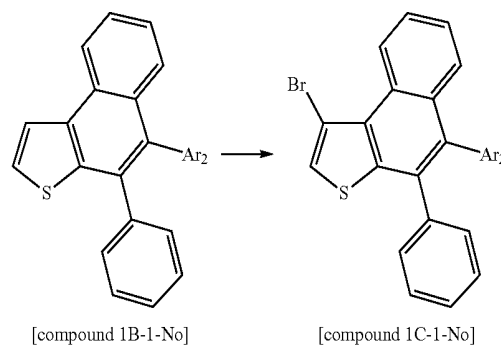
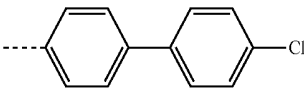
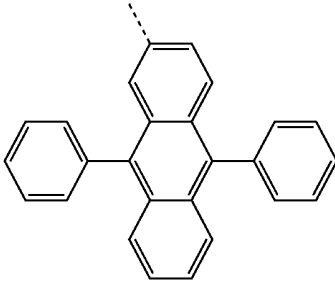
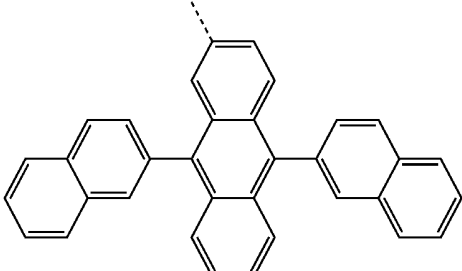


TABLE 1-2-1

Syn. Ex.	Product	Reactant	MS
1-2-No	1C-1-No	1B-1-No Ar ₂	[M] ⁺
1-2-1	compound 1C-1-1	compound 1B-1-1	465
1-2-2	compound 1C-1-2	compound 1B-1-2	415
1-2-3	compound 1C-1-3	compound 1B-1-3	717
1-2-4	compound 1C-1-4	compound 1B-1-4	667
1-2-5	compound 1C-1-5	compound 1B-1-5	449

TABLE 1-2-1-continued

Syn. Ex. 1-2-No	Product 1C-1-No	Reactant 1B-1-No	Ar2	MS [M] ⁺
1-2-6	compound 1C-1-6	compound 1B-1-6		525
1-2-7	compound 1C-1-7	compound 1B-1-7		667
1-2-8	compound 1C-1-8	compound 1B-1-8		767

SYNTHESIS EXAMPLE 1-2-1

Synthesis of the Compound 1C-1-1

[0133] After the compound 1B-1-1 (2.3 g, 6.0 mmol) was dissolved in DMF 20 mL, NBS (1.1 g, 6.0 mmol) was applied thereto and agitated at normal temperature for 2 hours. After water 50 mL was applied thereto to precipitate the solid, it was filtered, washed with ethanol, and dried to synthesize the compound 1C-1-1 (2.1 g, yield 85%).

[0134] MS [M]⁺=465

SYNTHESIS EXAMPLE 1-2-2

Synthesis of the Compound 1C-1-2

[0135] In Synthesis Example 1-2-1, it was synthesized by using the same method to synthesize the compound 1C-1-2, except that the compound 1B-1-2 was used instead of the compound 1B-1-1.

[0136] MS: [M]⁺=415

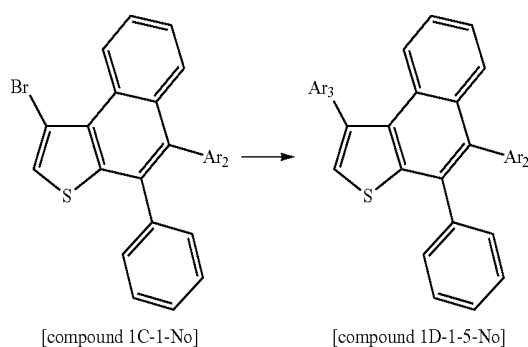
SYNTHESIS OF SYNTHESIS EXAMPLE 1-2-3
TO 1-2-8. SYNTHESIS OF THE COMPOUNDS
1C-1-3 TO 1C-1-8

[0137] In Synthesis Example 1-2-1, it was synthesized by using the same method to synthesize the compounds 1C-1-3, 1C-1-4, 1C-1-5, 1C-1-6, 1C-1-7, 1C-1-8, except that the compounds 1B-1-3, 1B-1-4, 1B-1-5, 1B-1-6, 1B-1-7, and 1B-1-8 were used instead of the compound 1B-1-1.

GENERAL SYNTHESIS EXAMPLE 1-3-No.

Synthesis of the Compound 1D-1~5-No

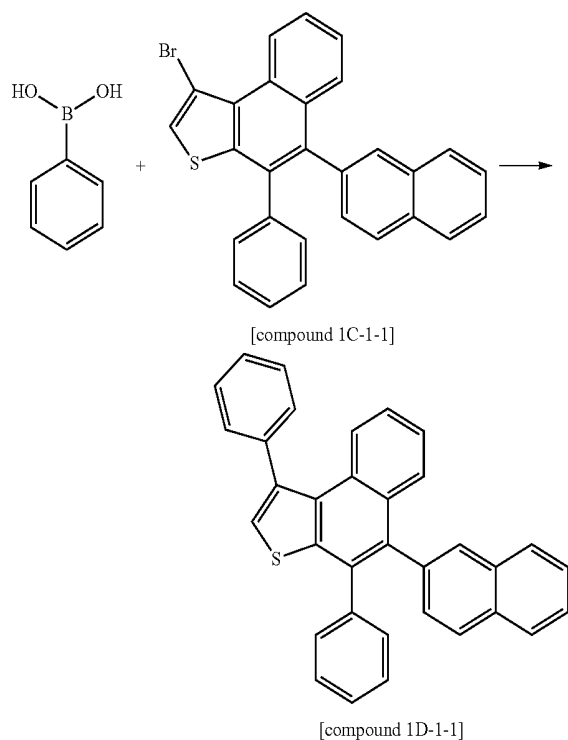
[0138] The compound 1C-1-No, and 1 to 1.5 equivalents of the substituted or unsubstituted arylboronic acid (or arylboron ester) or the substituted or unsubstituted heteroarylboronic acid (or arylboron ester) like the reactant S-No, described in Table 1-1 were put, dissolved in THF, 0.02 equivalents of Pd(PPh₃) and 2 equivalents or more of 2M K₂CO₃/H₂O aqueous solution were added, and heated and agitated for 3 to 16 hours. The reaction mixture was cooled to normal temperature, filtered or extracted with the organic solvent, separated, purified, and dried to synthesize the 1D-1-5-No compound.



SYNTHESIS EXAMPLE 1-3-1

Synthesis of the Compound 1D-1-1

[0139]



[0140] Phenyl boronic acid (1 g, 8.2 mmol), the compound 1C-1-1 (2.1 g, 5.1 mmol), and sodium carbonate (1.4 g, 10.2

mmol) were suspended in the mixture of toluene (50 mL), ethanol (10 mL) and water (20 mL). To the suspension solution, tetrakis(triphenylphosphine)palladium (0.12 g, 1.0 mmol) was applied. The mixture was refluxed and agitated for about 15 hours, and the refluxed mixture was cooled to room temperature. The organic material layer was separated, washed with water, and the aqueous layer was extracted with chloroform. The organic extract was dried on magnesium sulfate and concentrated under the vacuum to synthesize the compound 1D-1-1 (1.8 g, yield 77%).

SYNTHESIS EXAMPLE 1-3-2

Synthesis of the Compound 1D-1-2

[0141] In Synthesis Example 1-3-1, it was synthesized by using the same method to synthesize the compound 1D-1-2, except that the reactant S-1 was used instead of the phenyl boronic acid reactant S-3.

SYNTHESIS EXAMPLE 1-3-3

Synthesis of the Compound 1D-1-3

[0142] In Synthesis Example 1-3-1, it was synthesized by using the same method to synthesize the compound 1D-1-3, except that the reactant S-11 was used instead of the phenyl boronic acid reactant S-3.

SYNTHESIS EXAMPLE 1-3-4 TO 1-3-8

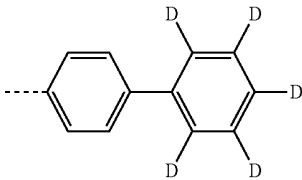
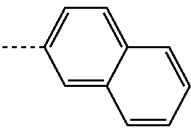
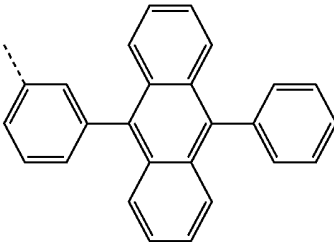
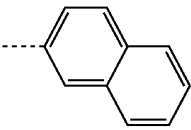
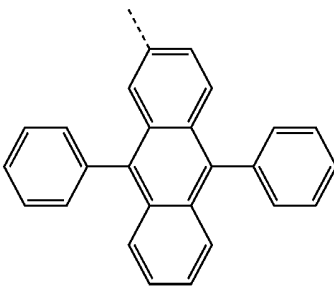
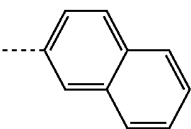
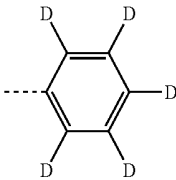
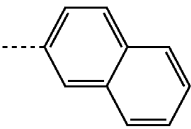
Synthesis of the Compounds 1D-1-4 to 1D-1-8

[0143] In Synthesis Example 1-3-1, it was synthesized by using the same method to synthesize the compounds 1D-1-4, 1D-1-5, 1D-1-6, 1D-1-7, and 1D-1-8, except that the reactants S-20, S-12, S-8, S-10, and S-4 were used instead of the phenyl boronic acid reactant S-3.

TABLE 1-3-1

Syn. Ex. 1-3-No	Product 1D-1-No	Ar3	Ar2	MS [M + H] ⁺
1-3-1	compound 1D-1-1			463
1-3-2	compound 1D-1-2			513
1-3-3	compound 1D-1-3			539
1-3-4	compound 1D-1-4			621

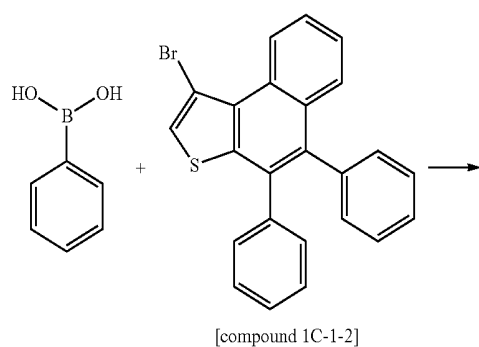
TABLE 1-3-1-continued

Syn. Ex. 1-3-No	Product 1D-1-No	Ar3	Ar2	MS [M + H] ⁺
1-3-5	compound 1D-1-5			544
1-3-6	compound 1D-1-6			715
1-3-7	compound 1D-1-7			715
1-3-8	compound 1D-1-8			468

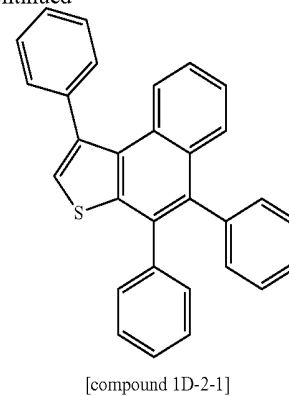
SYNTHESIS EXAMPLE 1-4-1

Synthesis of the Compounds 1D-2-1

[0144]



-continued



[0145] Phenyl boronic acid S-3 (2.2 g, 18.0 mmol), the compound 1C-1-2 (7.45 g, 16.0 mmol), and sodium carbonate (4.98 g, 36.0 mmol) were suspended in the mixture of

toluene (150 mL), ethanol (20 mL) and water (40 mL). To the suspension solution, tetrakis(triphenylphosphine)palladium (0.24 g, 2.00 mmol) was applied. The mixture was refluxed and agitated for about 15 hours, and the refluxed mixture was cooled to room temperature. The organic material layer was separated, washed with water, and the aqueous layer was extracted with chloroform. The organic extract was dried on magnesium sulfate and concentrated under the vacuum to synthesize the compound 1D-2-1 (6.7 g, yield 90%).

SYNTHESIS EXAMPLE 1-4-2 TO 1-4-12

Synthesis of the Compounds 1D-2-2 to 1D-2-12

[0146] In Synthesis Example 1-4-1, it was synthesized by using the same method to synthesize the compounds 1D-2-2 to 1D-2-11, except that the reactants S-1, S-11, S-20, S-12, S-8, S-10, S-4, S-19, S-15, and S-17 were used instead of the phenyl boronic acid reactant S-3.

[0147] The results are described in Table 1-4-1.

TABLE 1-4-1

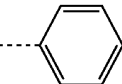
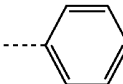
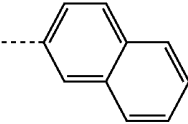
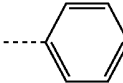
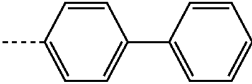
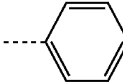
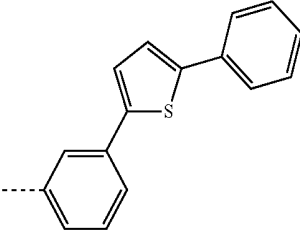
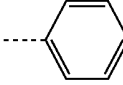
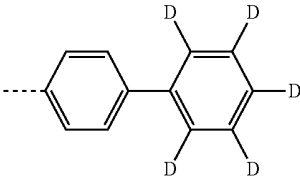
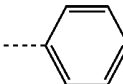
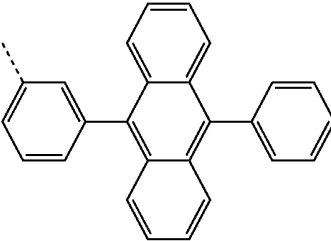
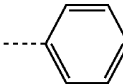
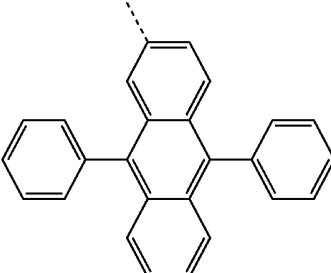
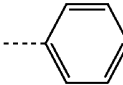
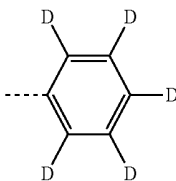
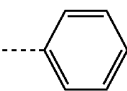
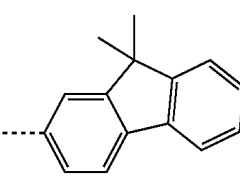
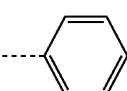
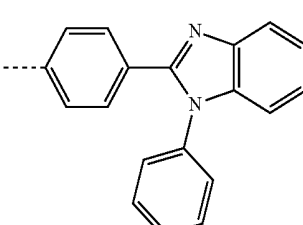
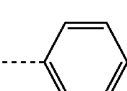
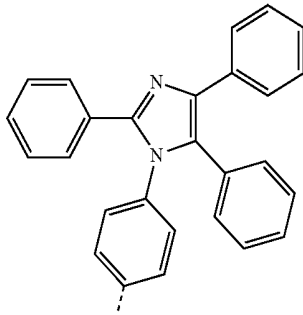
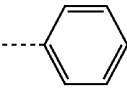
Syn. Ex. 1-4-No	Product 1D-2-No	Ar3	Ar2	MS [M + H] ⁺
1-4-1	compound 1D-2-1			413
1-4-2	compound 1D-2-2			463
1-4-3	compound 1D-2-3			489
1-4-4	compound 1D-2-4			571
1-4-5	compound 1D-2-5			494
1-4-6	compound 1D-2-6			665
1-4-7	compound 1D-2-7			665

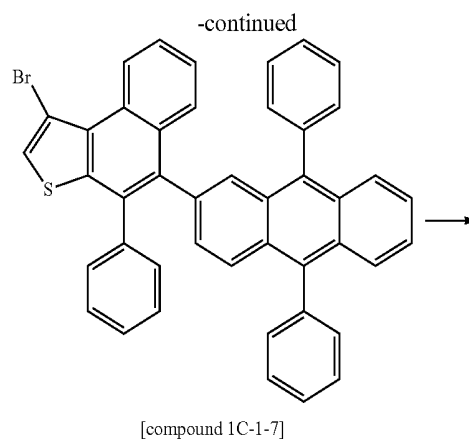
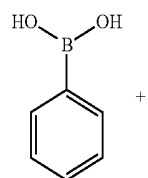
TABLE 1-4-1-continued

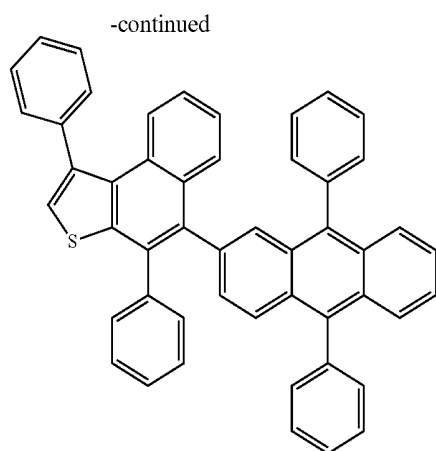
Syn. Ex. 1-4-No	Product 1D-2-No	Ar3	Ar2	MS [M + H] ⁺
1-4-8	compound 1D-2-8			418
1-4-9	compound 1D-2-9			529
1-4-10	compound 1D-2-10			605
1-4-11	compound 1D-2-11			707

SYNTHESIS EXAMPLE 1-5-1

Synthesis of the Compound 1D-3-1

[0148]





[compound 1D-3-1]

[0149] Phenyl boronic acid S-3 (2.2 g, 18.0 mmol), the compound 1C-1-7 (10.68 g, 16.0 mmol), and sodium carbonate (4.98 g, 36.0 mmol) were suspended in the mixture of toluene (150 mL), ethanol (20 mL) and water (40 mL). To the

suspension solution, tetrakis(triphenylphosphine)palladium (0.24 g, 2.0 mmol) was applied. The mixture was refluxed and agitated for about 15 hours, and the refluxed mixture was cooled to room temperature. The formed solid was filtered and washed with water and ethanol. It was dried in the oven under the vacuum to synthesize the compound 1D-3-1 (9.26 g, yield 87%).

SYNTHESIS EXAMPLE 1-5-2

Synthesis of the Compound 1D-3-2

[0150] In Synthesis Example 1-5-1, it was synthesized by using the same method to synthesize the compound 1D-3-2, except that the reactant S-1 was used instead of the reactant S-3.

SYNTHESIS EXAMPLE 1-5-3 TO 1-5-5

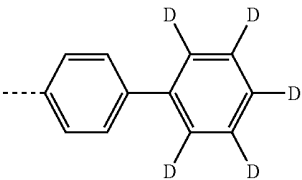
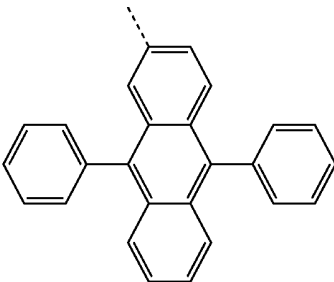
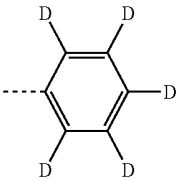
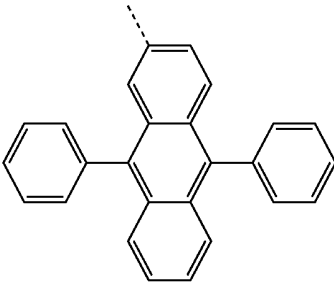
Synthesis of the Compounds 1D-3-3 to 1D-3-5

[0151] In Synthesis Example 1-5-1, it was synthesized by using the same method to synthesize the compounds 1D-3-3 to 1D-3-13, except that the reactants S-11, S-12, and S-4 were used instead of the phenyl boronic acid reactant S-3.

TABLE 1-5-1

Syn. Ex.	Product	Ar3	Ar2	MS [M + H] ⁺
1-5-1	compound 1D-3-1			665
1-5-2	compound 1D-3-2			715
1-5-3	compound 1D-3-3			741

TABLE 1-5-1-continued

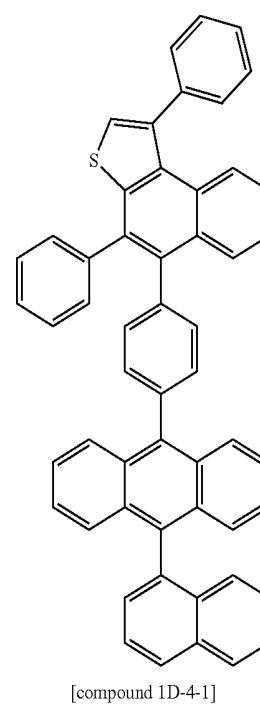
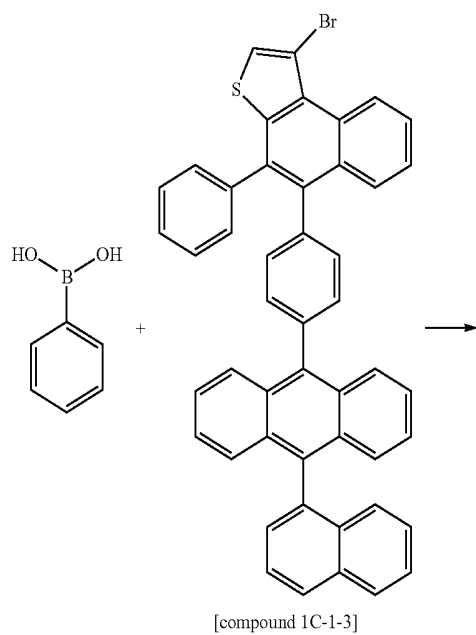
Syn. Ex. 1-5-No	Product 1D-3-No	Ar3	Ar2	MS [M + H] ⁺
1-5-4	compound 1D-3-4			746
1-5-5	compound 1D-3-5			670

SYNTHESIS EXAMPLE 1-6-1

Synthesis of the Compound 1D-4-1

-continued

[0152]



[0153] Phenyl boronic acid S-3 (2.2 g, 18.0 mmol), the compound 1C-1-3 (10.68 g, 16.0 mmol), and sodium carbonate (4.98 g, 36.0 mmol) were suspended in the mixture of toluene (150 mL), ethanol (20 mL) and water (40 mL). To the suspension solution, tetrakis(triphenylphosphine)palladium (0.24 g, 2.0 mmol) was applied. The mixture was refluxed and agitated for about 15 hours, and the refluxed mixture was cooled to room temperature. The formed solid was filtered and washed with water and ethanol. It was dried in the oven under the vacuum to synthesize the compound 1D-4-1 (9.26 g, yield 87%).

SYNTHESIS EXAMPLE 1-6-2

Synthesis of the Compound 1D-4-2

[0154] In Synthesis Example 1-6-1, it was synthesized by using the same method to synthesize the compound 1D-4-2, except that the reactant S-1 was used instead of the phenyl boronic acid reactant S-3.

-continued

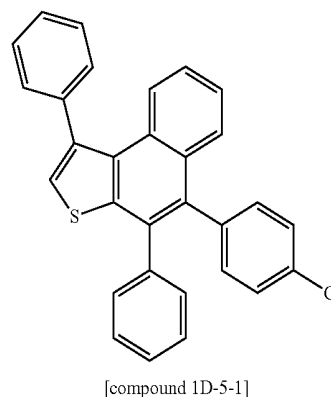


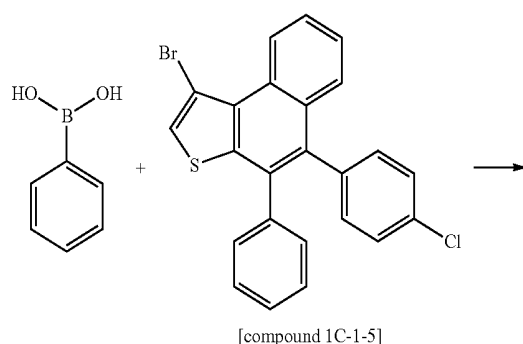
TABLE 1-6-1

Syn. Ex. 1-6-No	Product 1D-4-No	Ar3	Ar2	MS [M + H] ⁺
1-6-1	compound 1D-4-1			714
1-6-2	compound 1D-4-2			764

SYNTHESIS EXAMPLE 1-7-1

Synthesis of the Compound 1D-5-1

[0155]



[0156] Phenyl boronic acid S-3 (2.44 g, 20.0 mmol), the compound 1C-1-5 (8.1 g, 18.0 mmol), and sodium carbonate (4.98 g, 36.0 mmol) were suspended in the mixture of toluene (150 mL), ethanol (20 mL) and water (40 mL). To the suspension solution, tetrakis(triphenylphosphine)palladium (0.24 g, 2.0 mmol) was applied. The mixture was refluxed and agitated for about 15 hours, and the refluxed mixture was cooled to room temperature. The formed solid was filtered and washed with water and ethanol. It was dried in the oven under the vacuum to synthesize the compound 1D-5-1 (7.08 g, yield 88%).

SYNTHESIS EXAMPLE 1-7-2 TO 1-7-3

Synthesis of the Compounds 1D-5-2 to 1D-5-3

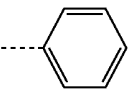
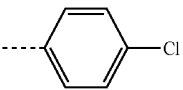
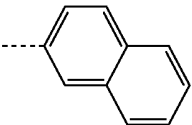
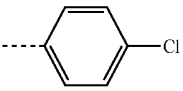
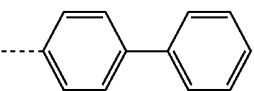
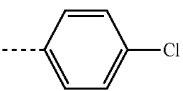
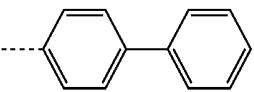
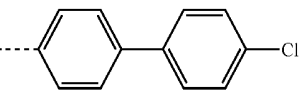
[0157] In Synthesis Example 1-7-1, it was synthesized by using the same method to synthesize the compounds 1D-5-2 to 1D-5-3, except that the reactants S-1, and S-11 were used instead of the phenyl boronic acid reactant S-3.

SYNTHESIS EXAMPLE 1-7-4

Synthesis of the Compound 1D-5-4

[0158] In Synthesis Example 1-7-4, it was synthesized by using the same method to synthesize the compound 1D-5-4, except that the reactant S-11 was used instead of the phenyl boronic acid reactant S-3 and the compound 1C-1-6 was used instead of the compound 1C-1-5.

TABLE 1-7-1

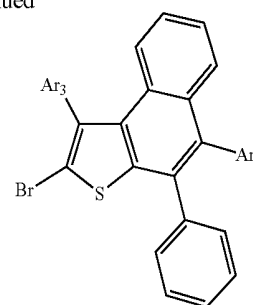
Syn. Ex. 1-7-No	Product 1D-5-No	Ar3	Ar2	MS [M + H] ⁺
1-7-1	compound 1D-5-1			447
1-7-2	compound 1D-5-2			496
1-7-3	compound 1D-5-3			522
1-7-4	compound 1D-5-4			599

GENERAL SYNTHESIS EXAMPLE 1-8~11-No

Synthesis of the Compound 1E-1~4-No

[0159] The compounds 1D-1-No to 1D-5-No were dissolved in chloroform, and 1 equivalent of N-bromo succinimide was added thereto, and agitated for 3 to 6 hours at normal temperature. The solid was formed by applying distilled water to the reaction solution, filtered and dried, and recrystallized with CHCl₃/EtOH to synthesize the compounds 1E-1-No, 1E-2-No, 1E-3-No, and 1E-4-No.

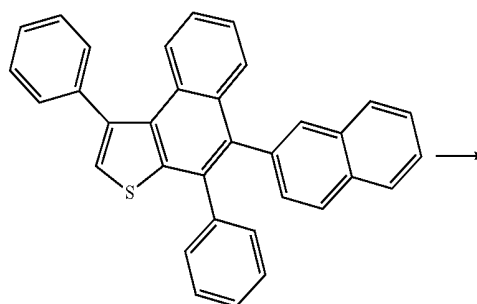
-continued



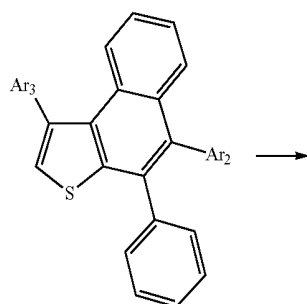
[compound 1E-1-No]

SYNTHESIS EXAMPLE 1-8-1
Synthesis of the Compound 1E-1-1

[0160]

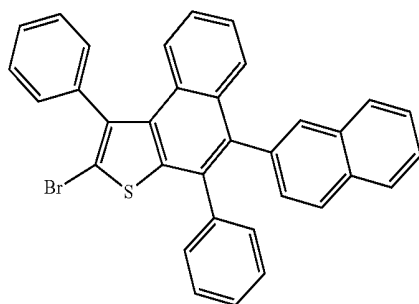


[compound 1D-1-1]



[compound 1D-1-No to 1D-5-No]

-continued



[compound 1E-11]

[0161] After the compound 1D-1-1 (4.6 g, 10.0 mmol) was dissolved in DMF 40 mL, NBS (1.8 g, 10.0 mmol) was applied thereto and agitated at normal temperature for 3 hours. After water 100 mL was applied thereto to precipitate the solid, it is filtered, washed with ethanol, and dried to synthesize the compound 1E-1-1 (4.98 g, yield 92%).

SYNTHESIS EXAMPLE 1-8-2 TO 1-11-5

Synthesis of the Compounds 1E-1-2 to 1E-4-5

[0162] The compound was manufactured by using the same method as Synthesis Example 1-8-1, except that the corresponding compounds 1D-1-No to 1D-5-No were used instead of the compound 1D-1-1. The results are described in the following Tables 1-8-1 to 1-11-1.

TABLE 1-8-1

Syn. Ex. 1-8-No	Product 1E-1-No	Ar3	Ar2	MS [M] ⁺
1-8-1	compound 1E-1-1			541
1-8-2	compound 1E-1-2			591
1-8-3	compound 1E-1-3			617
1-8-4	compound 1E-1-4			699
1-8-5	compound 1E-1-5			622

TABLE 1-8-1-continued

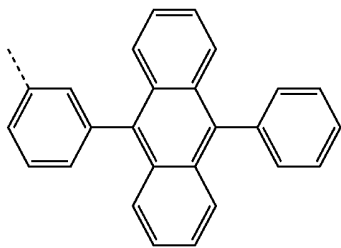
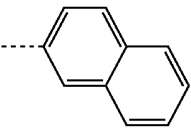
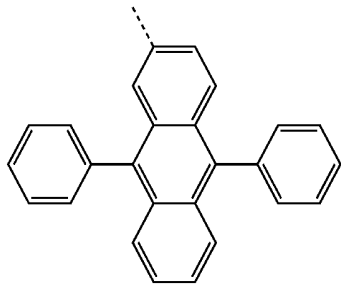
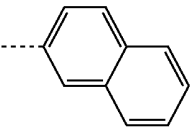
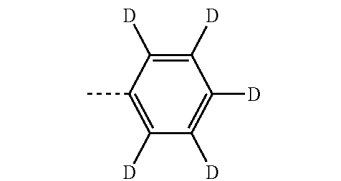
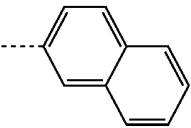
Syn. Ex. 1-8-No	Product 1E-1-No	Ar3	Ar2	MS [M] ⁺
1-8-6	compound 1E-1-6			793
1-8-7	compound 1E-1-7			793
1-8-8	compound 1E-1-8			546

TABLE 1-9-1

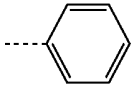
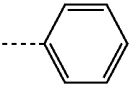
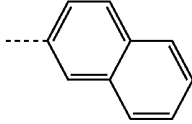
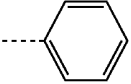
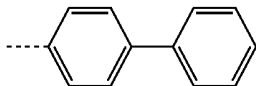
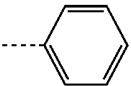
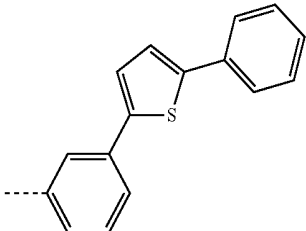
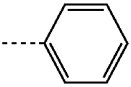
Syn. Ex. 1-9-No	Product 1E-2-No	Ar3	Ar2	MS [M] ⁺
1-9-1	compound 1E-2-1			491
1-9-2	compound 1E-2-2			541
1-9-3	compound 1E-2-3			567
1-9-4	compound 1E-2-4			649

TABLE 1-9-1-continued

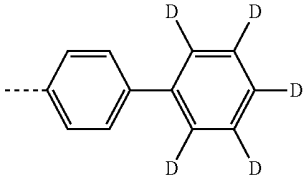
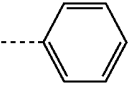
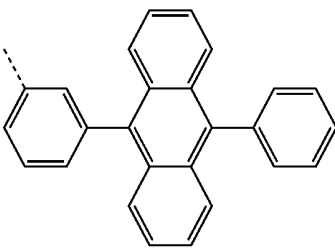
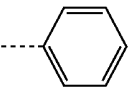
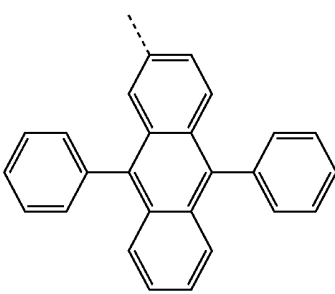
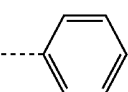
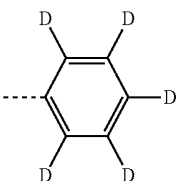
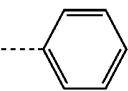
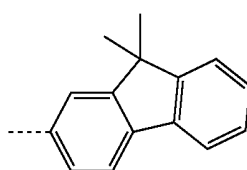
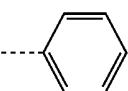
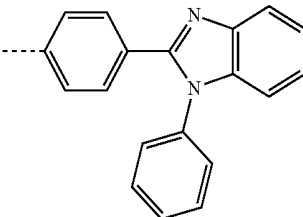
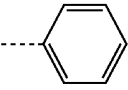
Syn. Ex. 1-9-No	Product 1E-2-No	Ar3	Ar2	MS [M] ⁺
1-9-5	compound 1E-2-5			572
1-9-6	compound 1E-2-6			743
1-9-7	compound 1E-2-7			743
1-9-8	compound 1E-2-8			496
1-9-9	compound 1E-2-9			607
1-9-10	compound 1E-2-10			683

TABLE 1-9-1-continued

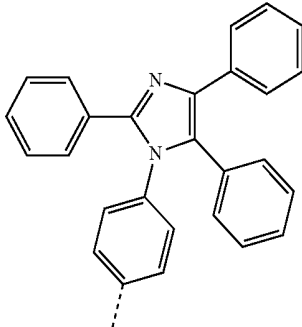
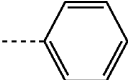
Syn. Ex. 1-9-No	Product 1E-2-No	Ar3	Ar2	MS [M] ⁺
1-9-11	compound 1E-2-11			755

TABLE 1-10-1

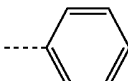
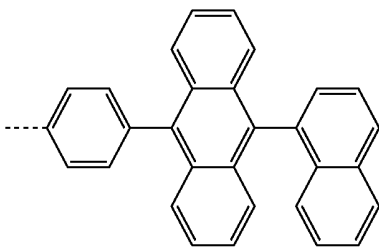
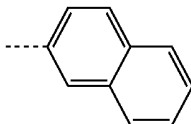
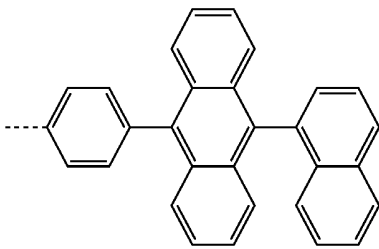
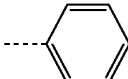
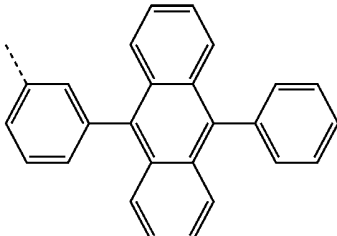
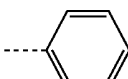
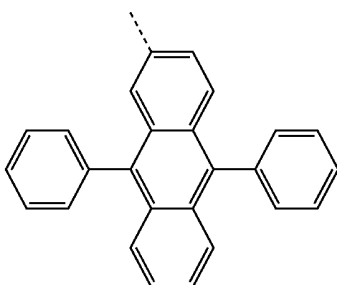
Syn. Ex. 1-10-No	Product 1E-3-No	Ar3	Ar2	MS [M] ⁺
1-10-1	compound 1E-3-1			793
1-10-2	compound 1E-3-2			843
1-10-3	compound 1E-3-3			743
1-10-4	compound 1E-3-4			743

TABLE 1-10-1-continued

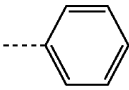
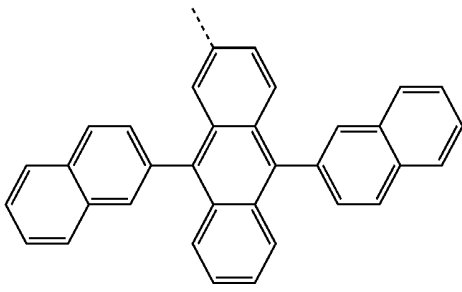
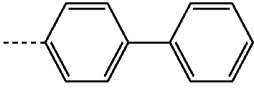
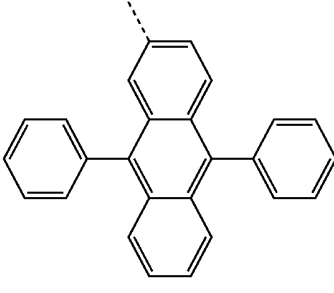
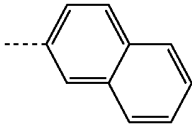
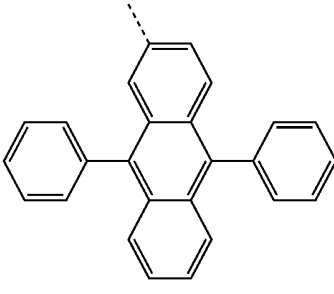
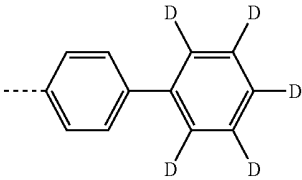
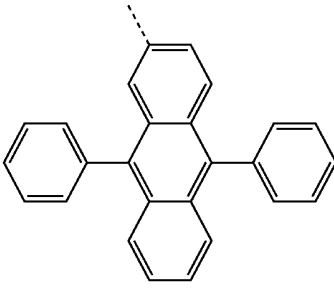
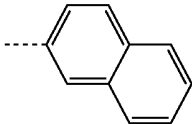
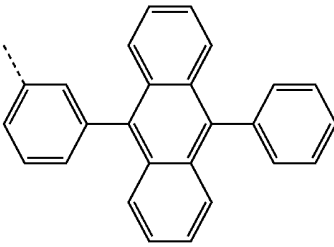
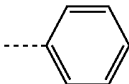
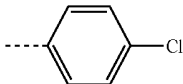
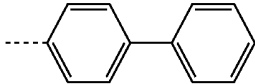
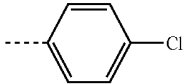
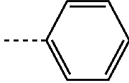
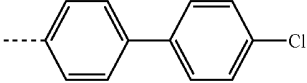
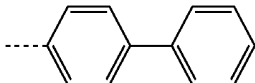
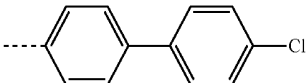
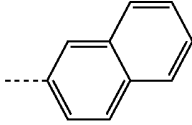
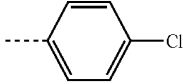
Syn. Ex.	Product	Ar3	Ar2	MS [M] ⁺
1-10-5	compound 1E-3-5			843
1-10-6	compound 1E-3-6			819
1-10-7	compound E-3-7			793
1-10-8	compound E-3-8			824
1-10-9	compound 1E-3-9			793

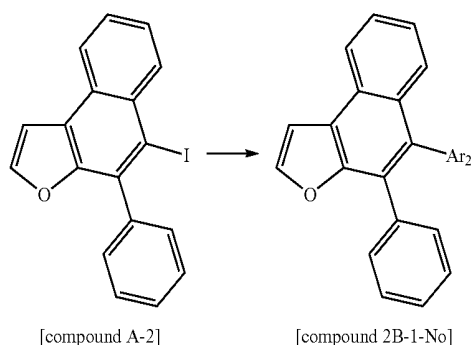
TABLE 1-11-1

Syn. Ex. 1-11-No	Product 1E-4-No	Ar3	Ar2	MS [M] ⁺
1-11-1	compound 1E-4-1			525
1-11-2	compound 1E-4-2			601
1-11-3	compound 1E-4-3			601
1-11-4	compound 1E-4-4			677
1-11-5	compound 1E-4-5			575

SYNTHESIS EXAMPLE 2-1-No

Synthesis of the Compound 2B-1-No

[0163] The compound A-2, and 1 to 1.5 equivalents of the substituted or unsubstituted arylboronic acid (or arylboron ester) or the substituted or unsubstituted heteroarylboronic acid (or arylboron ester) like the reactant S—No. described in Table 1 were put, dissolved in THF, 0.02 equivalents of Pd(PPh₃) and 2 equivalents or more of 2M K₂CO₃/H₂O aqueous solution were added, and heated and agitated for 3 to 16 hours. The reaction mixture was cooled to normal temperature, filtered or extracted with the organic solvent, separated, purified, and dried to synthesize the 2B-1-No compound, and the results thereof are described in Table 2-1-1.



SYNTHESIS EXAMPLE 2-1-1

Synthesis of the Compound 2B-1-1

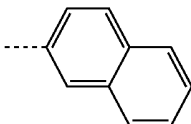
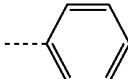
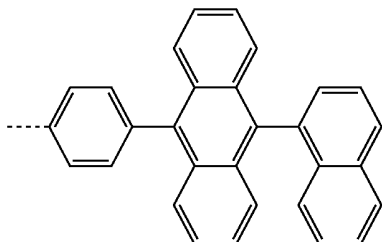
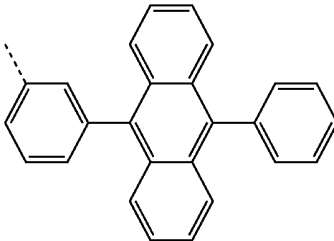
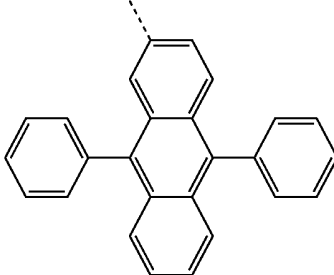
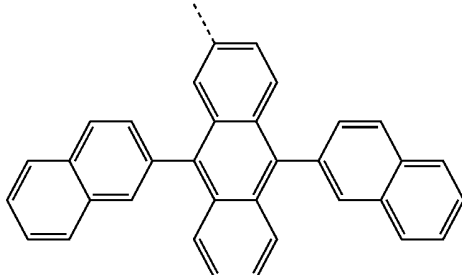
[0164] In Synthesis Example 1-1-1, the compound 2B-1-1 was synthesized by using the same method, except that naphthalene-2-yl-2-boronic acid that was the reactant S-1 of Table 1 and the compound A-2 were used.

SYNTHESIS EXAMPLE 2-1-2 TO 2-1-6

Synthesis of the Compounds 2B-1-2 to 2B-1-6

[0165] In Synthesis Example 2-1-1, it was synthesized by using the same method to synthesize the compounds 2B-1-2, 2B-1-3, 2B-1-4, 2B-1-5, and 2B-1-6, except that the reactants S-3, S-5, S-8, S-10, and S-9 were used instead of naphthalene-2-yl-2-boronic acid.

TABLE 2- 1- 1

Syn. Ex. 2-1-No	Product 2B-1-No	reactant	Ar2	MS [M + H] ⁺
2-1-1	compound 2B-1-1	S-1		371
2-1-2	compound 2B-1-2	S-3		321
2-1-3	compound 2B-1-3	S-5		623
2-1-4	compound 2B-1-4	S-8		573
2-1-5	compound 2B-1-5	S-10		572
2-1-6	compound 2B-1-6	S-9		673

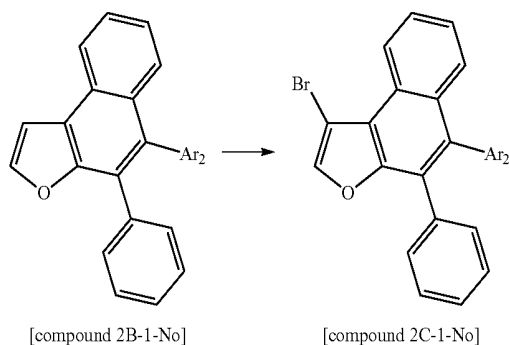
SYNTHESIS EXAMPLE 2-2-No

Synthesis of the Compound 2C-1-No

[0166] The compound 2B-1-No was dissolved in chloroform, and 1 equivalent of N-bromo succinimide was added

thereto, and agitated for 3 to 8 hours at normal temperature. Distilled water was put into the reaction solution, the termination of the reaction was carried out, and the organic material layer was extracted. The reaction solution was concentrated, and recrystallized with EtOH to synthesize the

compound 2C-1-No, and the results are described in Table 2-2-1.



SYNTHESIS EXAMPLE 2-2-1

Synthesis of the Compound 2C-1-1

[0167] In Synthesis Example 1-2-1, it was synthesized by using the same method to synthesize the compound 2C-1-1, except that the compound 2B-1-1 was used instead of the compound 1B-1-1.

SYNTHESIS OF SYNTHESIS EXAMPLES 2-2-2 TO 2-2-6

Synthesis of the Compounds 2C-1-3 to 2C-1-6

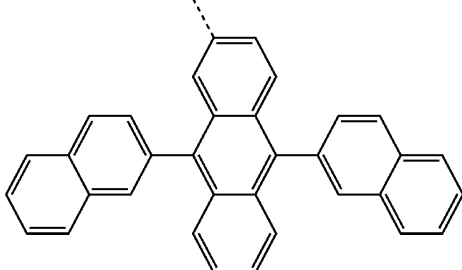
[0168] In Synthesis Example 2-2-1, it was synthesized by using the same method to synthesize the compounds 2C-1-2, 2C-1-3, 2C-1-4, 2C-1-5, and 2C-1-6, except that the compounds 2B-1-2, 2B-1-3, 2B-1-4, 2B-1-5, and 2B-1-6 were used instead of the compound 2B-1-1.

[0169] The results are described in Table 2-2-1.

TABLE 2-2-1

Syn. Ex. 2-2-No	Product 2C-1-No	reactant 2B-1-No	Ar ₂	MS [M] ⁺
2-2-1	compound 2C-1-1	compound 2B-1-1		449
2-2-2	compound 2C-1-2	compound 2B-1-2		399
2-2-3	compound 2C-1-3	compound 2B-1-3		701
2-2-4	compound 2C-1-4	compound 2B-1-4		651
2-2-5	compound 2C-1-5	compound 2B-1-5		651

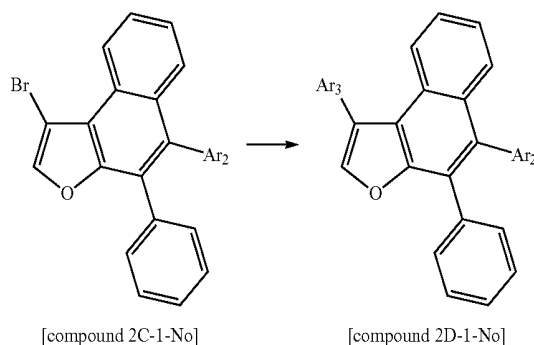
TABLE 2-2-1-continued

Syn. Ex. 2-2-No	Product 2C-1-No	reactant 2B-1-No	Ar2	MS [M] ⁺
2-2-6	compound 2C-1-6	compound 2B-1-6		751

GENERAL SYNTHESIS EXAMPLE 2-3-No

Synthesis of the Compound 2D-1-No

[0170] The compound 2C-1-No, and 1 to 1.5 equivalents of the substituted or unsubstituted arylboronic acid (or arylboron ester) or the substituted or unsubstituted heteroarylboronic acid (or arylboron ester) like the reactant S—No. described in Table 1 were put, dissolved in THF, 0.02 equivalents of Pd(PPh₃) and 2 equivalents or more of 2M K₂CO₃/H₂O aqueous solution were added, and heated and agitated for 3 to 16 hours. The reaction mixture was cooled to normal temperature, filtered or extracted with the organic solvent, separated, purified, and dried to synthesize the 2D-1-No compound.



SYNTHESIS EXAMPLE 2-3-1

Synthesis of the Compound 2D-1-1

[0171] In Synthesis Example 1-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-1, except that the phenyl boronic acid reactant S-3 and the compound 2C-1-1 were used instead of the compound 1C-1-1.

SYNTHESIS EXAMPLE 2-3-2

Synthesis of the Compound 2D-1-2

[0172] In Synthesis Example 2-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-2, except that the reactant S-1 was used instead of the phenyl boronic acid reactant S-3.

SYNTHESIS EXAMPLE 2-3-3

Synthesis of the Compound 2D-1-3

[0173] In Synthesis Example 2-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-3, except that the reactant S-1 was used instead of the phenyl boronic acid reactant S-3 and the compound 2C-1-2 was used instead of the compound 2C-1-1.

SYNTHESIS EXAMPLE 2-3-4

Synthesis of the Compound 2D-1-4

[0174] In Synthesis Example 2-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-4, except that the compound 2C-1-3 was used instead of the compound 2C-1-1.

SYNTHESIS EXAMPLE 2-3-5

Synthesis of the Compound 2D-1-5

[0175] In Synthesis Example 2-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-5, except that the reactant S-11 was used instead of the phenyl boronic acid reactant S-3 and the compound 2C-1-4 was used instead of the compound 2C-1-1.

SYNTHESIS EXAMPLE 2-3-6

Synthesis of the Compound 2D-1-6

[0176] In Synthesis Example 2-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-6, except that the reactant S-4 was used instead of the phenyl boronic acid reactant S-3 and the compound 2C-1-5 was used instead of the compound 2C-1-1.

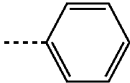
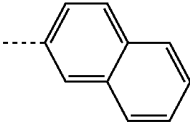
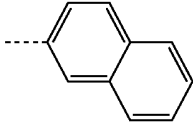
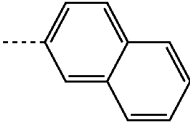
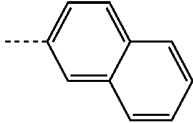
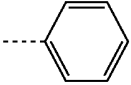
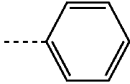
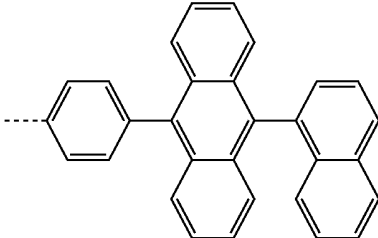
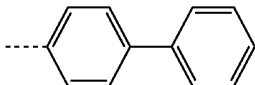
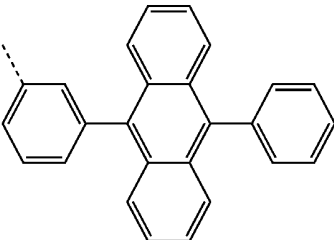
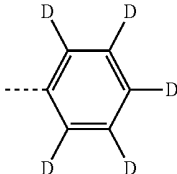
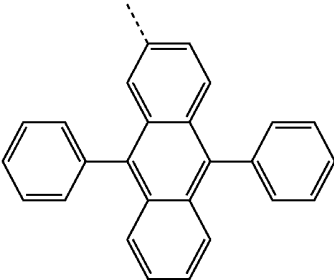
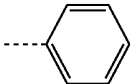
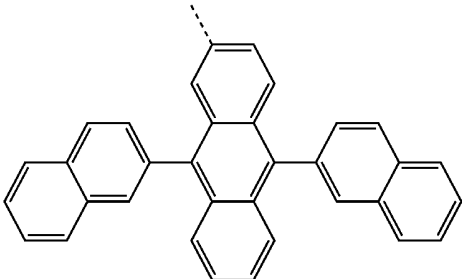
SYNTHESIS EXAMPLE 2-3-7

Synthesis of the Compound 2D-1-7

[0177] In Synthesis Example 2-3-1, it was synthesized by using the same method to synthesize the compound 2D-1-7, except that the compound 2C-1-6 was used instead of the compound 2C-1-1.

[0178] The results are described in Table 2-3-1.

TABLE 2-3-1

Syn. Ex. 2-3-No	Product 2D-1-No	Ar3	Ar2	MS [M + H] ⁺
2-3-1	compound 2D-1-1			447
2-3-2	compound 2D-1-2			497
2-3-3	compound 2D-1-3			447
2-3-4	compound 2D-1-4			699
2-3-5	compound 2D-1-5			725
2-3-6	compound 2D-1-6			654
2-3-7	compound 2D-1-7			749

SYNTHESIS EXAMPLE 2-4-1 TO 2-4-7

Synthesis of the Compounds 2E-1-1 to 2E-1-7

[0179] In Synthesis Example 1-4-1, it was synthesized by using the same method to synthesize the compounds 2E-1-1 to 2E-1-7, except that the compounds 2D-1-1 to 2D-1-7 were used instead of the compound 1-4-1.

TABLE 2-4-1

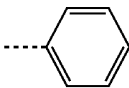
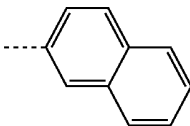
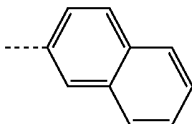
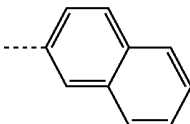
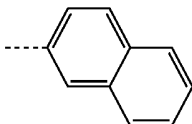
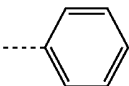
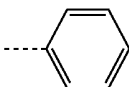
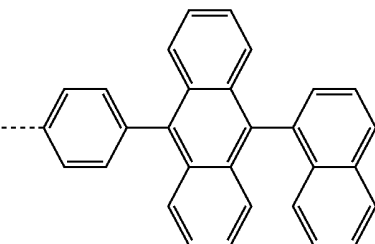
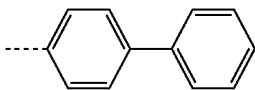
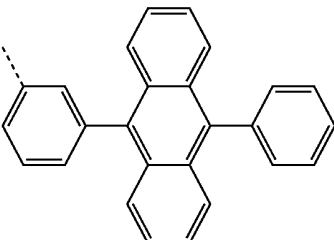
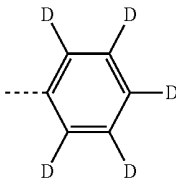
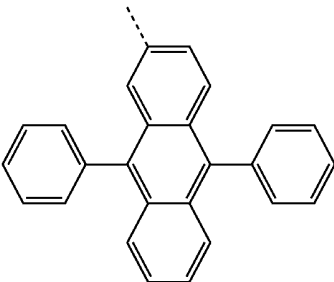
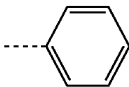
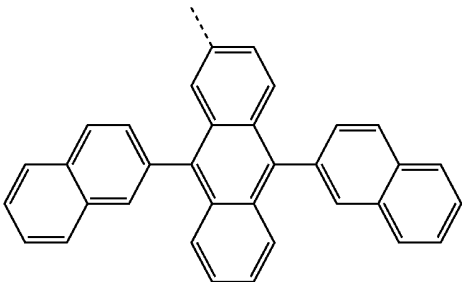
Syn. Ex.	Product	Ar3	Ar2	MS [M] ⁺
2-4-1	compound 2E-1-1			525
2-4-2	compound 2E-1-2			575
2-4-3	compound 2E-1-3			525
2-4-4	compound 2E-1-4			696
2-4-5	compound 2E-1-5			724

TABLE 2-4-1-continued

Syn. Ex. 2-4-No	Product 2E-1-No	Ar3	Ar2	MS [M] ⁺
2-4-6	compound 2E-1-6			653
2-4-7	compound 2E-1-7			748

SYNTHESIS EXAMPLE 3-1-1

Synthesis of the Compound 1F-1-1

-continued

[0180]

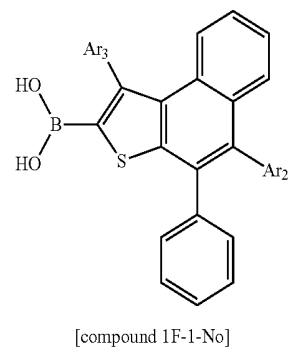
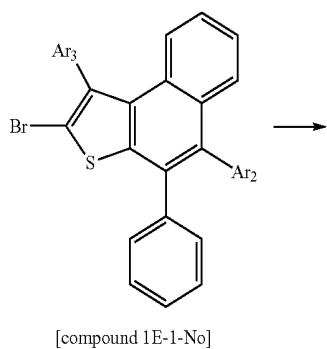
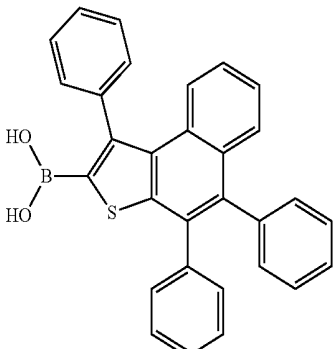
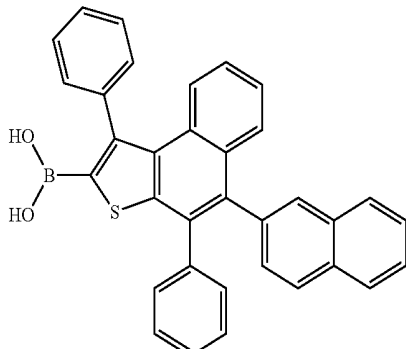
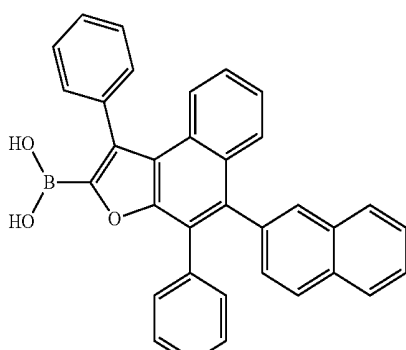


TABLE 3-1-1

Syn. Ex. 3-1-No	Product 1F-1-No	MS [M + H] ⁺
3-1-1 compound 1F-1-1		457
3-1-2 compound 1F-1-2		507
3-1-3 compound 1F-1-3		491

[0181] To the compound 1E-2-1 (20.3 g, 41.3 mmol) solution that was manufactured in Synthesis Example 1-9-1 in anhydrous THF (50 mL), n-BuLi (61.9 mmol, 24.8 mL in 2.5 M hexane solution) was dropped under the nitrogen atmosphere at -78°C . After the mixture was agitated for about 1 hour, trimethyl borate (14 mL, 123.9 mmol) was dropped at -78°C . After about 30 min, the cooling vessel was removed, and the mixture was agitated at room temperature for about 3 hours. 1N HCl (200 mL) was added to the above mixture, and extracted with ethyl acetate. The organic material layer was dried on magnesium sulfate and concentrated under the vacuum. The crude product was agitated with petroleum ether and precipitated, filtered, and dried to synthesize the compound 1F-1-1 (11.9 g, yield 63%).

SYNTHESIS EXAMPLE 3-1-2

Synthesis of the Compound 1F-1-2

[0182] In Synthesis Example 3-1-1, it was synthesized by using the same method to synthesize the compound 1F-1-2, except that the compound 1E-1-1 was used instead of the compound 1E-2-1.

SYNTHESIS EXAMPLE 3-1-3

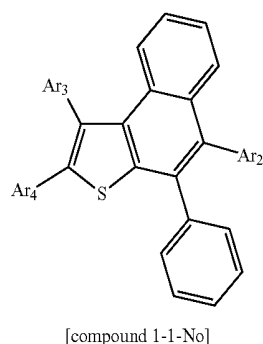
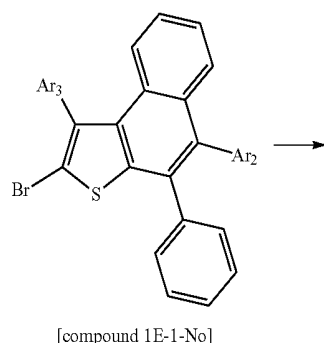
Synthesis of the Compound 1F-1-3

[0183] In Synthesis Example 3-1-1, it was synthesized by using the same method to synthesize the compound 1F-1-3, except that the compound 2E-1-1 was used instead of the compound 1E-2-1.

PREPARATION EXAMPLE 1-1-No

Preparation of the Compound 1-1-No

[0184]

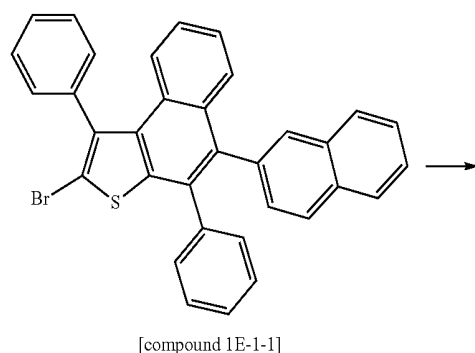


[0185] The compound 1E-1-No, and 1 to 1.5 equivalents of the substituted or unsubstituted arylboronic acid (or arylboron ester) or the substituted or unsubstituted heteroarylboronic acid (or arylboron ester) were put, dissolved in THF, 0.02 equivalents of Pd(PPh₃) and 2 equivalents or more of 2M K₂CO₃/H₂O aqueous solution were added, and heated and agitated for 3 to 16 hours. The reaction mixture was cooled to normal temperature, filtered or extracted with the organic solvent, separated, purified, and dried to prepare the following 1-1-No compound, and the results thereof are described in Table 1-1.

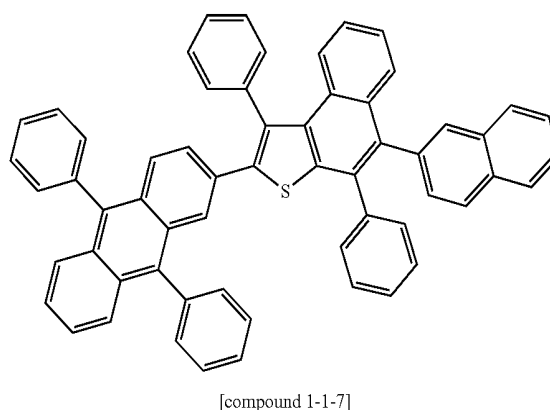
PREPARATION EXAMPLE 1-1-7

Preparation of the Compound 1-1-7

[0186]



-continued



[0187] 2-[9,10-diphenyl-2-anthracenyl]-4,4,5,5-tetramethyl-1,3,2-dioxaborolane (2.2 g, 4.9 mmol) that was the reactant S-10, the compound 1E-1-1 (2.2 g, 4.1 mmol) that was prepared in Synthesis Example 1-8-1, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-1-7 (2.5 g, yield 76%).

PREPARATION EXAMPLE 1-1-1 TO 1-1-6

Preparation of the Compounds 1-1-1 to 1-1-6

[0188] In Synthesis Example 1-1-7, it was synthesized by using the same method to prepare the compounds 1-1-1, 1-1-2, 1-1-3, 1-1-4, 1-1-5, and 1-1-6, except that the reactants S-1, S-11, S-20, S-12, S-8, S-10 were used instead of the reactant S-3.

PREPARATION EXAMPLE 1-1-8 TO
PREPARATION EXAMPLE 1-1-14

Preparation of the Compounds 1-1-8 to 1-1-14

[0189] In Synthesis Example 1-1-7, it was synthesized by using the same method to prepare the compounds 1-1-8, 1-1-9, 1-1-10, 1-1-11, 1-1-12, 1-1-13, and 1-1-14, except that the reactants S-4, S-19, S-15, S-17, S-21, S-18, and S-16 were used instead of the reactant S-3.

[0190] In Preparation Examples 1-1-1 to 1-1-6 and Preparation Examples 1-1-8 to 1-1-14, they were prepared by using the same method as Preparation Example 1-1-7 by using the compound 1E-1-1 and boronic acid or boron ester compounds in the reactants of Table 1.

TABLE 1-1

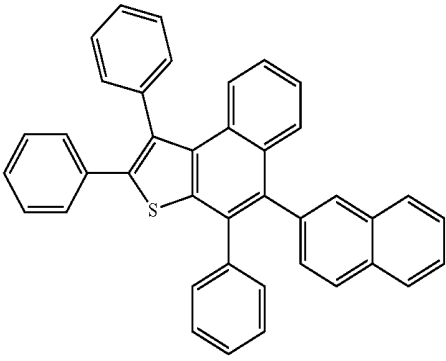
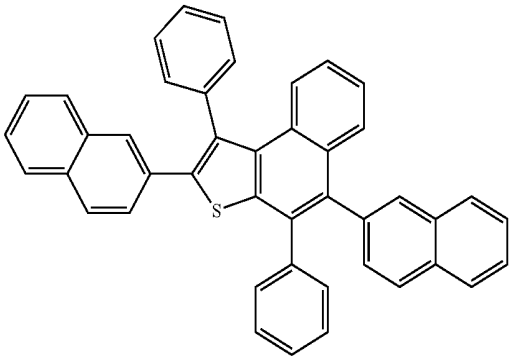
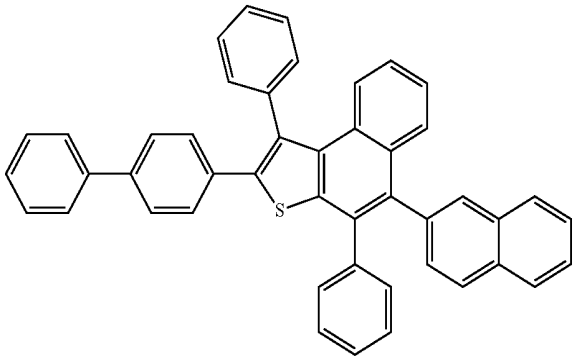
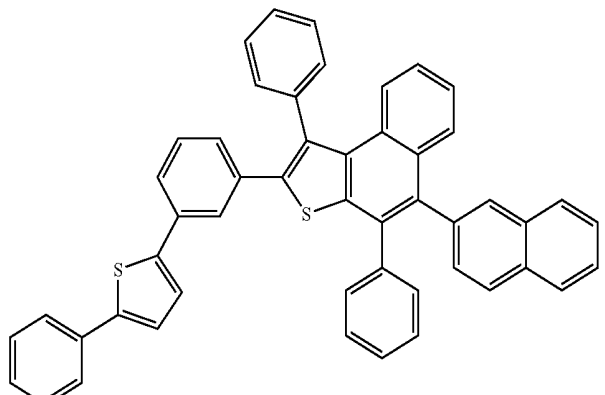
Prep. Ex. 1-1-No	Product 1-1-No	structure	MS [M + H] ⁺
1-1-1	compound 1-1-1		539
1-1-2	compound 1-1-2		589
1-1-3	compound 1-1-3		615
1-1-4	compound 1-1-4		697

TABLE 1-1-continued

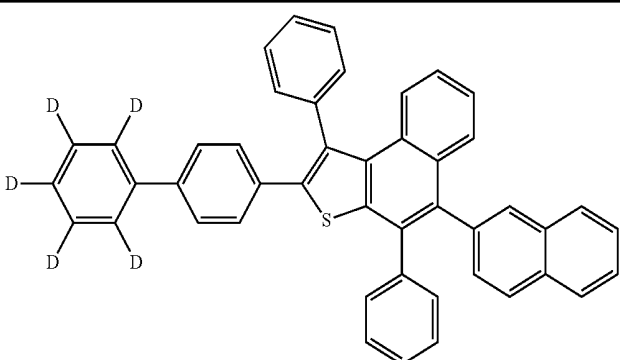
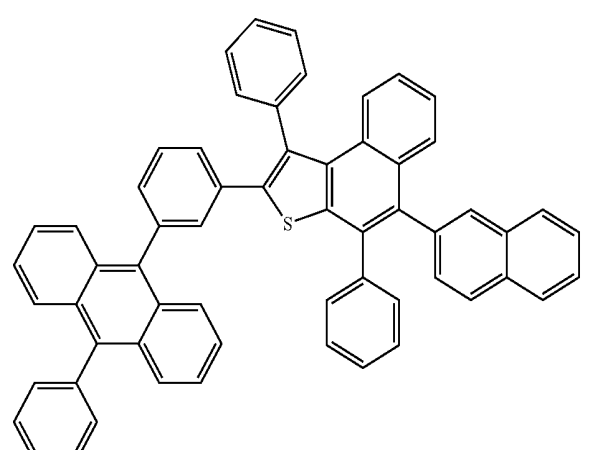
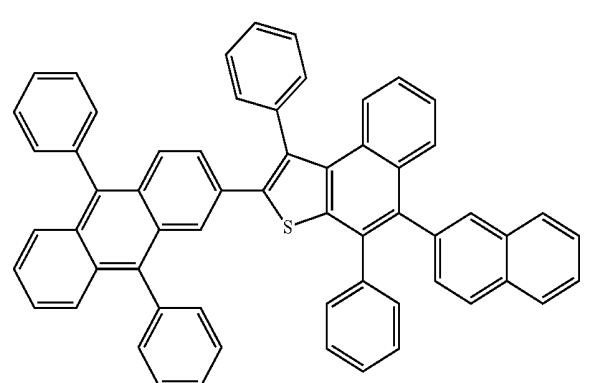
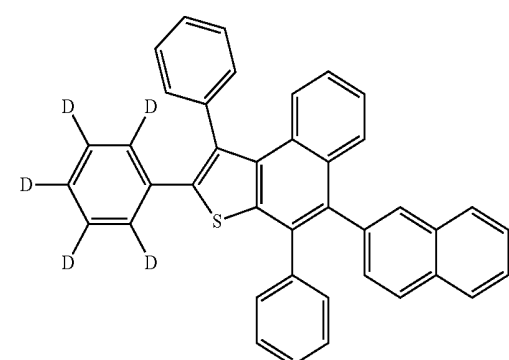
Prep. Ex. 1-1-No	Product 1-1-No	structure	MS [M + H] ⁺
1-1-5	compound 1-1-5		620
1-1-6	compound 1-1-6		791
1-1-7	compound 1-1-7		791
1-1-8	compound 1-1-8		544

TABLE 1-1-continued

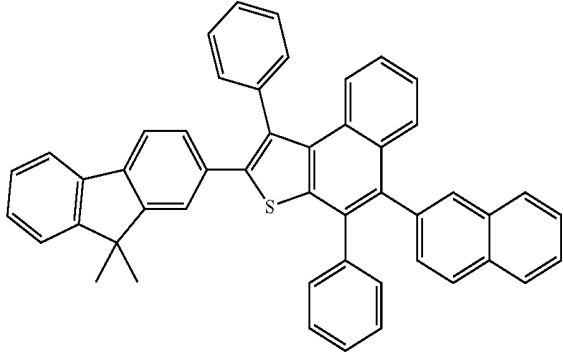
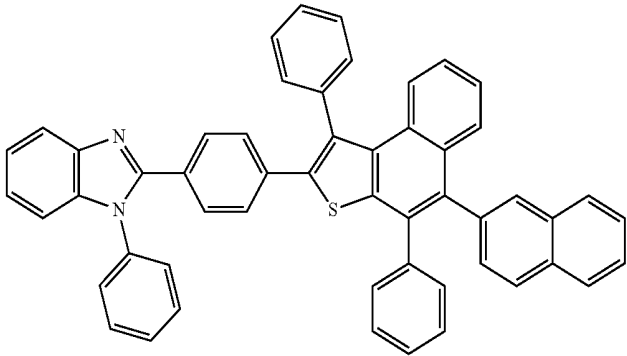
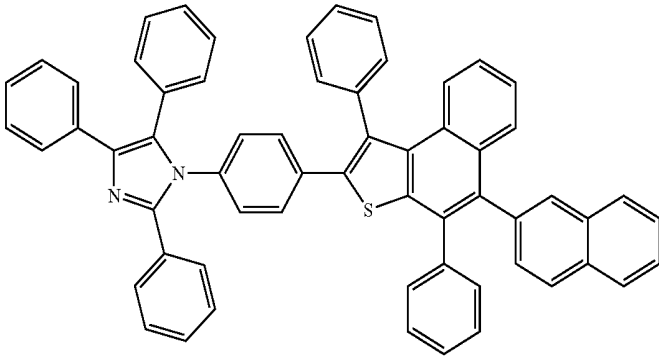
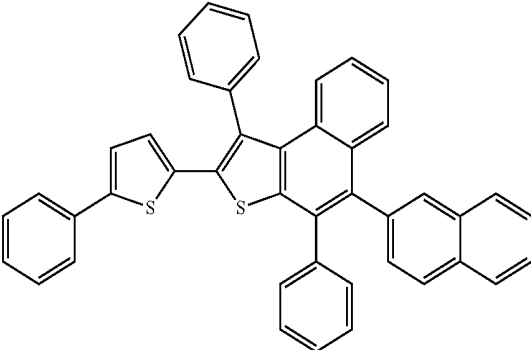
Prep. Ex.	Product	structure	MS [M + H] ⁺
1-1-9	compound 1-1-9		655
1-1-10	compound 1-1-10		731
1-1-11	compound 1-1-11		833
1-1-12	compound 1-1-12		621

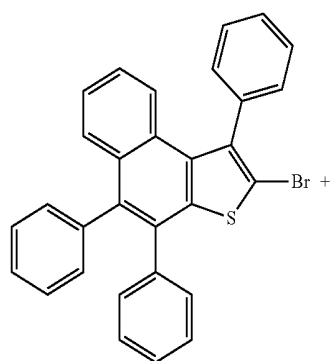
TABLE 1-1-continued

Prep. Ex. 1-1-No	Product 1-1-No	structure	MS [M + H] ⁺
1-1-13	compound 1-1-13		704
1-1-14	compound 1-1-14		770

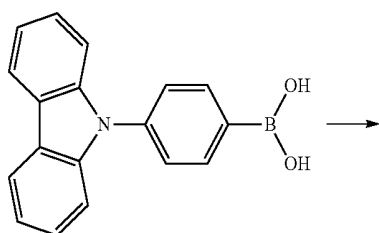
PREPARATION EXAMPLE 1-2-4

Preparation of the Compound 1-2-4

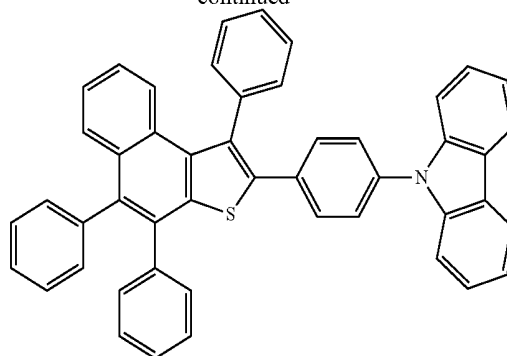
[0191]



[compound 1E-2-1]



-continued



[compound 1-2-4]

[0192] [4-(9H-carbazol-9-yl)phenyl] boronic acid (1.4 g, 4.9 mmol), the compound E-2 (2.0 g, 4.1 mmol) that was prepared in Preparation Example 2, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-2-4 (1.6 g, yield 58%).

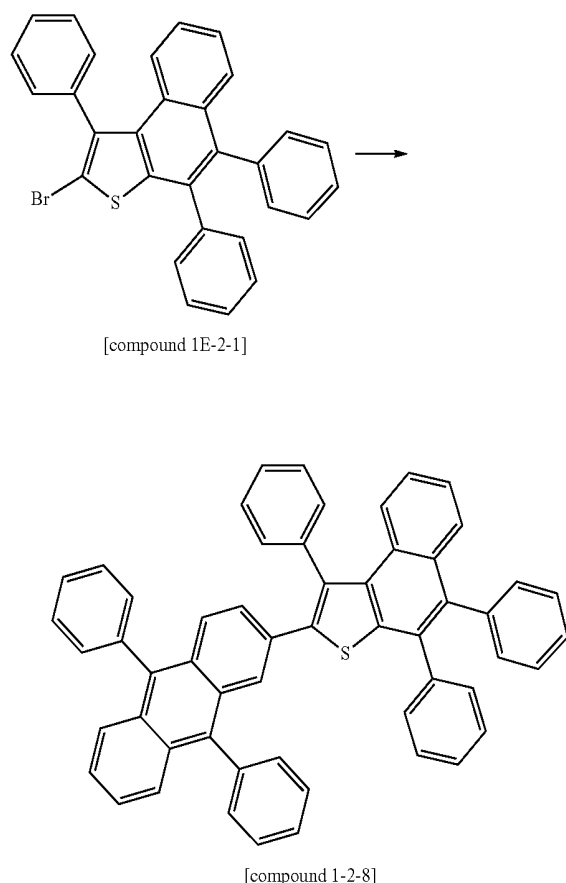
[0193] In Preparation Examples 1-2-1 to 1-2-3, Preparation Examples 1-2-5 to 1-2-7, Preparation Examples 1-2-11, 1-2-

13, 1-2-15 and Preparation Examples 1-2-16 to 1-2-20, they were prepared by using the same method as Preparation Example 1-2-8, except that the reactants having different substituent groups were used as the boronic acid or boron ester reactant.

PREPARATION EXAMPLE 1-2-8

Preparation of the Compound 1-2-8

[0194]

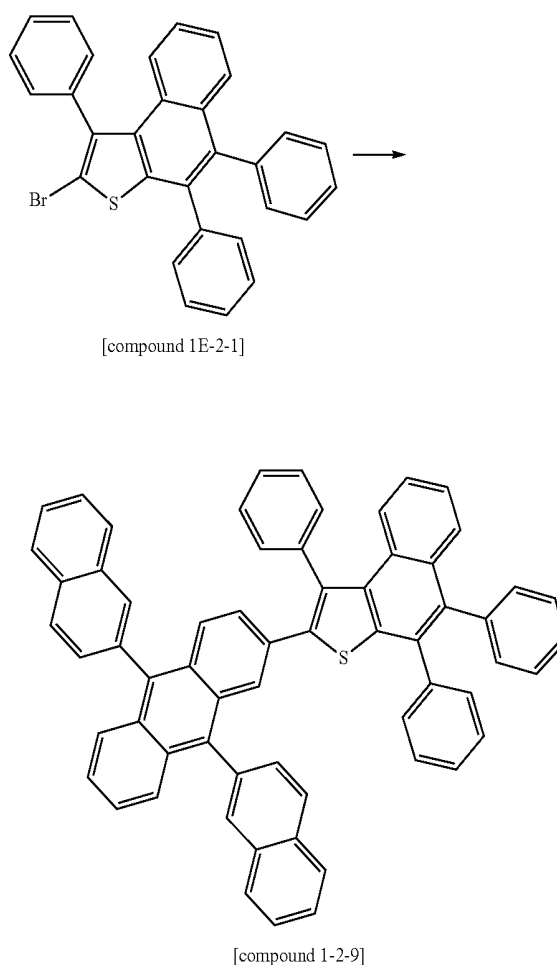


[0195] 2-[9,10-diphenyl-2-anthracenyl]-4,4,5,5-tetramethyl-1,3,2-dioxaborolane (2.2 g, 4.9 mmol) that was the reactant S-10, the compound 1E-1-2 (2.0 g, 4.1 mmol) that was prepared in Synthesis Example 1-9-1, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-2-8 (2.2 g, yield 73%).

PREPARATION EXAMPLE 1-2-9

Preparation of the Compound 1-2-9

[0196]

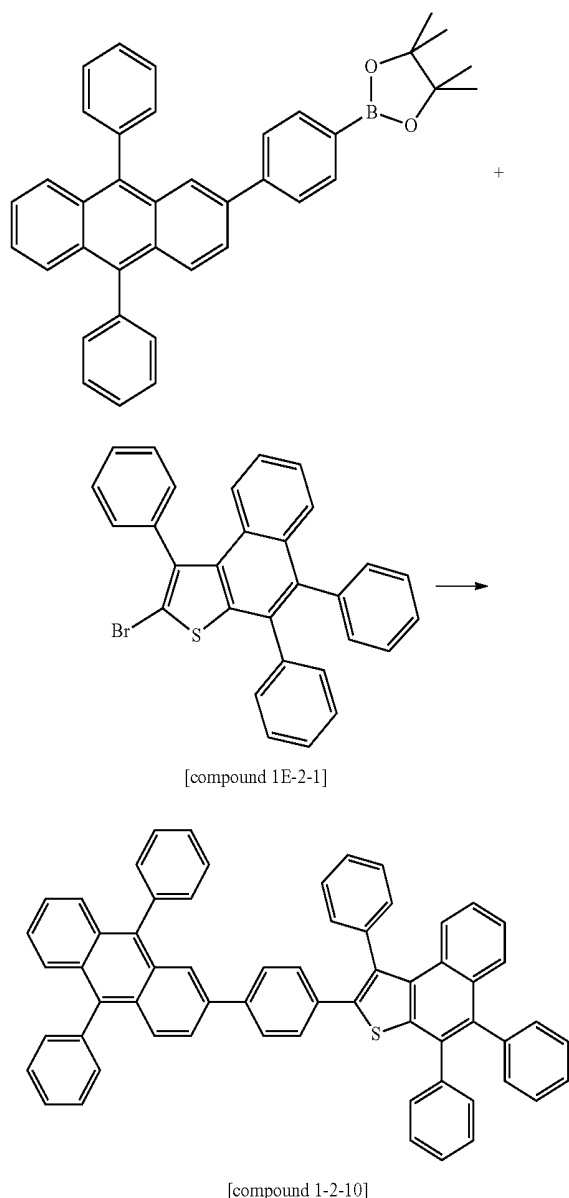


[0197] 2-[9,10-di-2-naphthalenyl-2-anthracenyl]-4,4,5,5-tetramethyl-1,3,2-dioxaborolane (2.7 g, 4.9 mmol) that was the reactant S-10, the compound 1E-2-1 (2.0 g, 4.1 mmol) that was prepared in Synthesis Example 1-1-9, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-2-9 (2.5 g, yield 76%).

PREPARATION EXAMPLE 1-2-10

Preparation of the Compound 1-2-10

[0198]

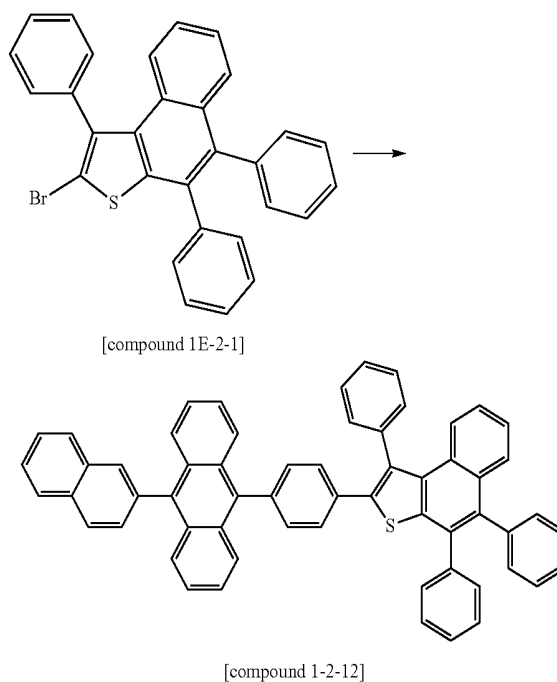


[0199] 2-[9,10-diphenyl-2-anthracenyl]-4,4,5,5-tetraethyl-1,3,2-dioxaborolane (2.6 g, 4.9 mmol) that was the reactant S-22, the compound 1E-2-1 (2.0 g, 4.1 mmol) that was prepared in Synthesis Example 1-9-1, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-2-10 (2.5 g, yield 75%).

PREPARATION EXAMPLE 1-2-12

Preparation of the Compound 1-2-12

[0200]

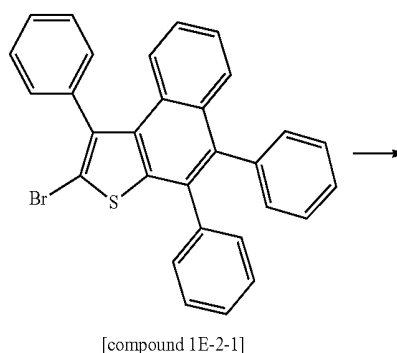


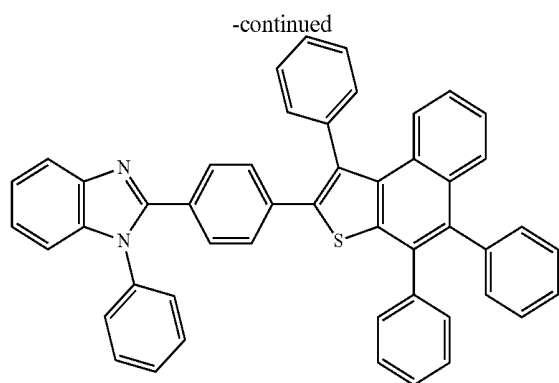
[0201] 4-[9-(2-naphthyl-10-phenylene)-4,4,5,5-tetraethyl-1,3,2-dioxaborolane] (2.2 g, 4.9 mmol) that was the reactant S-6, the compound 1E-2-1 (2.0 g, 4.1 mmol) that was prepared in Synthesis Example 1-9-1, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-2-12 (2.5 g, yield 77%).

PREPARATION EXAMPLE 1-2-14

Preparation of the Compound 1-2-14

[0202]





[compound 1-2-14]

[0203] The reactant S-15 (1.9 g, 4.9 mmol), the compound 1E-2-1 (2.0 g, 4.1 mmol) that was prepared in Synthesis Example 1-9-1, and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-2-14 (1.9 g, yield 67%).

TABLE 1-2

Prep. Ex. 1-2-No	Product 1-2-No	structure	MS [M + H] ⁺
1-2-1	compound 1-2-1		666
1-2-2	compound 1-2-2		665
1-2-3	compound 1-2-3		641

TABLE 1-2-continued

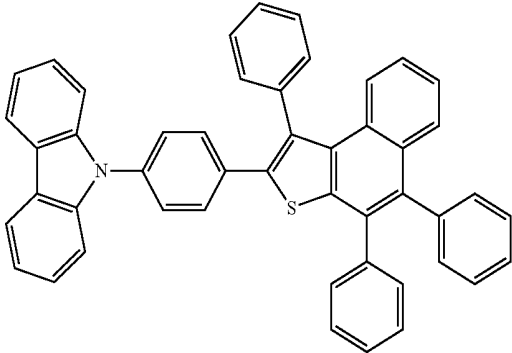
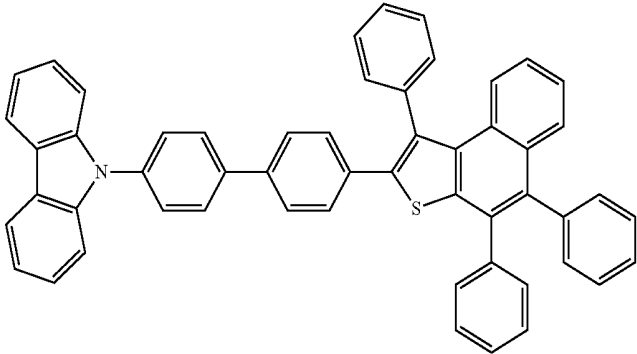
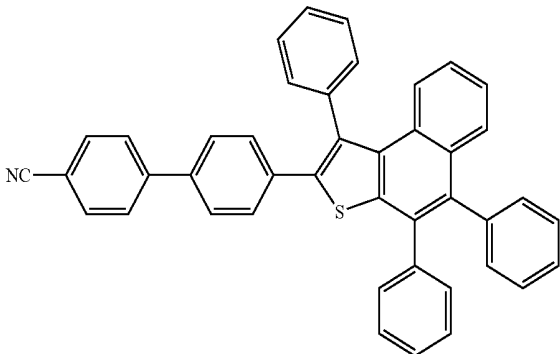
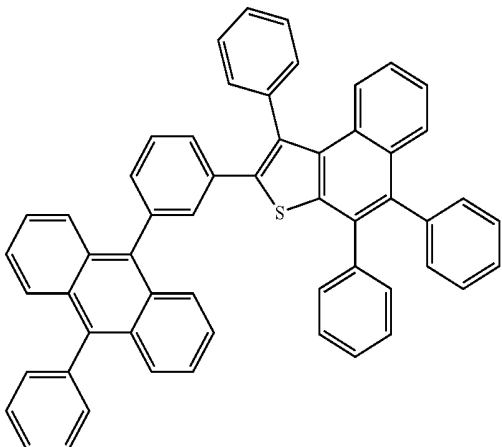
Prep. Ex. 1-2-No	Product 1-2-No	structure	MS [M + H] ⁺
1-2-4	compound 1-2-4		654
1-2-5	compound 1-2-5		730
1-2-6	compound 1-2-6		590
1-2-7	compound 1-2-7		741

TABLE 1-2-continued

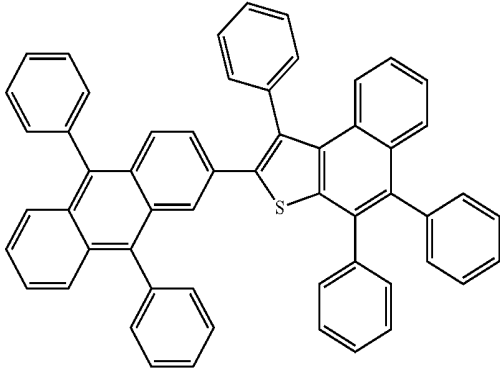
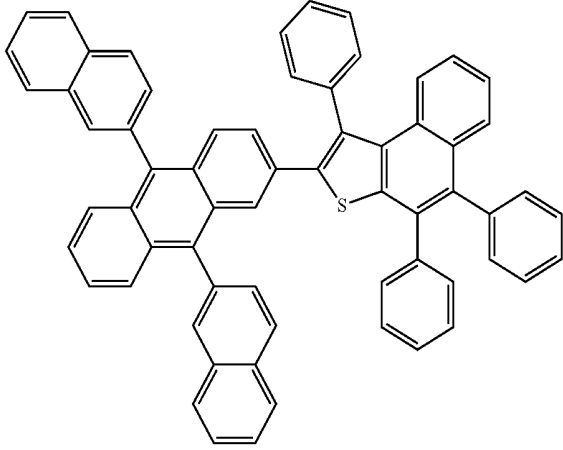
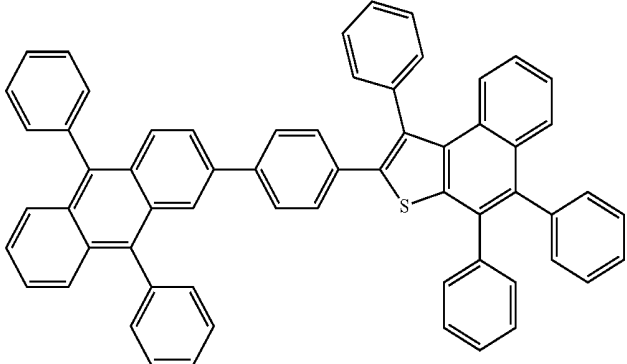
Prep. Ex.	Product	MS
1-2-No	1-2-No structure	[M + H] ⁺
1-2-8	compound 1-2-8 	741
1-2-9	compound 1-2-9 	841
1-2-10	compound 1-2-10 	817

TABLE 1-2-continued

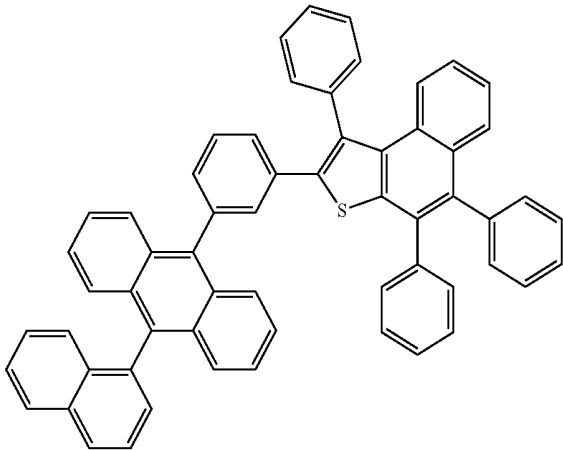
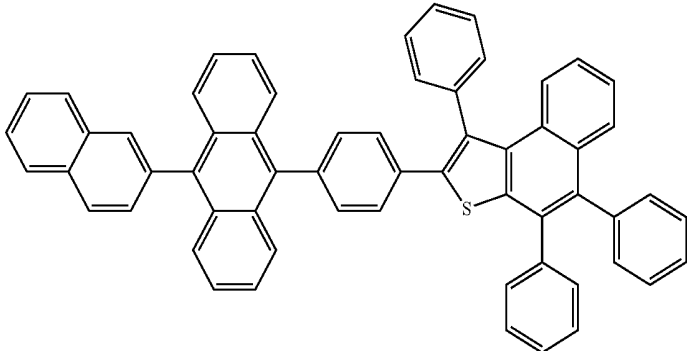
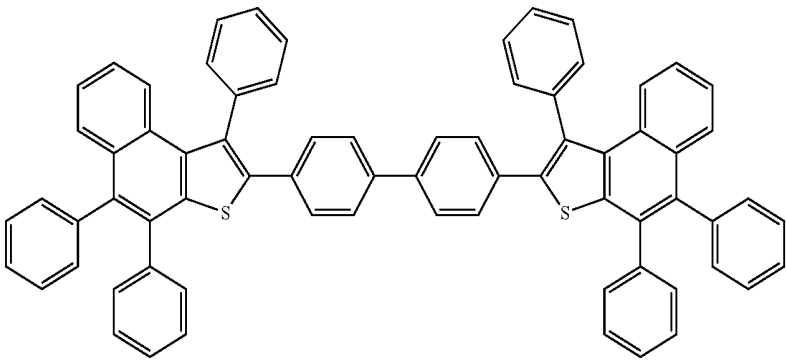
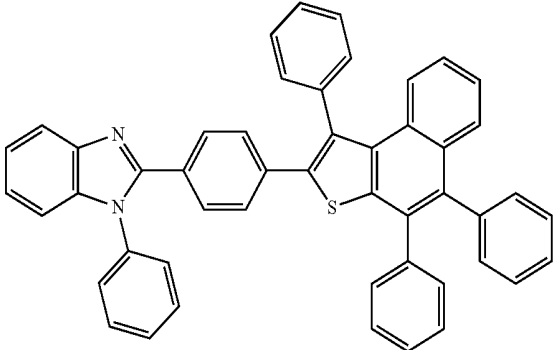
Prep. Ex. 1-2-No	Product 1-2-No	structure	MS [M + H] ⁺
1-2-11	compound 1-2-11		791
1-2-12	compound 1-2-12		791
1-2-13	compound 1-2-13		975
1-2-14	compound 1-2-14		681

TABLE 1-2-continued

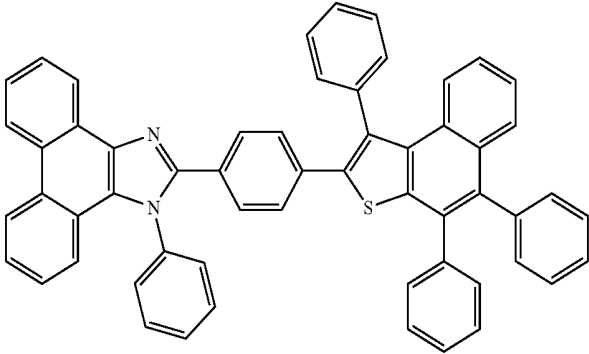
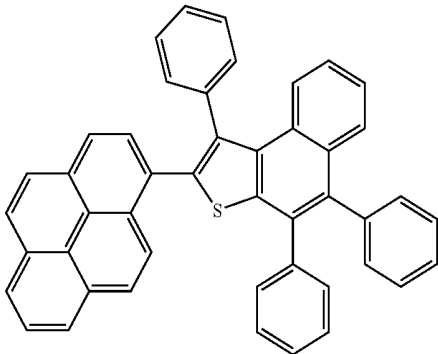
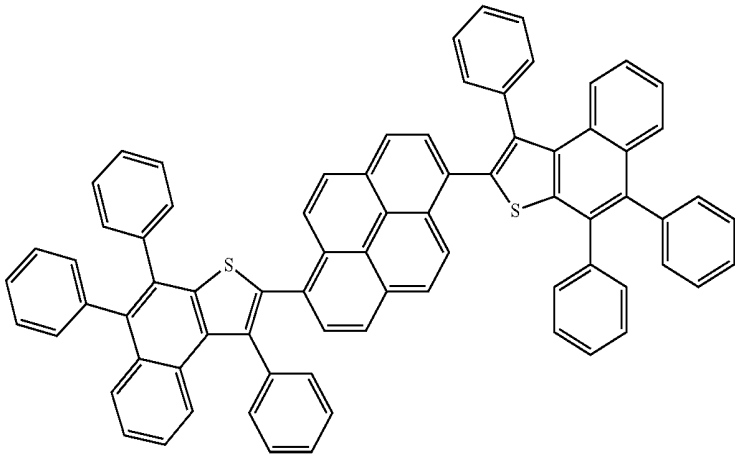
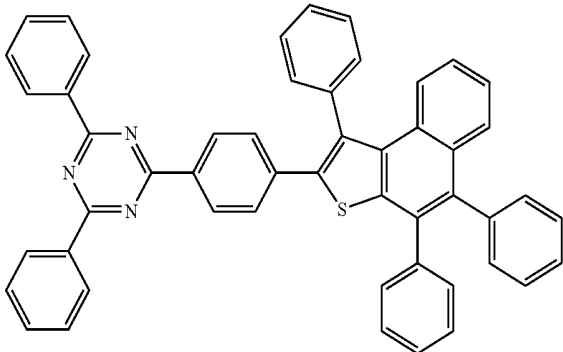
Prep. Ex. 1-2-No	Product 1-2-No	structure	MS [M + H] ⁺
1-2-15	compound 1-2-15		781
1-2-16	compound 1-2-16		613
1-2-17	compound 1-2-17		1023
1-2-16	compound 1-2-16		719

TABLE 1-2-continued

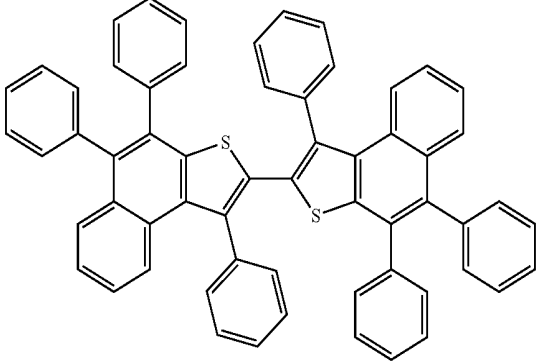
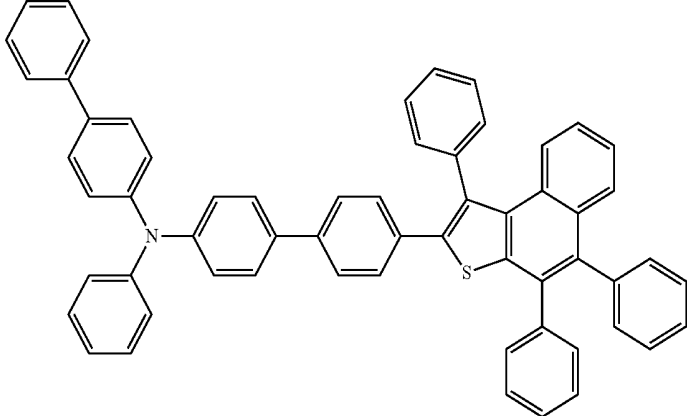
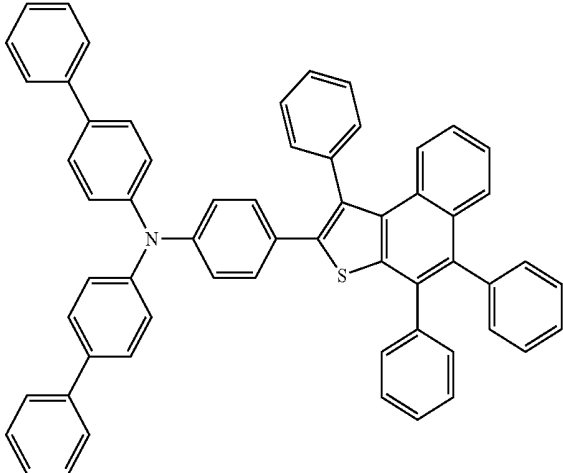
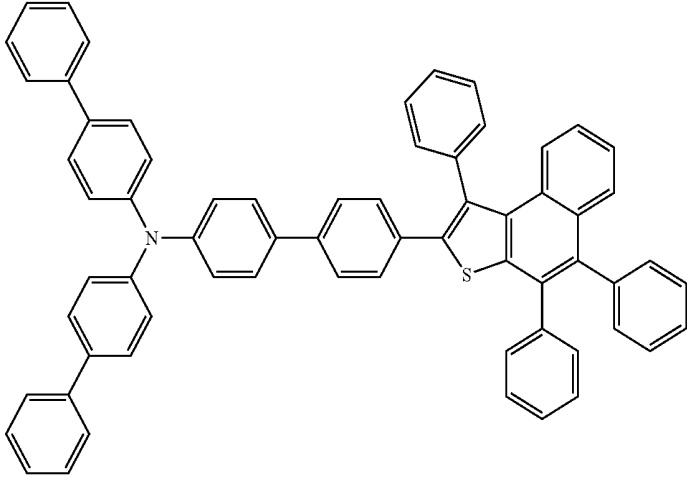
Prep. Ex.	Product		MS
1-2-No	1-2-No	structure	[M + H] ⁺
1-2-17	compound 1-2-17		823
1-2-18	compound 1-2-18		808
1-2-19	compound 1-2-19		808

TABLE 1-2-continued

Prep. Ex. 1-2-No	Product 1-2-No	structure	MS [M + H] ⁺
1-2-20	compound 1-2-20		884

PREPARATION EXAMPLE 1-3-1

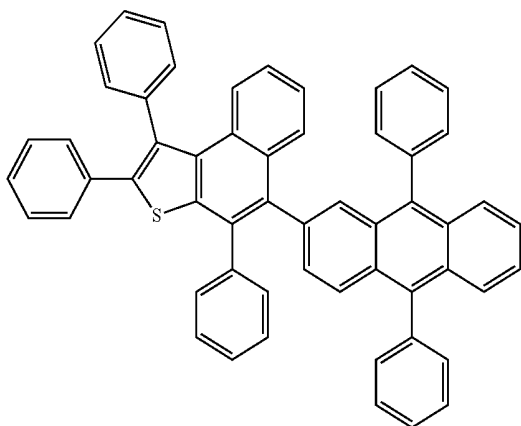
Preparation of the Compound 1-3-1

[0204]

(0.1 g, 0.2 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-3-1 (3.2 g, yield 46%).

[0206] MS [M+H]⁺=741

[compound 1-3-1]



PREPARATION EXAMPLE 1-3-2

Preparation of the Compound 1-3-2

[0207] In Preparation Example 1-3-1, it was prepared by using the same method to prepare the compound 1-3-2, except that the compound of 1E-3-6 synthesized in Synthesis Example 1-10-6 was used.

PREPARATION EXAMPLE 1-3-3

Preparation of the Compound 1-3-3

[0208] In Preparation Example 1-3-1, it was prepared by using the same method to prepare the compound 1-3-3, except that the compound of 1E-3-7 synthesized in Synthesis Example 1-10-7 was used.

PREPARATION EXAMPLE 1-3-4

Preparation of the Compound 1-3-4

[0205] Phenyl boronic acid (2.5 g, 20.5 mmol), the compound 1E-3-4 (5.6 g, 9.3 mmol) that was prepared in Synthesis Example 1-10-4, and sodium carbonate (2.8 g, 20.5 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium

[0209] In Preparation Example 1-3-1, it was prepared by using the same method to prepare the compound 1-3-4, except that the compound of 1E-3-8 synthesized in Synthesis Example 1-10-8 was used.

TABLE 1-3

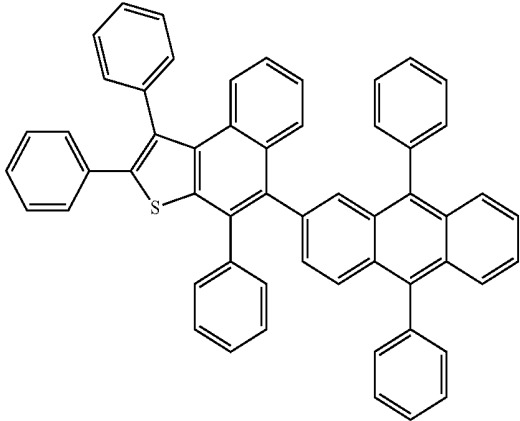
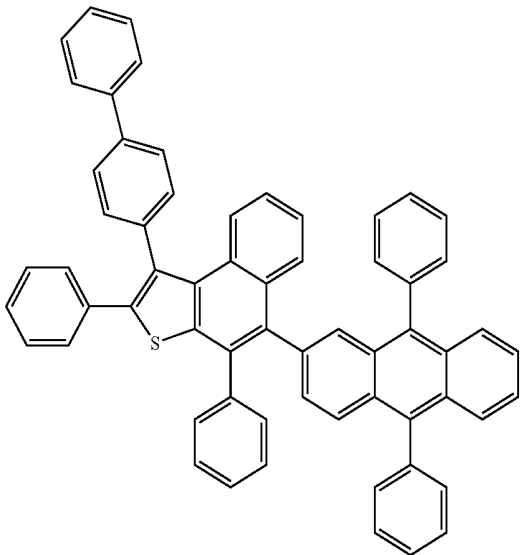
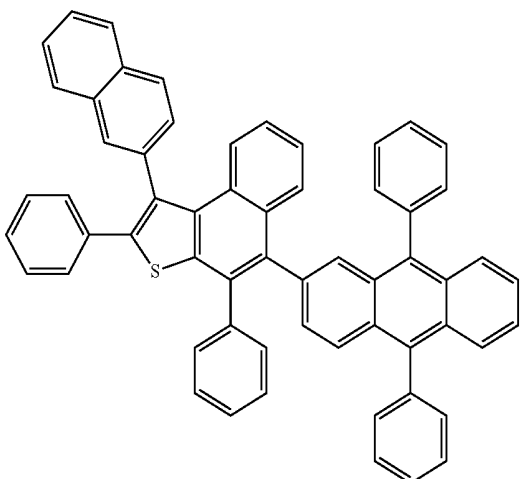
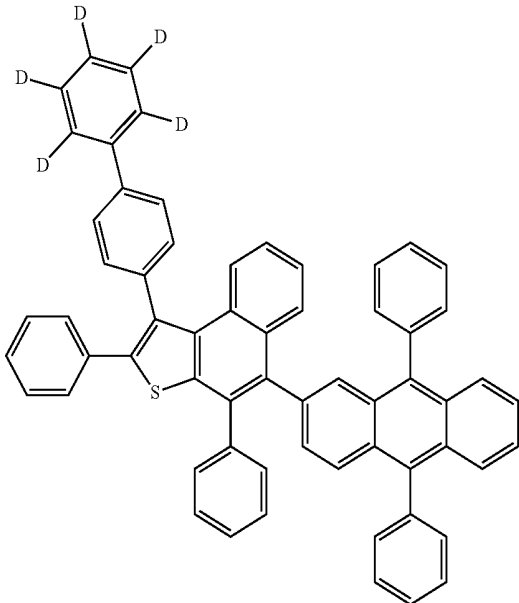
Prep. Ex.	Product	MS
1-3-No	1-3-No structure	[M + H] ⁺
1-3-1	compound 1-3-1	741
		
1-3-2	compound 1-3-2	817
		
1-3-3	compound 1-3-3	665
		

TABLE 1-3-continued

Prep. Ex. 1-3-No	Product 1-3-No	structure	MS [M + H] ⁺
1-3-4	compound 1-3-4		822

PREPARATION EXAMPLE 1-4-1

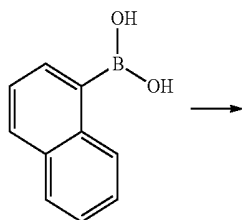
Preparation of the Compound 1-4-1

[0210] In Preparation Example 1-4-2, the compound 1-4-1 was prepared by using the same method, except that phenyl boronic acid was used instead of naphthyl boronic acid.

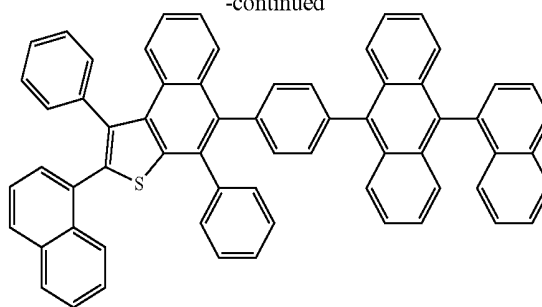
PREPARATION EXAMPLE 1-4-2

Preparation of the Compound 1-4-2

[0211]



-continued



[compound 1-4-2]

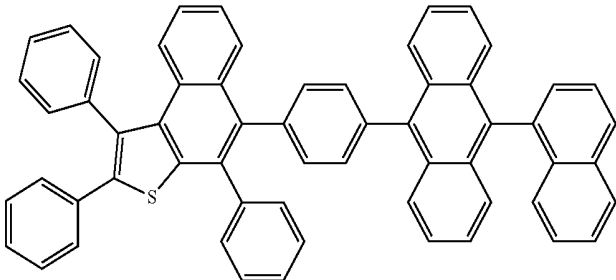
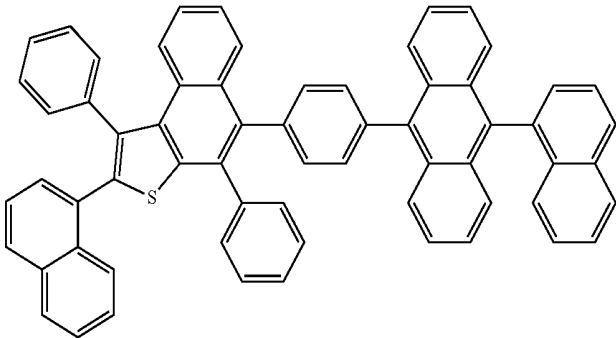
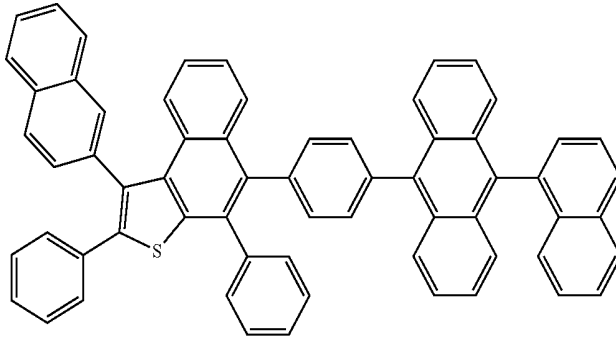
[0212] Naphthyl boronic acid (3.5 g, 20.5 mmol), the compound 1E-3-2 (5.6 g, 9.3 mmol) that was prepared in Synthesis Example 1-10-2, and sodium carbonate (2.8 g, 20.5 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.2 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 1-4-2 (3.2 g, yield 46%).

PREPARATION EXAMPLE 1-4-3

Preparation of the Compound 1-4-3

[0213] In Preparation Example 1-4-1, it was prepared by using the same method to prepare the compound 1-4-3, except that the compound of 1E-3-2 synthesized in Synthesis Example 1-10-2 was used.

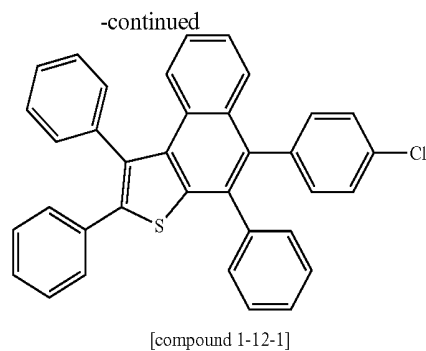
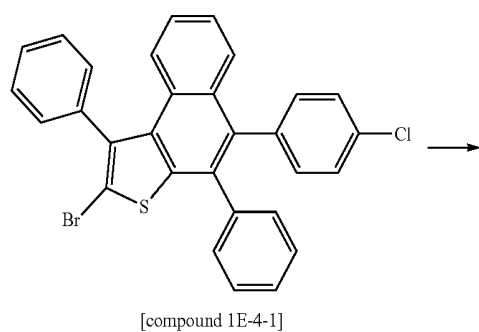
TABLE 1-4

Prep. Ex. 1-4-No	Product 1-4-No	structure	MS [M + H] ⁺
1-4-1	compound 1-4-1		791
1-4-2	compound 1-4-2		841
1-4-3	compound 1-4-3		841

PREPARATION EXAMPLE 1-5-1

Preparation of the Compound 1-5-1

[0214] Preparation of the Compound 1-12-1



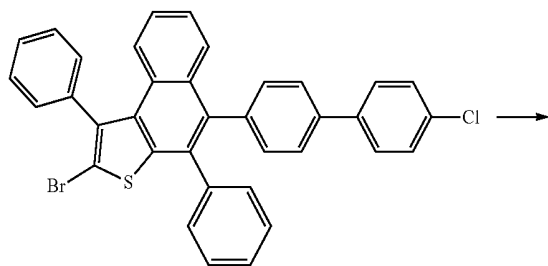
[0215] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-12-1, except that phenyl boronic acid was used instead of naphthyl boronic acid and the compound 1E-4-1 was used instead of the compound 1E-3-2.

[0216] Preparation of the Compound 1-5-1

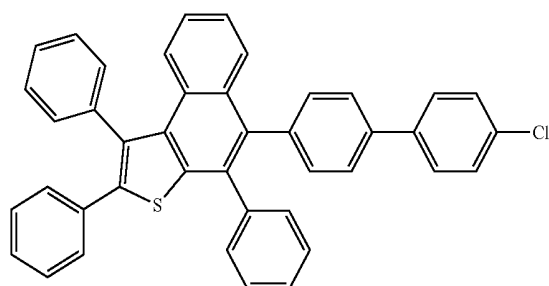
[0217] The compound 1-12-1 (20.2 g, 38.6 mmol), and the reactant S-28 (12.4 g, 38.6 mmol) were dissolved in 200 ml of xylene, 5.6 g of sodium-tertiary-butoxide (57.9 mmol), and $\text{Pd}[\text{P}(\text{t-Bu})_3]_2$ (0.19 g, 0.386 mmol) were added thereto, and refluxed for 5 hours under the nitrogen atmosphere. Distilled water was put into the reaction solution, the termination of the reaction was carried out, and the organic material layer was extracted. After the column separation was carried out with normal-hexane/tetrahydrofuran=10/1 solvent, it was agitated in petroleum ether, and dried under vacuum to manufacture the compound 1-5-1 (22.5 g, yield 72%).

PREPARATION EXAMPLE 1-5-2

Preparation of the Compound 1-5-2

[0218] Preparation of the Compound 1-12-3

[compound 1E-4-3]



[compound 1-12-3]

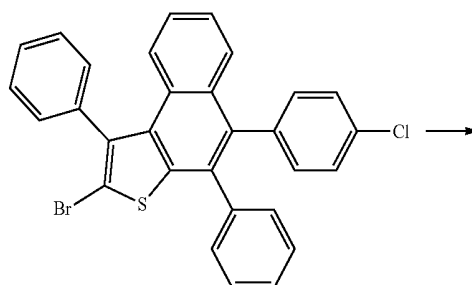
[0219] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-12-3, except that phenyl boronic acid was used instead of naphthyl boronic acid and the compound 1E-4-3 was used instead of the compound 1E-3-2.

[0220] Preparation of the Compound 1-5-2

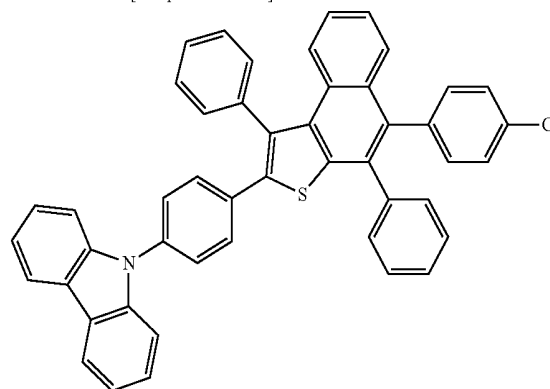
[0221] In Preparation Example 1-5-1, the compound 1-5-2 was prepared by using the same method, except that the compound 1-12-3 was used instead of the compound 1-12-1.

PREPARATION EXAMPLE 1-5-3

Preparation of the Compound 1-5-3

[0222] Preparation of the Compound 1-12-6

[compound 1E-4-1]



[compound 1-12-6]

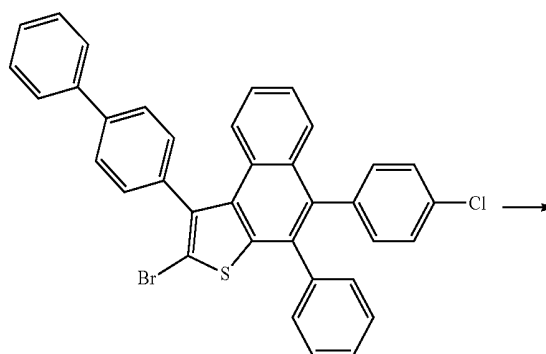
[0223] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-12-6, except that the reactant S-18 was used instead of naphthyl boronic acid and the compound 1E-4-1 was used instead of the compound 1E-3-2.

[0224] Preparation of the Compound 1-5-3

[0225] In Preparation Example 1-5-1, the compound 1-5-3 was prepared by using the same method, except that the compound 1-12-6 was used instead of the compound 1-12-1 and the reactant S-30 was used instead of the reactant S-28.

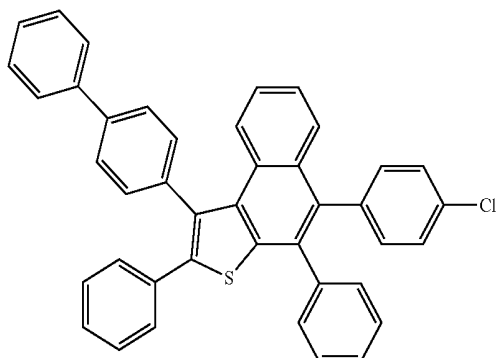
PREPARATION EXAMPLE 1-5-4

Preparation of the Compound 1-5-4

[0226] Preparation of the Compound 1-12-2

[compound 1E-4-2]

-continued



[compound 1-12-2]

[0227] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-12-2, except that phenyl boronic acid was used instead of naphthyl boronic acid and the compound 1E-4-2 was used instead of the compound 1E-3-2.

[0228] Preparation of the Compound 1-5-4

[0229] In Preparation Example 1-5-1, the compound 1-5-4 was prepared by using the same method, except that the compound 1-12-2 was used instead of the compound 1-12-1 and the reactant S-29 was used instead of the reactant S-28.

PREPARATION EXAMPLE 1-5-5

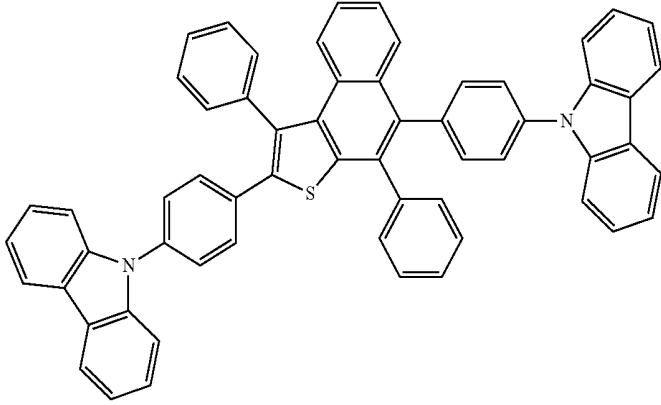
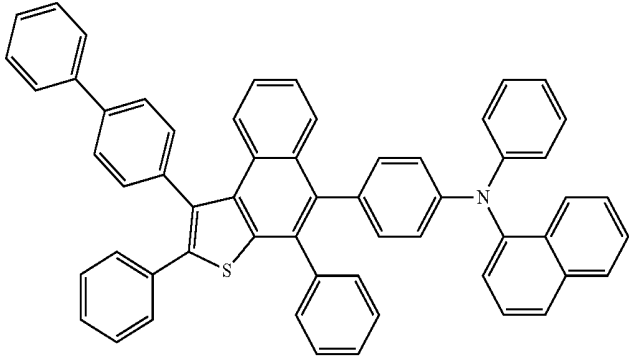
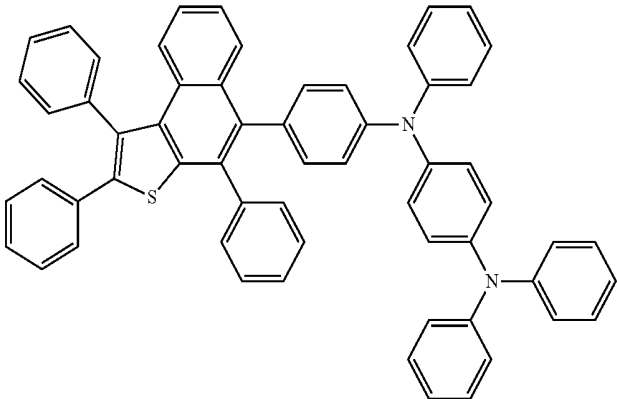
Preparation of the Compound 1-5-5

[0230] In Preparation Example 1-5-1, the compound 1-5-5 was prepared by using the same method, except that the reactant S-27 was used instead of the reactant S-28.

TABLE 1-5

Prep. Ex.	Product	MS
1-5-No	1-5-No structure	[M + H] ⁺
1-5-1	compound 1-5-1	808
1-5-2	compound 1-5-2	885

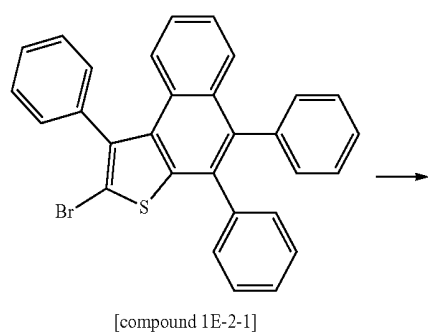
TABLE 1-5-continued

Prep. Ex.	Product	MS
1-5-No	1-5-No structure	[M + H] ⁺
1-5-3	compound 1-5-3	819
		
1-5-4	compound 1-5-4	782
		
1-5-5	compound 1-5-5	823
		

PREPARATION EXAMPLE 1-6-1

Preparation of the Compound 1-6-1

[0231] Preparation of the Compound 1-12-7



[0232] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-12-7, except that the reactant S-14 was used instead of naphthyl boronic acid and the compound 1E-2-1 was used instead of the compound 1E-3-2.

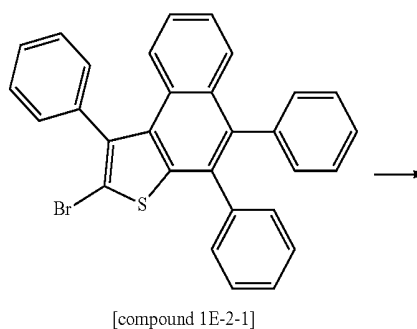
[0233] Preparation of the Compound 1-6-1

[0234] In Preparation Example 1-5-1, the compound 1-6-1 was prepared by using the same method, except that the compound 1-12-7 was used instead of the compound 1-12-1 and the reactant S-30 was used instead of the reactant S-28.

PREPARATION EXAMPLE 1-6-2

Preparation of the Compound 1-6-2

[0235] Preparation of the Compound 1-12-8



[0236] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-12-8, except that the reactant S-13 was used instead of naphthyl boronic acid and the compound 1E-2-1 was used instead of the compound 1E-3-2.

[0237] Preparation of the Compound 1-6-2

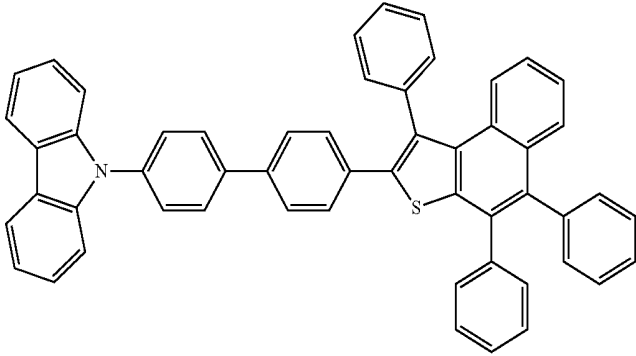
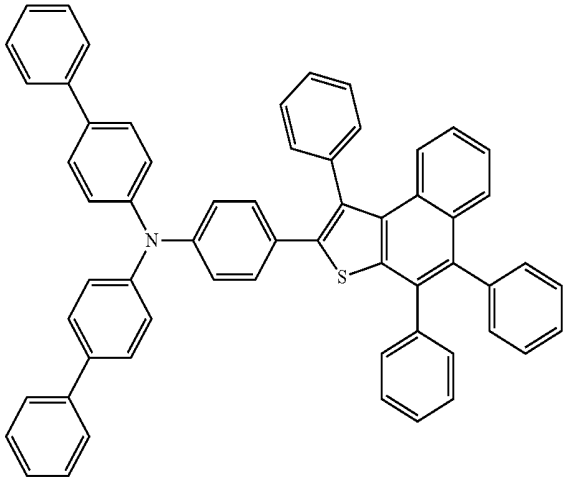
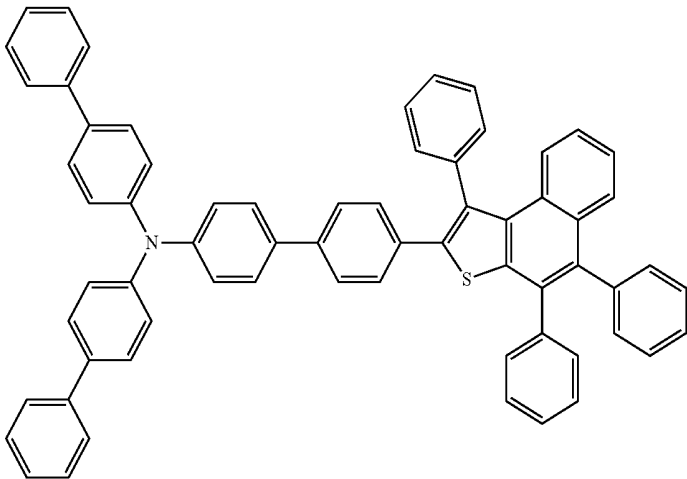
[0238] In Preparation Example 1-5-1, the compound 1-6-2 was prepared by using the same method, except that the compound 1-12-8 was used instead of the compound 1-12-1 and the reactant S-30 was used instead of the reactant S-28.

PREPARATION EXAMPLE 1-6-3

Preparation of the Compound 1-6-3

[0239] In Preparation Example 1-5-1, the compound 1-6-3 was prepared by using the same method, except that the compound 1-12-7 was used instead of the compound 1-12-1.

TABLE 1-6

Prep. Ex. 1-6-No	Product 1-6-No	structure	MS [M + H] ⁺
1-6-1	compound 1-6-1		730
1-6-2	compound 1-6-2		808
1-6-3	compound 1-6-3		884

PREPARATION EXAMPLE 1-7-1

Preparation of the Compound 1-7-1

[0240] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-7-1, except that phenyl boronic acid compound was used instead of naphthyl boronic acid and the compound 1E-3-3 was used instead of the compound 1E-3-2.

PREPARATION EXAMPLE 1-7-2

Preparation of the Compound 1-7-2

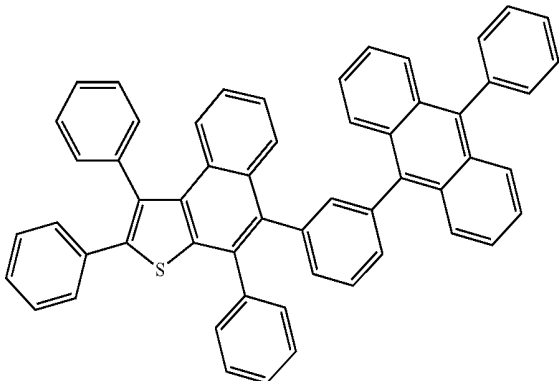
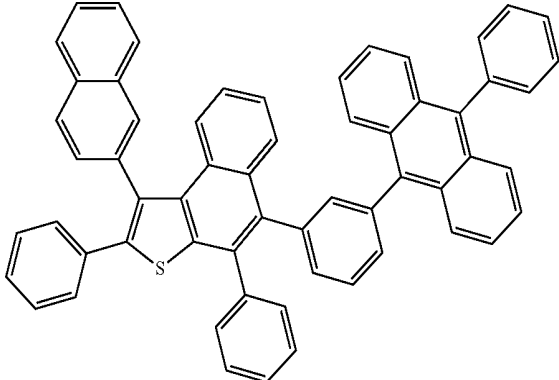
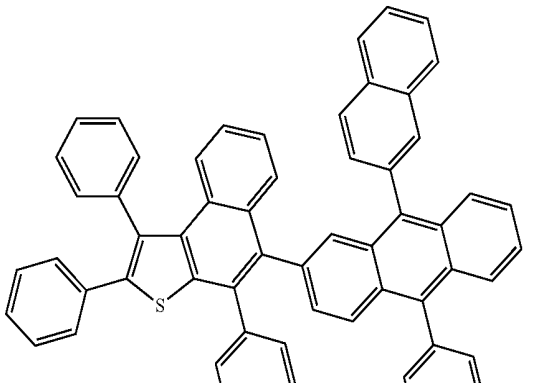
[0241] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 1-7-2, except that phenyl boronic acid compound was used instead of naphthyl boronic acid and the compound 1E-3-9 was used instead of the compound 1E-3-2.

PREPARATION EXAMPLE 2-1-1

Preparation of the Compound 2-1-1

[0243] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 2-1-1, except that the reactant S-10 was used instead of naphthyl boronic acid and the compound 2E-1-1 was used instead of the compound 1E-3-2.

TABLE 1-7

Prep. Ex. 1-7-No	Product 1-7-No	structure	MS [M + H] ⁺
1-7-1	compound 1-7-1		741
1-7-2	compound 1-7-2		885
1-7-3	compound 1-7-3		841

PREPARATION EXAMPLE 2-1-2

Preparation of the Compound 2-1-2

[0244] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 2-1-2, except that the reactant S-31 was used instead of naphthyl boronic acid and the compound 2E-1-2 was used instead of the compound 1E-3-2.

PREPARATION EXAMPLE 2-1-3

Preparation of the Compound 2-1-3

[0245] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 2-1-3, except that phenyl boronic acid compound was used instead of naphthyl boronic acid and the compound 2E-1-4 was used instead of the compound 1E-3-2.

PREPARATION EXAMPLE 2-1-4

Preparation of the Compound 2-1-4

[0246] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 2-1-4,

except that phenyl boronic acid was used instead of naphthyl boronic acid and the compound 2E-1-6 was used instead of the compound 1E-3-2.

PREPARATION EXAMPLE 2-1-5

Preparation of the Compound 2-1-5

[0247] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 2-1-5, except that phenyl boronic acid was used instead of naphthyl boronic acid and the compound 2E-1-5 was used instead of the compound 1E-3-2.

PREPARATION EXAMPLE 2-1-6

Preparation of the Compound 2-1-6

[0248] In Preparation Example 1-4-2, it was prepared by using the same method to prepare the compound 2-1-6, except that the reactant S-33 was used instead of naphthyl boronic acid in an equivalent of 2.4 and the compound 2E-1-1 was used instead of the compound 1E-3-2.

TABLE 2-1

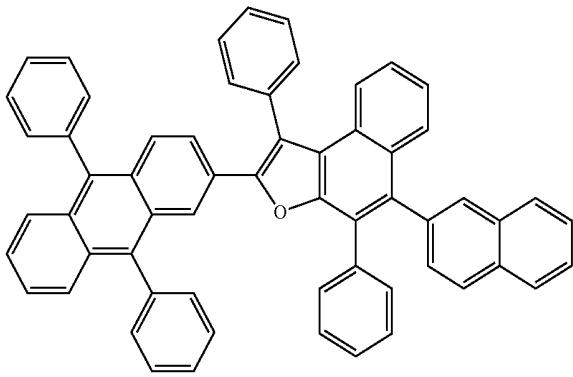
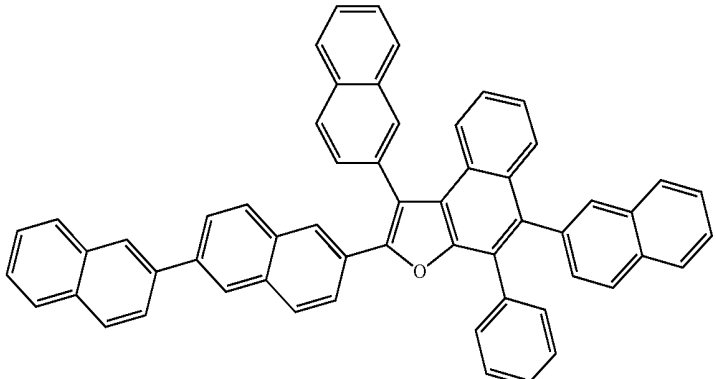
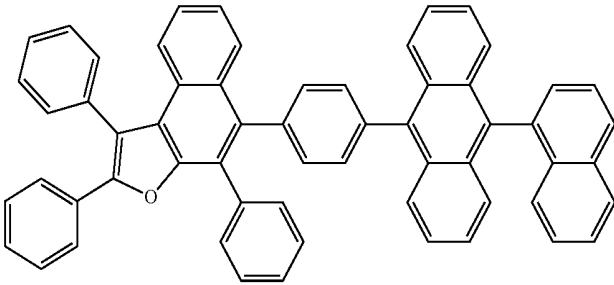
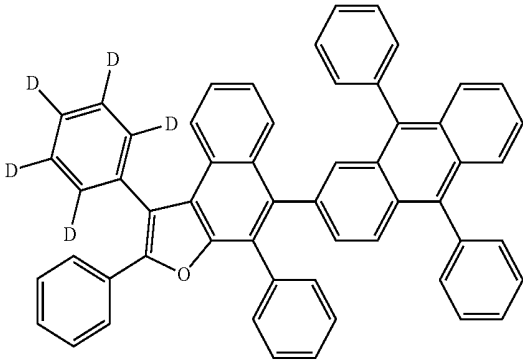
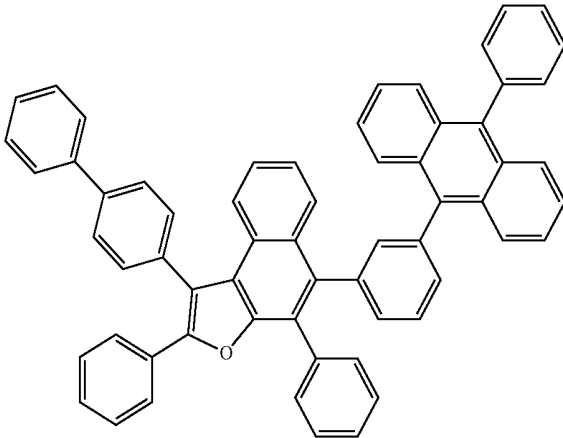
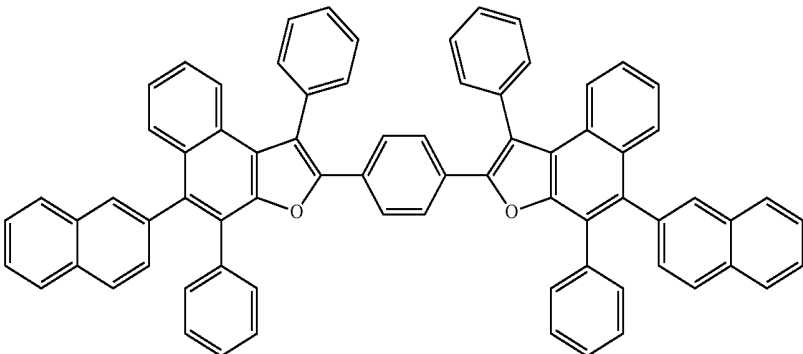
Prep. Ex.	Product		MS
2-1-No	2-1-No	structure	[M + H] ⁺
2-1-1	compound 2-1-1		775
2-1-2	compound 2-1-2		749

TABLE 2-1-continued

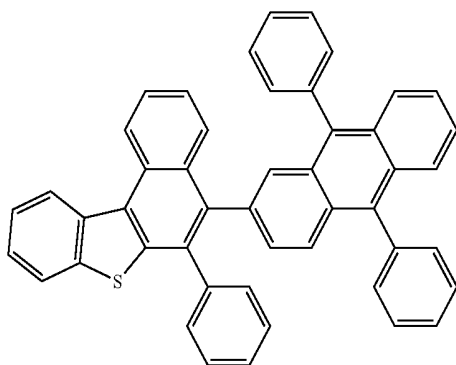
Prep. Ex.	Product	MS
2-1-No	2-1-No structure	[M + H] ⁺
2-1-3	compound 2-1-3	775
		
2-1-4	compound 2-1-4	730
		
2-1-5	compound 2-1-5	801
		
2-1-6	2-1-6	967
		

PREPARATION EXAMPLE 3-1-2

Preparation of the Compound 3-1-2

[0249]

[compound 3-1-2]



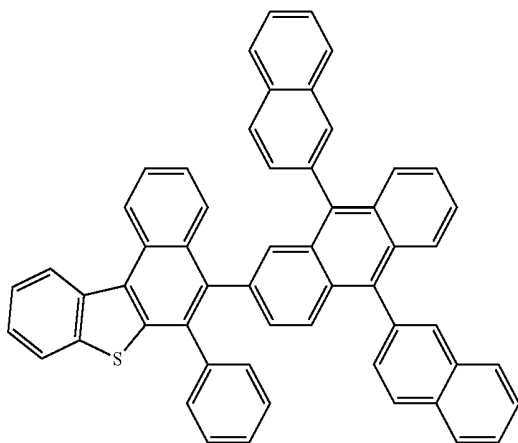
[0250] 2-[9,10-diphenyl-2-anthracenyl]-4,4,5,5-tetramethyl-1,3,2-dioxaborolane (2.2 g, 4.9 mmol) that was the reactant S-10, the prepared compound A-3 (1.8 g, 4.1 mmol), and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 3-1-2 (2.1 g, yield 68%).

PREPARATION EXAMPLE 3-1-3

Preparation of the Compound 3-1-3

[0251]

[compound 3-1-3]



[0252] 2-[9,10-di-2-naphthalenyl-2-anthracenyl]-4,4,5,5-tetramethyl-1,3,2-dioxaborolane (2.7 g, 4.9 mmol) that was the reactant S-9, the prepared compound A-3 (1.8 g, 4.1

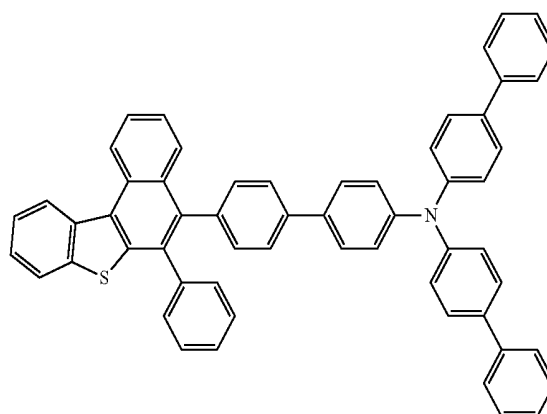
mmol), and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 3-1-3 (2.5 g, yield 82%).

PREPARATION EXAMPLE 3-1-13

Preparation of the Compound 3-1-13

[0253]

[compound 3-1-13]



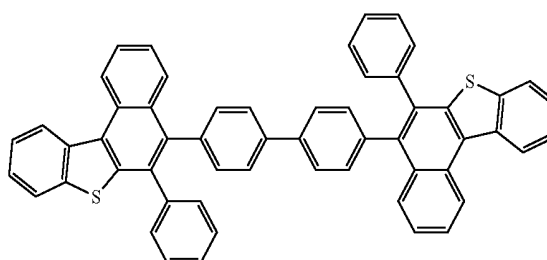
[0254] 4'-(dibiphenylamino)(1,1'-biphenyl)-4-yl boronic acid (2.5 g, 4.9 mmol) that was the reactant S-23, the prepared compound A-3 (1.8 g, 4.1 mmol), and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 3-1-13 (1.8 g, yield 56%).

PREPARATION EXAMPLE 3-1-15

Preparation of the Compound 3-1-15

[0255]

[compound 3-1-15]

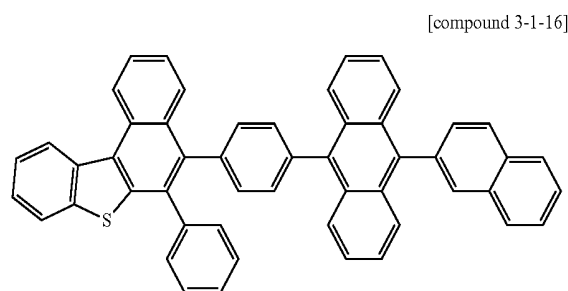


[0256] The reactant S-23 (1.9 g, 4.9 mmol), the prepared compound A-3 (1.8 g, 4.1 mmol), and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 3-1-15 (1.5 g, yield 47%).

PREPARATION EXAMPLE 3-1-16

Preparation of the Compound 3-1-16

[0257]



[0258] 4-[9-(2-naphthyl-10-phenylene)-4,4,5,5-tetraethyl-1,3,2-dioxaborolane] (2.2 g, 4.9 mmol) that was the reactant S-33, the prepared compound A-3 (1.8 g, 4.1 mmol), and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 3-1-16 (1.47 g, yield 52%).

PREPARATION EXAMPLE 3-1-1

Preparation of the Compound 3-1-1

[0259] In Preparation Example 3-1-16, the compound 3-1-1 was prepared by using the same method, except that the reactant S-10 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-4

Preparation of the Compound 3-1-4

[0260] In Preparation Example 3-1-16, the compound 3-1-4 was prepared by using the same method, except that the reactant S-5 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-5

Preparation of the Compound 3-1-5

[0261] In Preparation Example 3-1-16, the compound 3-1-5 was prepared by using the same method, except that the reactant S-8 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-6

Preparation of the Compound 3-1-6

[0262] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-6, except that the reactant S-7 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-7

Preparation of the Compound 3-1-7

[0263] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-7, except that the reactant S-31 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-8

Preparation of the Compound 3-1-8

[0264] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-8, except that the reactant S-38 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-9

Preparation of the Compound 3-1-9

[0265] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-9, except that the reactant S-39 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-10

Preparation of the Compound 3-1-10

[0266] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-10, except that the reactant S-36 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-11

Preparation of the Compound 3-1-11

[0267] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-11, except that the reactant S-35 was used instead of the reactant S-33.

PREPARATION EXAMPLE 3-1-12

Preparation of the Compound 3-1-12

[0268] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound 3-1-12, except that the reactant S-34 was used instead of the reactant S-33.

TABLE 3-1

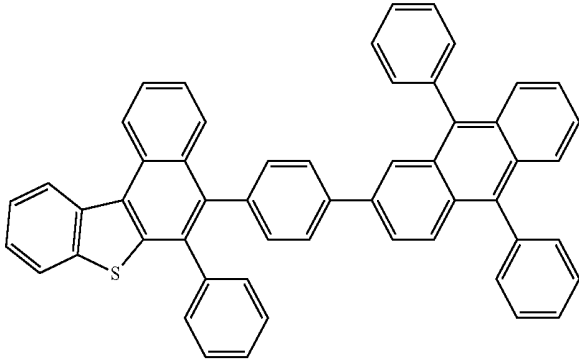
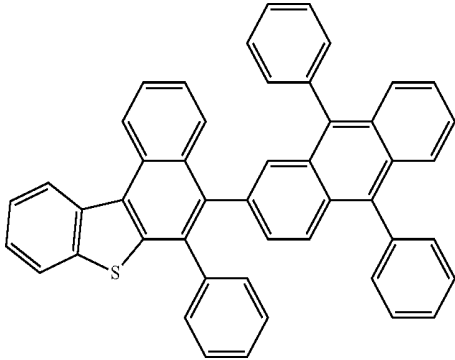
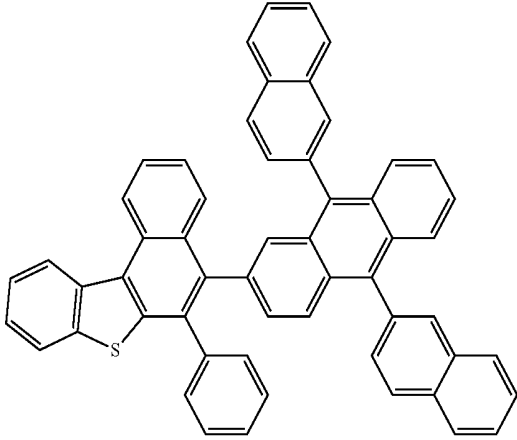
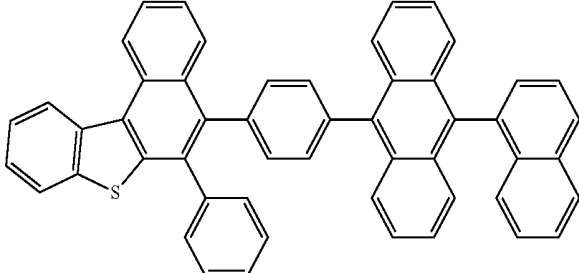
Prep. Ex.	Product		MS
3-1-No	3-1-No	structure	[M + H] ⁺
3-1-1	compound 3-1-1		715
3-1-2	compound 3-1-2		639
3-1-3	compound 3-1-3		739
3-1-4	compound 3-1-4		689

TABLE 3-1-continued

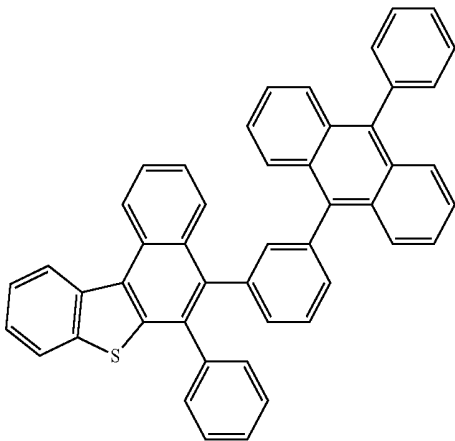
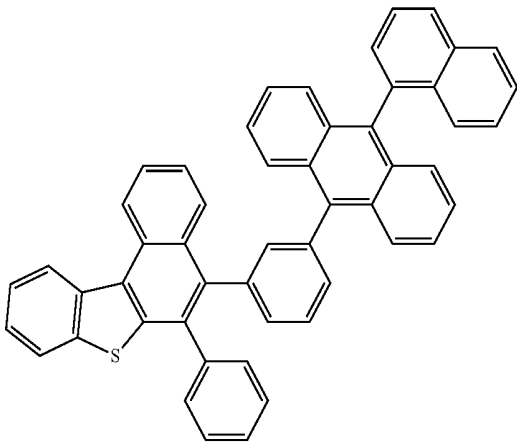
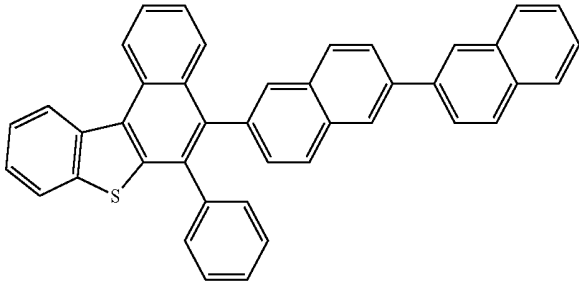
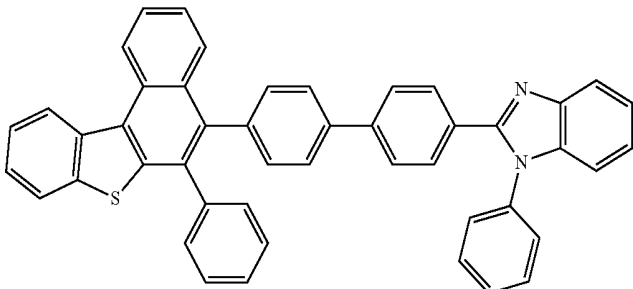
Prep. Ex. 3-1-No	Product 3-1-No	structure	MS [M + H] ⁺
3-1-5	compound 3-1-5		639
3-1-6	compound 3-1-6		689
3-1-7	compound 3-1-7		563
3-1-8	compound 3-1-8		655

TABLE 3-1-continued

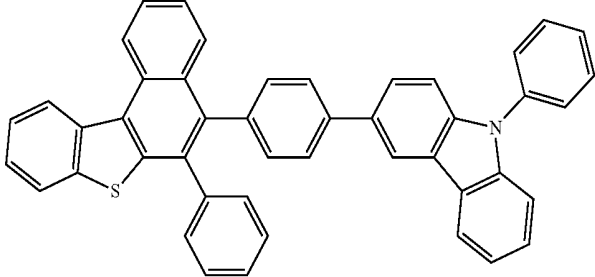
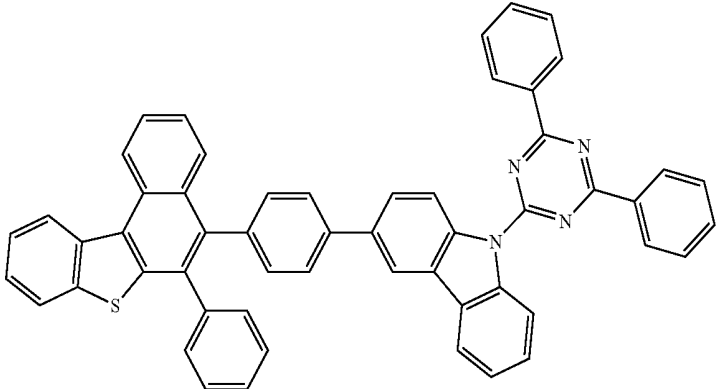
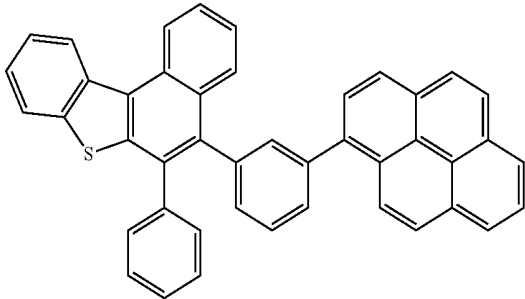
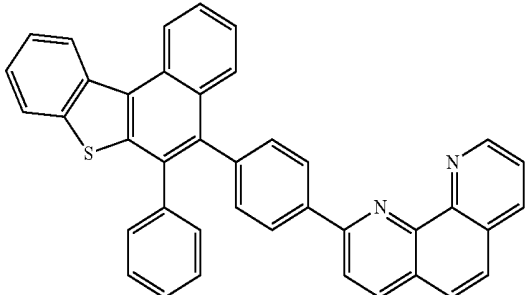
Prep. Ex. 3-1-No	Product 3-1-No	structure	MS [M + H] ⁺
3-1-9	compound 3-1-9		628
3-1-10	compound 3-1-10		783
3-1-11	compound 3-1-11		587
3-1-12	compound 3-1-12		565

TABLE 3-1-continued

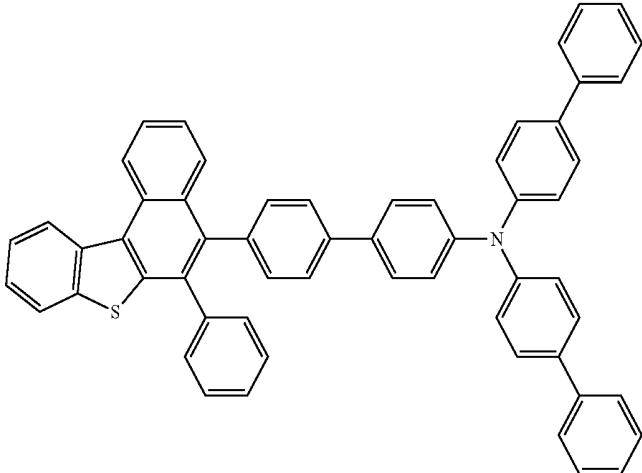
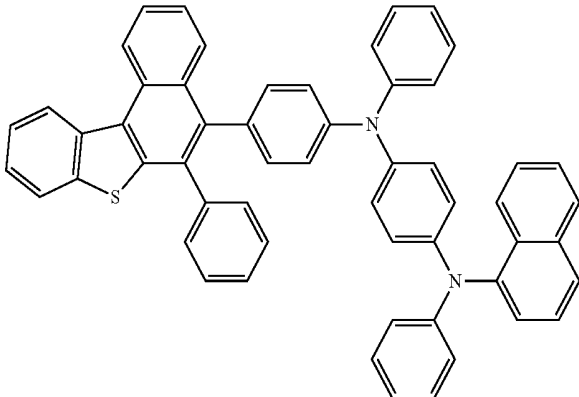
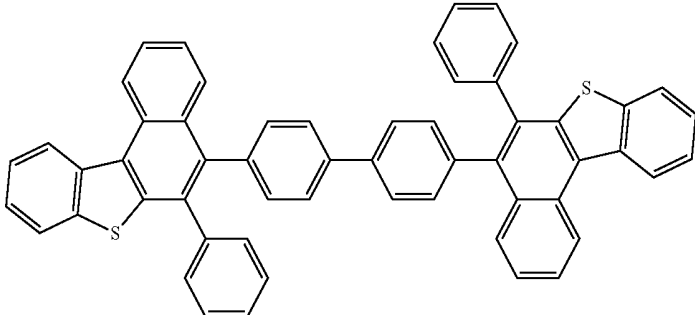
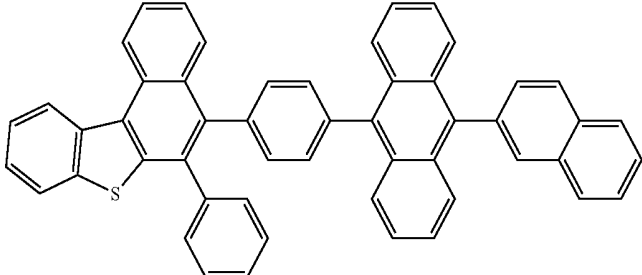
Prep. Ex. 3-1-No	Product 3-1-No	structure	MS [M + H] ⁺
3-1-13	compound 3-1-13		782
3-1-14	compound 3-1-14		771
3-1-15	compound 3-1-15		771
3-1-16	compound 3-1-16		689

TABLE 3-1-continued

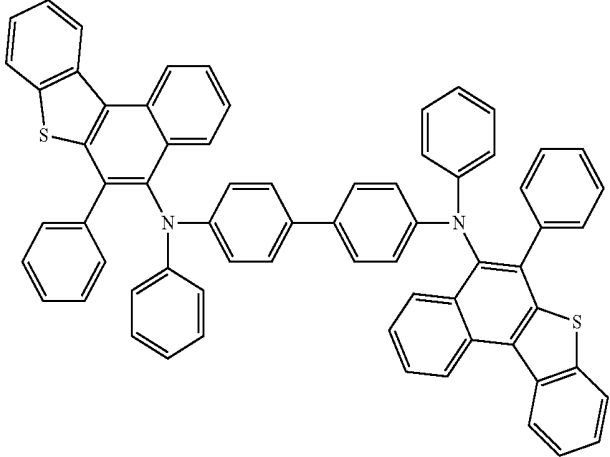
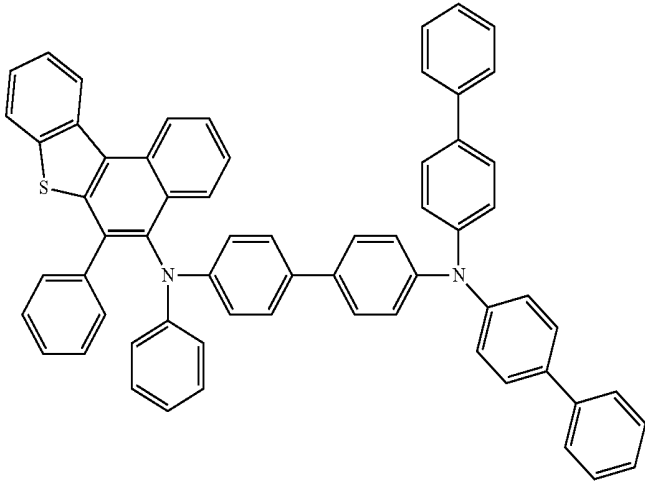
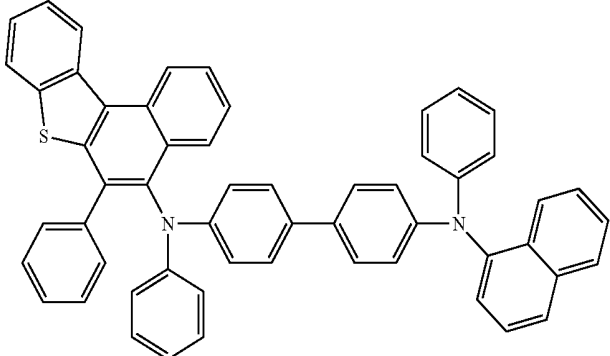
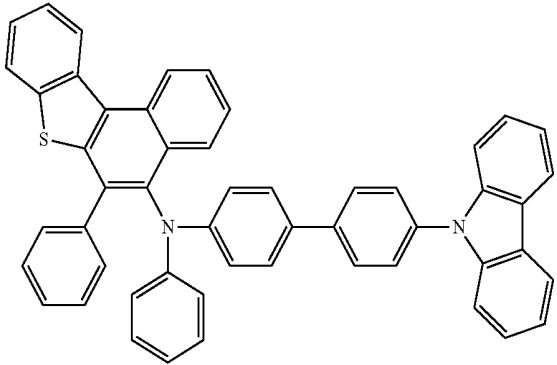
Prep. Ex. 3-1-No	Product 3-1-No	structure	MS [M + H] ⁺
3-1-17	compound 3-1-17		953
3-1-18	compound 3-1-18		873
3-1-19	compound 3-1-19		771

TABLE 3-1-continued

Prep. Ex. 3-1-No	Product 3-1-No	structure	MS [M + H] ⁺
3-1-20	compound 3-1-20		719

PREPARATION EXAMPLE 3-1-17

Preparation of the Compound 3-1-17

[0269] In Preparation Example 1-5-1, the compound 3-1-17 was prepared by using the same method, except that 2.4 equivalents of the compound A-3 and 4.8 equivalents of sodium-tertiary-butoxide were used instead of the compound 1-12-1 and the reactant S-41 was used instead of the reactant S-28.

PREPARATION EXAMPLE 3-1-18

Preparation of the Compound 3-1-18

[0270] In Preparation Example 1-5-1, the compound 3-1-18 was prepared by using the same method, except that the compound A-3 was used instead of the compound 1-12-1 and the reactant S-43 was used instead of the reactant S-28.

PREPARATION EXAMPLE 3-1-19

Preparation of the Compound 3-1-19

[0271] In Preparation Example 1-5-1, the compound 3-1-19 was prepared by using the same method, except that the compound A-3 was used instead of the compound 1-12-1 and the reactant S-44 was used instead of the reactant S-28.

PREPARATION EXAMPLE 3-1-20

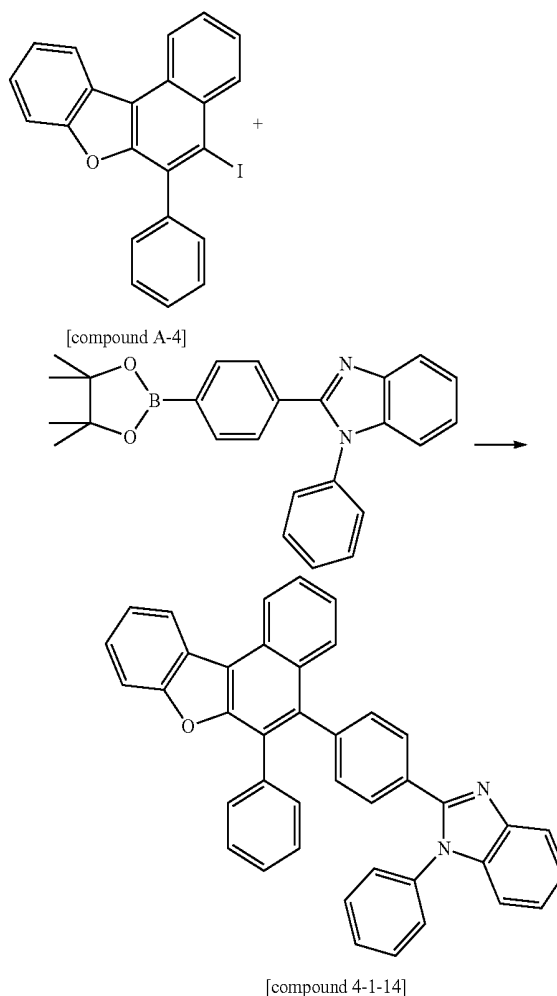
Preparation of the Compound 3-1-20

[0272] In Preparation Example 1-5-1, the compound 3-1-20 was prepared by using the same method, except that the compound A-3 was used instead of the compound 1-12-1 and the reactant S-42 was used instead of the reactant S-28.

PREPARATION EXAMPLE 4-1-14

Preparation of the Compound 4-1-14

[0273]



[0274] The reactant S-15 (1.5 g, 4.9 mmol), the prepared compound A-4 (1.7 g, 4.1 mmol), and sodium carbonate (1.4 g, 10.0 mmol) were suspended in the mixture of tetrahydrofuran (100 mL) and water (50 mL). Tetrakis(triphenylphosphine)palladium (0.1 g, 0.1 mmol) was applied to the suspension solution. The mixture was refluxed and agitated for about 24 hours, and the refluxed mixture was cooled to room temperature. The prepared solid was purified with filtered THF/EtOH to prepare the compound 4-1-14 (2.3 g, yield 82%).

PREPARATION EXAMPLE 4-1-1 TO 4-1-12

Preparation of the Compounds 4-1-1 to 4-1-12

[0275] In Preparation Example 4-1-14, it was prepared by using the same method to prepare the compounds 4-1-1 to

4-1-12, except that the reactants S-22, S-10, S-9, S-5, S-8, S-7, S-31, S-38, S-36, S-34, and S-25 were used instead of the reactant S-15.

PREPARATION EXAMPLE 4-1-13

Preparation of the Compound 4-1-13

[0276] In Preparation Example 4-1-14, it was prepared by using the same method to prepare the compound 4-1-13, except that the reactant S-23 was used instead of the reactant S-15 in an equivalent of 2.4.

TABLE 4-1

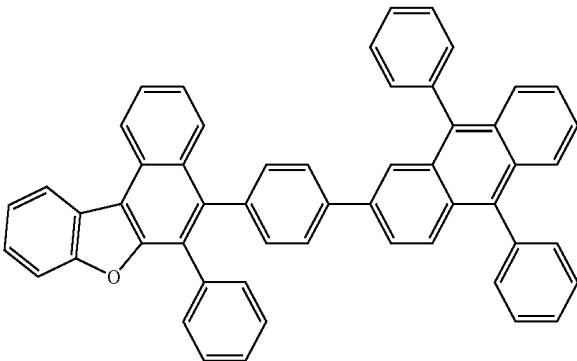
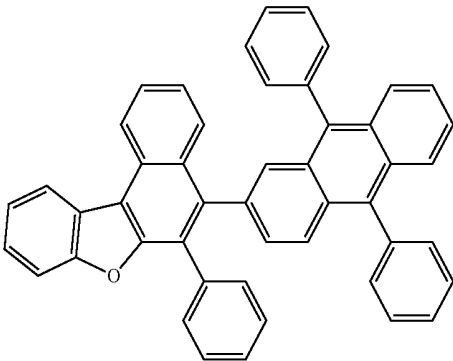
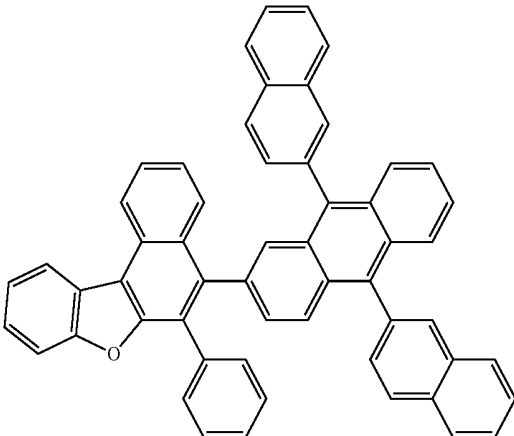
Prep. Ex. 4-1-No	Product 4-1-No	structure	MS [M + H] ⁺
4-1-1	compound 4-1-1		699
4-1-2	compound 4-1-2		623
4-1-3	compound 4-1-3		723

TABLE 4-1-continued

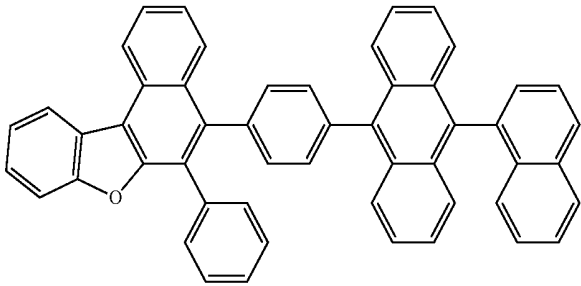
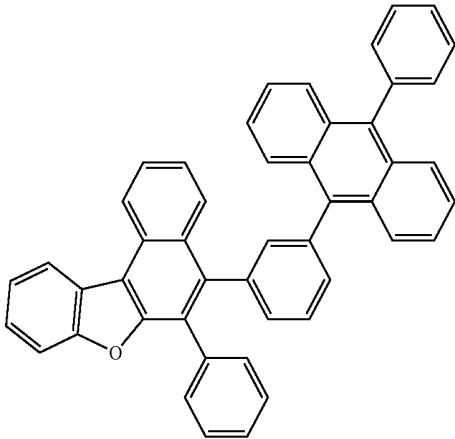
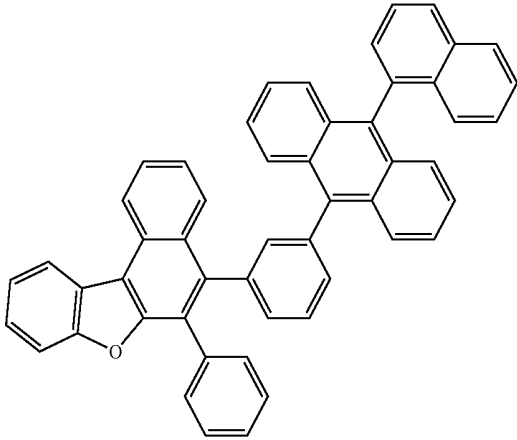
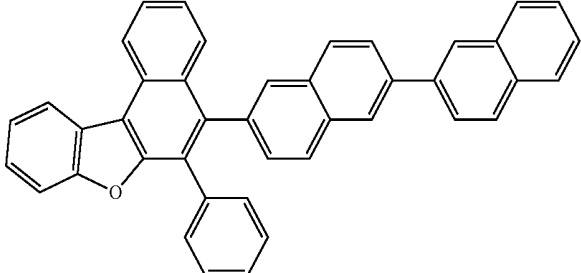
Prep. Ex.	Product		MS
4-1-No	4-1-No	structure	[M + H] ⁺
4-1-4	compound 4-1-4		673
4-1-5	compound 4-1-5		623
4-1-6	compound 4-1-6		673
4-1-7	compound 4-1-7		547

TABLE 4-1-continued

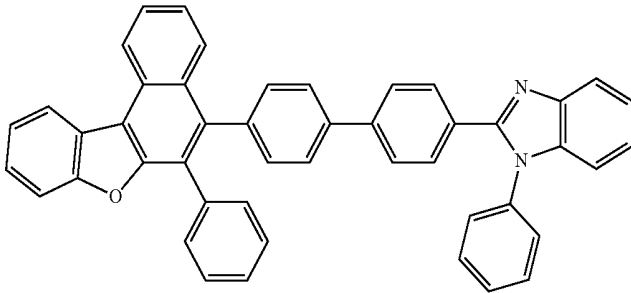
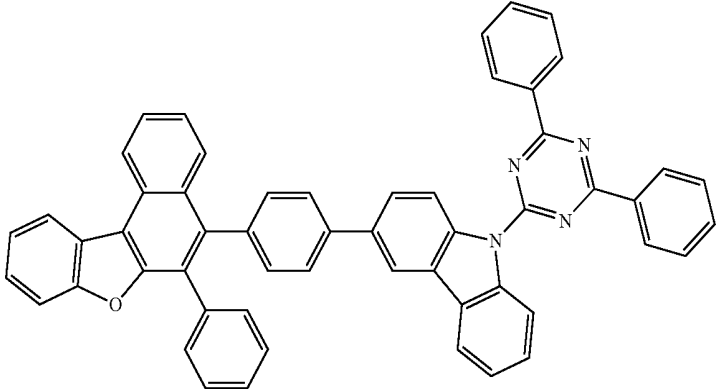
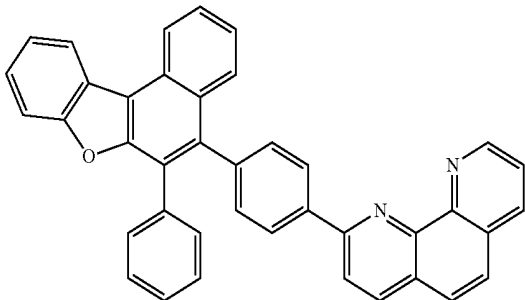
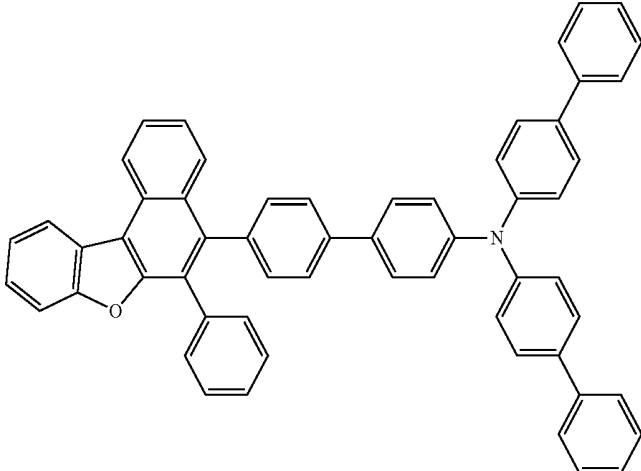
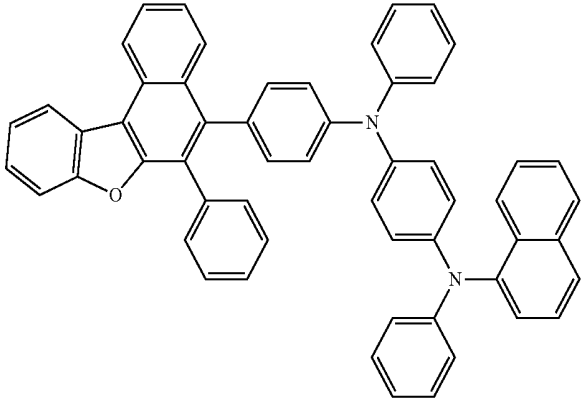
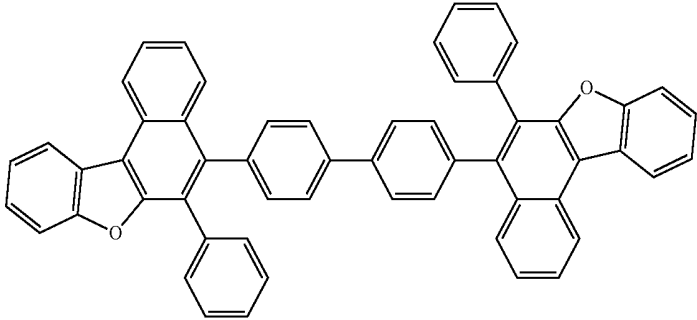
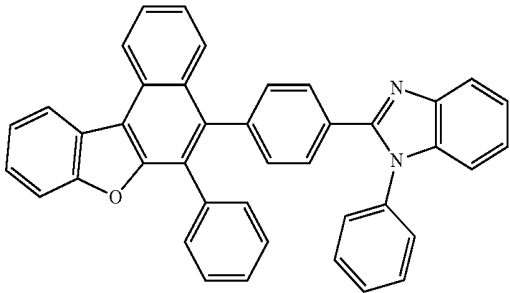
Prep. Ex. 4-1-No	Product 4-1-No	structure	MS [M + H] ⁺
4-1-8	compound 4-1-8		639
4-1-9	compound 4-1-9		767
4-1-10	compound 4-1-10		549
4-1-11	compound 4-1-11		766

TABLE 4-1-continued

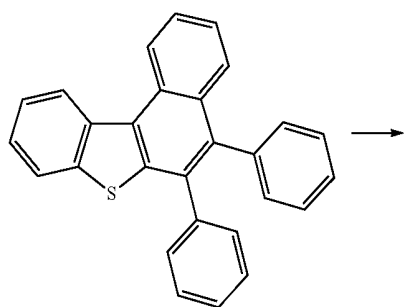
Prep. Ex. 4-1-No	Product 4-1-No	structure	MS [M + H] ⁺
4-1-12	compound 4-1-12		755
4-1-13	compound 4-1-13		739
4-1-14	compound 4-1-14		563

PREPARATION EXAMPLE 5-1-1

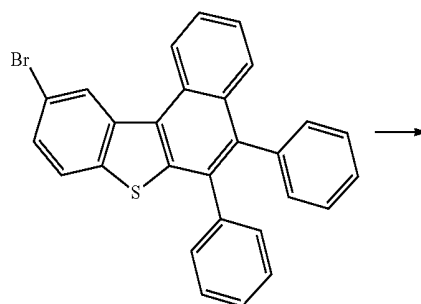
Preparation of the Compound 5-1-1

-continued

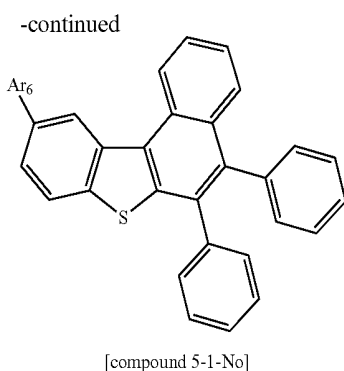
[0277]



[compound A-3]



[compound A-5]



[0278] Synthesis of the Compound A-5

[0279] In Preparation Example 3-1-16, it was prepared by using the same method to prepare the compound A-5, except that the phenyl boronic acid that was the reactant S-3 was used instead of the reactant S-33.

[0280] Synthesis of the compound C-5-1

[0281] After the compound B-5-1 (4.6 g, 12.0 mmol) was dissolved in DMF 60 mL, NBS (2.2 g, 12.0 mmol) was applied thereto and agitated at normal temperature for 2

hours. After water 120 mL was applied thereto to precipitate the solid, it was filtered, washed with ethanol, and dried to prepare the compound C-5-1 (3.8 g, yield 68%).

[0282] MS $[M]^+ = 465$

[0283] Preparation of the Compound 5-1-1

[0284] In Preparation Example 3-1-16, the compound 5-1-1 was prepared by using the same method, except that the compound A-5 was used instead of the compound A-3 and the reactant S-26 was used instead of the reactant S-33.

PREPARATION EXAMPLE 5-1-2

Preparation of the Compound 5-1-2

[0285] In Preparation Example 3-1-16, the compound 5-1-2 was prepared by using the same method, except that the compound A-5 was used instead of the compound A-3 and the reactant S-16 was used instead of the reactant S-33.

PREPARATION EXAMPLE 5-1-3

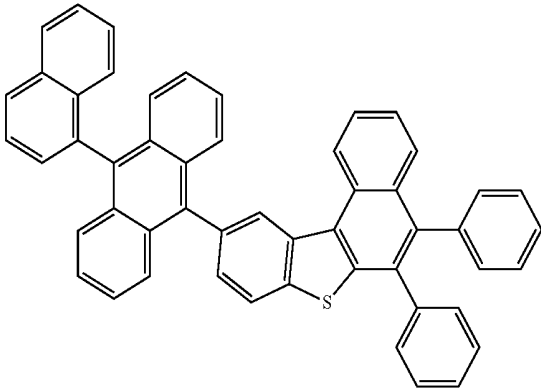
Preparation of the Compound 5-1-3

[0286] In Preparation Example 3-1-16, the compound 5-1-3 was prepared by using the same method, except that the compound A-5 was used instead of the compound A-3 and the reactant S-40 was used instead of the reactant S-33.

TABLE 5-1

Prep. Ex.	Product	structure	MS [M + H] ⁺
5-1-No	5-1-No		
5-1-1	compound 5-1-1		782
5-1-2	compound 5-1-2		694

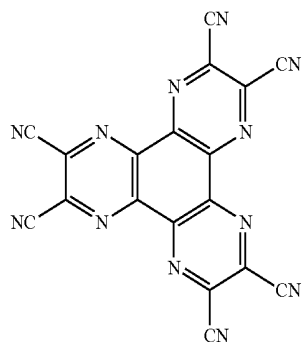
TABLE 5-1-continued

Prep. Ex. 5-1-No	Product 5-1-No	structure	MS [M + H] ⁺
5-1-3	compound 5-1-3		689

EXPERIMENTAL EXAMPLE 1-1

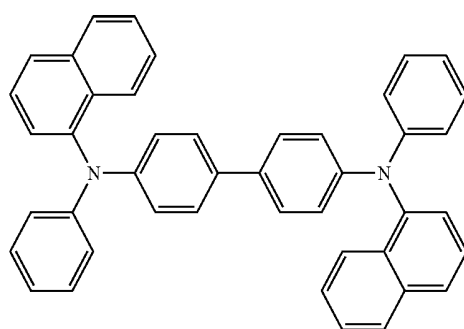
[0287] A glass substrate on which a thin film of ITO (indium tin oxide) was coated to a thickness of 1500 Å was immersed in distilled water having a detergent dissolved therein to wash the substrate with ultrasonic waves. At this time, the detergent as used herein was a product commercially available from Fisher Co. and the distilled water was one which had been twice filtered by using a filter commercially available from Millipore Co. ITO was washed for 30 minutes, and then washing with ultrasonic waves was repeated twice for 10 minutes by using distilled water. After the completion of washing with distilled water, washing with ultrasonic waves was subsequently carried out by using solvents such as isopropyl alcohol, acetone and methanol, the resultant product was dried, and transported to the plasma washing machine. In addition, the substrate was washed by using the oxygen plasma for 5 min, and the substrate was transported to the vacuum deposition machine.

[0288] On the ITO transparent electrode thus prepared, hexanitrile hexaazatriphenylene was coated to thicknesses of 500 Å by thermal vacuum deposition to form a hole injecting layer. After NPB (400 Å) that was the material transporting the holes was deposited under the vacuum state thereon, the host H1 and the dopant D1 compound were deposited under the vacuum state in a thickness of 300 Å as a light emitting layer.

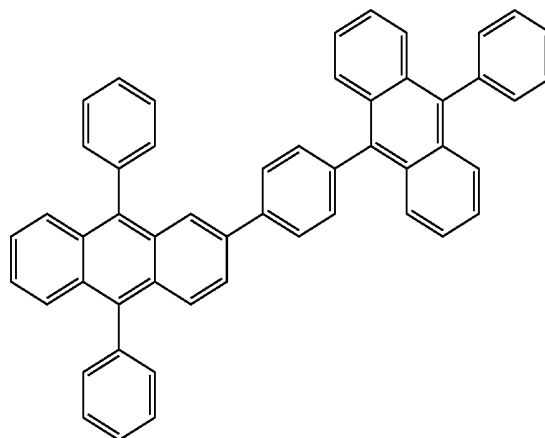


[hexanitrile hexaazatriphenylene]

-continued



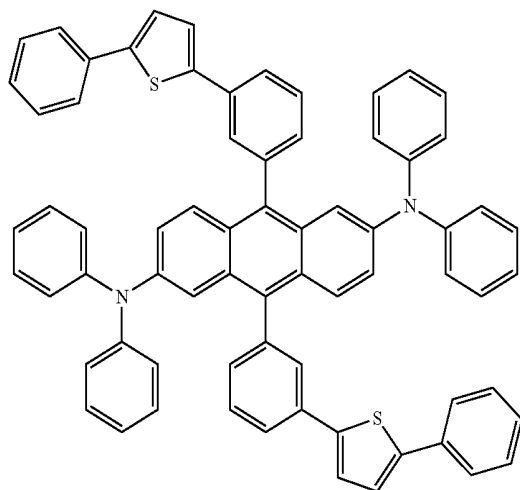
[NPB]



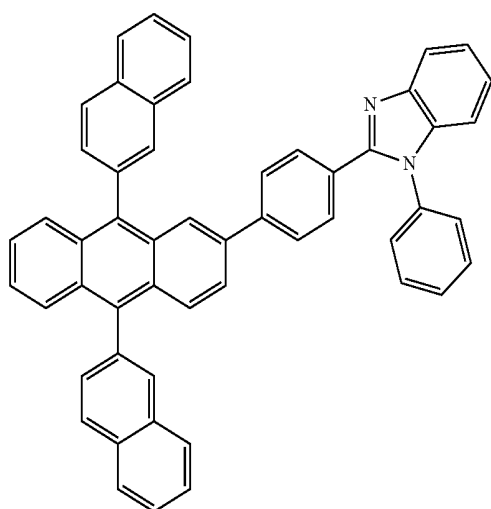
[H1]

-continued

[D1]



[E1]



[0289] On the light emitting layer, the compound 1-1-10—prepared in Preparation Example 1-1-10 was deposited under the vacuum state in a thickness of 200 Å to form the electron injection and transport layer. On the electron injection and transport layer, lithium fluoride (LiF) in a thickness of 12 Å and aluminium in a thickness of 2000 Å were subsequently deposited to form a cathode.

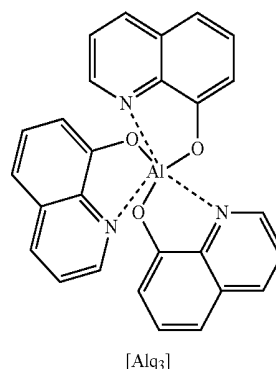
[0290] In the above process, the deposition speed of the organic substance was maintained at 1 Å/sec, that of lithium fluoride was maintained at 0.2 Å/sec, and that of aluminium was maintained at 3 to 7 Å/sec.

EXPERIMENTAL 1-2 TO EXPERIMENTAL EXAMPLE 1-12

[0291] In Experimental Example 1-1, the same experiment was performed, except that on the light emitting layer, the compounds 1-1-11, 1-1-14, 1-2-1, 1-2-5, 1-2-11, 1-2-14, 3-1-8, 3-1-12, 4-1-8, 4-1-10, 4-1-14, and 5-1-2 were used instead of the compound 1-1-10 prepared in Preparation Example 1-1-10.

COMPARATIVE EXAMPLE 1

[0292] In Experimental Example 1-1, the same experiment was performed, except that on the light emitting layer, the compound Alq₃ was used instead of the compound 1-1-10.



[0293] Like Experimental Examples 1-1 to 1-12 and Comparative Example 1, the test results of the organic light emitting device that was prepared by using each compound as the electron injection and transport layer material are described in Table 11.

TABLE 11

Exp. Ex. 100 mA/cm ²	compound	Voltage (V)	Cur. Eff. (cd/A)	Color Coordinate (x, y)
Com. Ex. 1	Alq ₃	10.91	10.96	(0.323, 0.644)
Exp. Ex. 1-1	1-1-10	7.76	21.06	(0.317, 0.649)
Exp. Ex. 1-2	1-1-11	7.05	24.22	(0.323, 0.647)
Exp. Ex. 1-3	1-1-14	8.14	24.28	(0.314, 0.650)
Exp. Ex. 1-4	1-2-1	6.91	23.27	(0.310, 0.652)
Exp. Ex. 1-5	1-2-5	8.29	24.63	(0.318, 0.653)
Exp. Ex. 1-6	1-2-11	8.91	18.44	(0.317, 0.645)
Exp. Ex. 1-7	1-2-14	8.28	18.61	(0.318, 0.652)
Exp. Ex. 1-8	3-1-8	7.31	21.12	(0.318, 0.658)
Exp. Ex. 1-9	3-1-12	7.12	24.34	(0.319, 0.657)
Exp. Ex. 1-10	4-1-8	8.19	24.65	(0.318, 0.658)
Exp. Ex. 1-11	4-1-10	8.37	22.52	(0.318, 0.653)
Exp. Ex. 1-11	4-1-14	8.31	22.91	(0.317, 0.651)
Exp. Ex. 1-12	5-1-2	8.32	20.98	(0.317, 0.653)

[0294] As shown in the results of Table 11, properties are improved in terms of low voltage and efficiency in comparison with the results of the device of Comparative Example 1. In the compounds of Table 11, the substituent group having relatively excellent electron injection and transport properties is introduced. The properties of them are not lowered but improved by the basic structure of Formula 1. This is because the structure of Formula 1 has an appropriate LUMO so as to easily transport electrons to the light emitting layer by introducing the frame having the relatively large energy band gap or the substituent groups having the electron injection and transport properties.

EXPERIMENTAL EXAMPLE 2-1

[0295] A glass substrate on which a thin film of ITO (indium tin oxide) was coated to a thickness of 1500 Å was immersed in distilled water having a detergent dissolved therein to wash the substrate with ultrasonic waves. At this time, the detergent as used herein was a product commercially available from Fisher Co. and the distilled water was

one which had been twice filtered by using a filter commercially available from Millipore Co. ITO was washed for 30 minutes, and then washing with ultrasonic waves was repeated twice for 10 minutes by using distilled water. After the completion of washing with distilled water, washing with ultrasonic waves was subsequently carried out by using solvents such as isopropyl alcohol, acetone and methanol, the resultant product was dried, and transported to the plasma washing machine. In addition, the substrate was washed by using the oxygen plasma for 5 min, and the substrate was transported to the vacuum deposition machine.

[0296] On the ITO transparent electrode thus prepared, hexanitrile hexaazatriphenylene was coated to thicknesses of 500 Å by thermal vacuum deposition to form a hole injecting layer. After NPB (400 Å) that was the material transporting the holes was deposited under the vacuum state thereon, the compound 1-1-7 that was prepared in Preparation Example 1-1-7 as the host H1 and the dopant D1 compound were deposited under the vacuum state in a thickness of 300 Å as a light emitting layer. On the light emitting layer, the electron injection and transport layer was formed by depositing E1 under the vacuum state in a thickness of 200 Å on the light emitting layer. On the electron transport layer, lithium fluoride (LiF) in a thickness of 12 Å and aluminium in a thickness of 2000 Å were subsequently deposited to form a cathode, thereby manufacturing the organic light emitting device.

[0297] In the above process, the deposition speed of the organic material was maintained at 0.4 to 0.7 Å/sec, the deposition speed of the lithium fluoride of the cathode was maintained at 0.3 Å/sec, the deposition speed of aluminium was maintained at 2 Å/sec, and the degree of vacuum in the deposition was maintained at 2×10^{-7} to 5×10^{-8} torr.

EXPERIMENTAL EXAMPLE 2-2 TO EXPERIMENTAL EXAMPLE 2-36

[0298] In Experimental Example 2-1, the organic light emitting device was experimented by using the same method, except that the compounds 1-1-6, 1-2-6, 1-2-7, 1-2-8, 1-2-9, 1-2-10, 1-2-12, 1-2-13, 1-3-1, 1-3-2, 1-3-3, 1-3-4, 1-4-1, 1-4-2, 1-4-3, 1-7-1, 1-7-3, 2-1-1, 2-1-3, 2-1-4, 2-1-5, 3-1-1, 3-1-2, 3-1-3, 3-1-4, 3-1-5, 3-1-6, 4-1-1, 4-1-2, 4-1-3, 4-1-4, 4-1-5, 4-1-6, 4-1-7, and 5-1-3 were used instead of the compound 1-1-7 on the hole transport layer, and the results thereof are described in Table 12.

TABLE 12

Exp. Ex. 100 mA/cm ²	Host Material	Dopant Material	Voltage (V)	Cur. Eff. (cd/A)	Color Coordinate (x, y)
Exp. Ex. 2-1	1-1-7	D1	7.34	23.35	(0.314, 0.652)
Exp. Ex. 2-2	1-1-6	D1	7.61	21.62	(0.314, 0.650)
Exp. Ex. 2-3	1-2-6	D1	8.82	22.04	(0.315, 0.648)
Exp. Ex. 2-4	1-2-7	D1	8.09	21.63	(0.317, 0.650)
Exp. Ex. 2-5	1-2-8	D1	7.67	23.06	(0.315, 0.651)
Exp. Ex. 2-6	1-2-9	D1	8.67	20.23	(0.315, 0.650)
Exp. Ex. 2-7	1-2-10	D1	10.51	16.26	(0.314, 0.650)
Exp. Ex. 2-8	1-2-12	D1	10.06	20.46	(0.317, 0.650)
Exp. Ex. 2-9	1-2-13	D1	8.08	21.40	(0.317, 0.647)
Exp. Ex. 2-10	1-3-1	D1	8.05	26.10	(0.315, 0.648)
Exp. Ex. 2-11	1-3-2	D1	8.01	26.18	(0.316, 0.648)
Exp. Ex. 2-12	1-3-3	D1	7.62	20.26	(0.314, 0.650)
Exp. Ex. 2-13	1-3-4	D1	8.01	21.36	(0.317, 0.650)
Exp. Ex. 2-14	1-4-1	D1	7.65	23.63	(0.315, 0.651)
Exp. Ex. 2-15	1-4-2	D1	8.53	22.21	(0.315, 0.650)
Exp. Ex. 2-16	1-4-3	D1	8.10	20.05	(0.314, 0.650)
Exp. Ex. 2-17	1-7-1	D1	11.71	24.02	(0.319, 0.649)

TABLE 12-continued

Exp. Ex. 100 mA/cm ²	Host Material	Dopant Material	Voltage (V)	Cur. Eff. (cd/A)	Color Coordinate (x, y)
Exp. Ex. 2-18	1-7-3	D1	10.32	21.46	(0.317, 0.650)
Exp. Ex. 2-19	2-1-1	D1	8.23	23.40	(0.317, 0.647)
Exp. Ex. 2-20	2-1-3	D1	8.91	22.02	(0.319, 0.649)
Exp. Ex. 2-21	2-1-4	D1	7.22	22.10	(0.315, 0.648)
Exp. Ex. 2-22	2-1-5	D1	7.67	20.06	(0.315, 0.651)
Exp. Ex. 2-23	3-1-1	D1	7.15	21.06	(0.315, 0.651)
Exp. Ex. 2-24	3-1-2	D1	8.47	21.23	(0.315, 0.650)
Exp. Ex. 2-25	3-1-3	D1	8.85	22.08	(0.317, 0.648)
Exp. Ex. 2-26	3-1-4	D1	7.66	20.57	(0.315, 0.649)
Exp. Ex. 2-27	3-1-5	D1	7.46	21.22	(0.316, 0.652)
Exp. Ex. 2-28	3-1-6	D1	7.98	19.98	(0.314, 0.652)
Exp. Ex. 2-29	4-1-1	D1	8.38	19.89	(0.314, 0.650)
Exp. Ex. 2-30	4-1-2	D1	8.32	21.89	(0.315, 0.647)
Exp. Ex. 2-31	4-1-3	D1	7.55	20.02	(0.319, 0.649)
Exp. Ex. 2-32	4-1-4	D1	7.97	23.07	(0.318, 0.651)
Exp. Ex. 2-33	4-1-5	D1	8.29	24.01	(0.317, 0.649)
Exp. Ex. 2-34	4-1-6	D1	8.43	20.78	(0.317, 0.651)
Exp. Ex. 2-35	4-1-7	D1	9.03	16.56	(0.317, 0.650)
Exp. Ex. 2-36	5-1-3	D1	8.81	23.80	(0.317, 0.647)

[0299] As shown in the results of Table 12, the compounds of Formula 1 may be used as the light emitting layer in conjunction with the dopant by introducing the aryl group such as anthracene.

EXPERIMENTAL EXAMPLE 3-1

[0300] A glass substrate (corning 7059 glass) on which a thin film of ITO (indium tin oxide) was coated to a thickness of 1000 Å was immersed in distilled water having a detergent dissolved therein to wash the substrate with ultrasonic waves. The detergent as used herein was a product commercially available from Fisher Co. and the distilled water was one which had been twice filtered by using a filter commercially available from Millipore Co. ITO was washed for 30 minutes, and then washing with ultrasonic waves was repeated twice for 10 minutes by using distilled water. After the completion of washing with distilled water, washing with ultrasonic waves was carried out by using solvents such as isopropyl alcohol, acetone and methanol, and the resultant product was dried.

[0301] On the ITO transparent electrode thus prepared, hexanitrile hexaazatriphenylene was coated to thicknesses of 500 Å by thermal vacuum deposition to form a hole injecting layer. After the compound 1-5-1 (400 Å) prepared in Preparation Example 1-5-1, which was the material transporting the holes was deposited under the vacuum state thereon, the host H1 and the dopant D1 compound were deposited under the vacuum state in a thickness of 300 Å as a light emitting layer. Thereafter, the E1 compound (300 Å) was deposited by heating under the vacuum as the electron injection and the transport layer. On the electron transport layer, lithium fluoride (LiF) in a thickness of 12 Å and aluminium in a thickness of 2,000 Å were subsequently deposited to form a cathode, thereby manufacturing the organic light emitting device.

[0302] In the above process, the deposition speed of the organic substance was maintained at 1 Å/sec, that of lithium fluoride was maintained at 0.2 Å/sec, and that of aluminium was maintained at 3 to 7 Å/sec.

EXPERIMENTAL EXAMPLE 3-2
EXPERIMENTAL EXAMPLE 3-18

[0303] In Experimental Example 3-1, the organic light emitting device was experimented by using the same method, except that the compounds 11-5-2, 1-5-3, 1-5-4, 1-5-5, 1-6-1, 1-6-2, 1-6-3, 3-1-13, 3-1-14, 3-1-15, 4-1-11, 4-1-12, 5-1-1, 3-1-17, 3-1-18, 3-1-19, and 3-1-20 were used, and the results thereof are described in Table 13.

TABLE 13

Exp. Ex. 100 mA/cm ²	HTL Material	Voltage (V)	Cur. Eff. (cd/A)	Color Coordinate (x, y)
Com. Ex. 2	NPB	8.89	21.23	(0.323, 0.644)
Exp. Ex. 3-1	1-5-1	7.17	22.05	(0.316, 0.650)
Exp. Ex. 3-2	1-5-2	6.49	19.08	(0.312, 0.650)
Exp. Ex. 3-3	1-5-3	7.28	20.53	(0.315, 0.648)
Exp. Ex. 3-4	1-5-4	7.73	23.72	(0.310, 0.647)
Exp. Ex. 3-5	1-5-5	6.88	21.11	(0.312, 0.651)
Exp. Ex. 3-6	1-6-1	6.17	20.05	(0.313, 0.650)
Exp. Ex. 3-7	1-6-2	7.28	21.53	(0.315, 0.648)
Exp. Ex. 3-8	1-6-3	7.73	24.72	(0.310, 0.650)
Exp. Ex. 3-9	3-1-13	6.89	21.67	(0.313, 0.651)
Exp. Ex. 3-10	3-1-14	7.02	21.05	(0.317, 0.650)
Exp. Ex. 3-11	3-1-15	9.07	18.88	(0.315, 0.651)
Exp. Ex. 3-12	4-1-11	7.27	21.87	(0.312, 0.650)
Exp. Ex. 3-13	4-1-12	7.98	22.43	(0.314, 0.648)
Exp. Ex. 3-14	5-1-1	7.48	20.07	(0.314, 0.650)
Exp. Ex. 3-15	3-1-17	8.21	21.10	(0.316, 0.649)
Exp. Ex. 3-16	3-1-18	7.68	22.02	(0.318, 0.648)
Exp. Ex. 3-17	3-1-19	7.74	20.19	(0.317, 0.650)
Exp. Ex. 3-18	3-1-20	7.51	19.78	(0.312, 0.648)

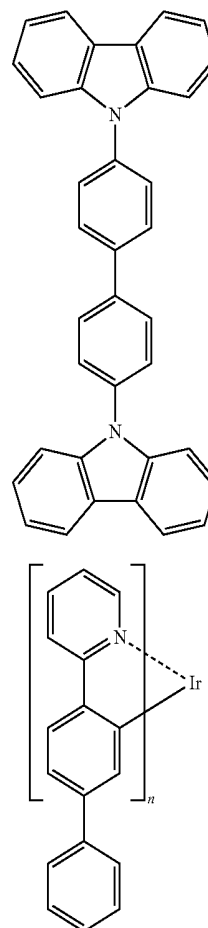
[0304] As shown in the results of Table 13, in the compound of Formula 1, low voltage and efficiency increase may be obtained by using the compounds that were prepared by introducing the aryl group substituted by the arylamin group as the hole transport layer.

EXPERIMENTAL EXAMPLE 4-1

[0305] A glass substrate (corning 7059 glass) on which a thin film of ITO (indium tin oxide) was coated to a thickness of 1000 Å was immersed in distilled water having a detergent dissolved therein to wash the substrate with ultrasonic waves. The detergent as used herein was a product commercially available from Fisher Co. and the distilled water was one which had been twice filtered by using a filter commercially available from Millipore Co. ITO was washed for 30 minutes, and then washing with ultrasonic waves was repeated twice for 10 minutes by using distilled water. After the completion of washing with distilled water, washing with ultrasonic waves was carried out by using solvents such as isopropyl alcohol, acetone and methanol, and the resultant product was dried.

[0306] On the ITO transparent electrode thus prepared, hexanitrile hexaazatriphenylene was coated to thicknesses of 500 Å by thermal vacuum deposition to form a hole injecting layer. NPB (400 Å) was deposited under the vacuum state as the material transporting the holes thereon. As the light emitting layer, the compound 3-1-10 prepared in Preparation Example 3-1-10 and the dopant D2 (doping concentration 14%) compound were deposited under the vacuum state in a thickness of 300 Å.

[H2]



[D2]

[0307] Thereafter, the E1 compound (300 Å) was deposited by heating under the vacuum as the electron injection and the transport layer. On the electron transport layer, lithium fluoride (LiF) in a thickness of 12 Å and aluminium in a thickness of 2,000 Å were subsequently deposited to form a cathode, thereby manufacturing the organic light emitting device.

[0308] In the above process, the deposition speed of the organic substance was maintained at 1 Å/sec, that of lithium fluoride was maintained at 0.2 Å/sec, and that of aluminium was maintained at 3 to 7 Å/sec.

EXPERIMENTAL EXAMPLE 4-2 TO
EXPERIMENTAL EXAMPLE 4-10

[0309] In Experimental Example 4-1, the compounds represented by Formulas 1-1-13, 1-1-14, 1-2-1, 1-2-4, 1-5-2, 1-5-3, 1-6-1, 3-1-9, and 4-1-9 were used instead of the compound 3-1-10, and the organic light emitting device was manufactured by using the compound E1, and the experimental results thereof are described in the following Table 14.

COMPARATIVE EXAMPLE 3

[0310] In Experimental Example 4-1, the same experiment was performed, except that the compound H2 was used instead of the compound 3-1-10.

TABLE 14

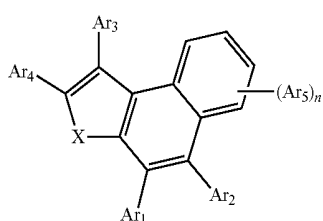
Exp. Ex. 20 mA/cm ²	EML (Host:D3)	Voltage (V)	Cur. Eff. (cd/A)	Color Coordinate (x, y)
Com. Ex. 3	H2	6.74	16.28	(0.371, 0.595)
Exp. Ex. 4-1	3-1-10	5.71	33.28	(0.371, 0.595)
Exp. Ex. 4-2	1-1-13	5.24	31.28	(0.371, 0.595)
Exp. Ex. 4-3	1-1-14	5.52	18.75	(0.354, 0.611)
Exp. Ex. 4-4	1-2-1	5.74	28.28	(0.371, 0.595)
Exp. Ex. 4-5	1-2-4	4.89	31.12	(0.365, 0.601)
Exp. Ex. 4-6	1-5-2	4.31	32.07	(0.362, 0.607)
Exp. Ex. 4-7	1-5-3	4.96	33.07	(0.362, 0.607)
Exp. Ex. 4-8	1-6-1	4.57	33.96	(0.380, 0.589)
Exp. Ex. 4-9	3-1-9	4.31	30.07	(0.362, 0.607)
Exp. Ex. 4-10	4-1-9	6.23	22.77	(0.367, 0.601)

[0311] As shown in Table 14, the compound derivative that is represented by Formula according to the present invention can function as the light emitting material in the organic light emitting device and the organic electronic device, and the device according to the present invention shows excellent characteristics in views of efficiency, the driving voltage, and stability. In particular, in views of efficiency, the high light emitting characteristics are shown.

INDUSTRIAL APPLICABILITY

[0312] An organic light emitting device and an organic electronic device that were prepared by using a novel compound according to the present invention as an organic material layer may act as a hole injection, hole transport, electron injection and transport, or light emitting material, and show excellent properties in terms of efficiency, a driving voltage, and stability.

1. A compound that is represented by the following Formula 1:



[Formula 1]

X is S or O,

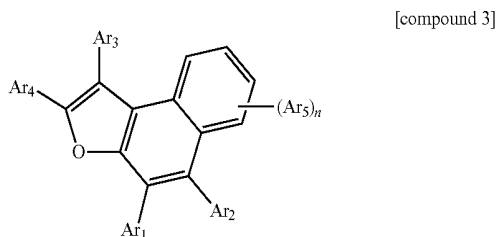
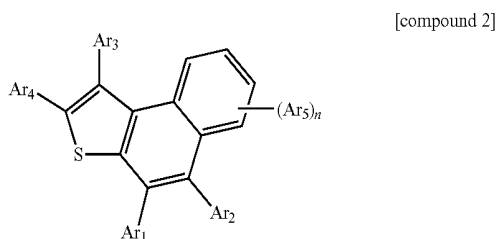
n is an integer in the range of 0 to 4,

Ar₁, Ar₂, Ar₃, Ar₄, and Ar₅ may be the same as or different from each other, and each independently selected from the group consisting of hydrogen atom; heavy hydrogen atom; halogen group; amino group; nitrile group; nitro group; amide group; C₁~C₃₀ alkoxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₃₀ aryloxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group,

nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₁~C₃₀ alkylthioxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₃₀ arylthioxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₃₀ arylthioxy group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; C₆~C₆₀ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, C₁~C₃₀ alkyl group, C₂~C₃₀ alkenyl group, C₁~C₃₀ alkoxy group, C₃~C₃₀ cycloalkyl group, C₂~C₃₀ heterocycloalkyl group, C₆~C₆₀ aryl group and C₃~C₆₀ heteroaryl group; boron group that is substituted

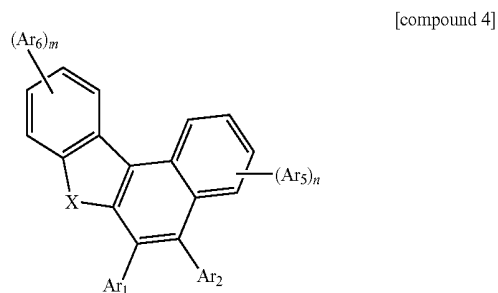
or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, nitrile group, nitro group, $C_1\text{--}C_{30}$ alkyl group, $C_2\text{--}C_{30}$ alkenyl group, $C_1\text{--}C_{30}$ alkoxy group, $C_3\text{--}C_{60}$ cycloalkyl group, $C_2\text{--}C_{30}$ heterocycloalkyl group, $C_6\text{--}C_{60}$ aryl group and $C_3\text{--}C_{60}$ heteroaryl group; silyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, $C_1\text{--}C_{30}$ alkyl group, $C_2\text{--}C_{30}$ alkenyl group, $C_1\text{--}C_{30}$ alkoxy group, $C_3\text{--}C_{60}$ cycloalkyl group, $C_2\text{--}C_{30}$ heterocycloalkyl group, $C_6\text{--}C_{60}$ aryl group and $C_3\text{--}C_{60}$ heteroaryl group; and ester group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, hydroxy group, formyl group, amino group, nitrile group, nitro group, $C_1\text{--}C_{30}$ alkyl group, $C_2\text{--}C_{30}$ alkenyl group, $C_1\text{--}C_{30}$ alkoxy group, $C_3\text{--}C_{60}$ cycloalkyl group, $C_2\text{--}C_{30}$ heterocycloalkyl group, $C_6\text{--}C_{60}$ aryl group and $C_3\text{--}C_{60}$ heteroaryl group, or may form an aliphatic, aromatic, aliphatic hetero or aromatic hetero condensated ring or a Spiro bond in conjunction with an adjacent group.

2. The compound as set forth in claim 1, wherein the compound that is represented by Formula 1 is represented by the following Formula 2 or 3:



wherein, Ar_1 to Ar_5 and n are the same as those defined in Formula 1.

3. The compound as set forth in claim 1, wherein the compound that is represented by Formula 1 is represented by the following Formula 4:



wherein X is S or O ,

m and n are each independently 0 to 4,

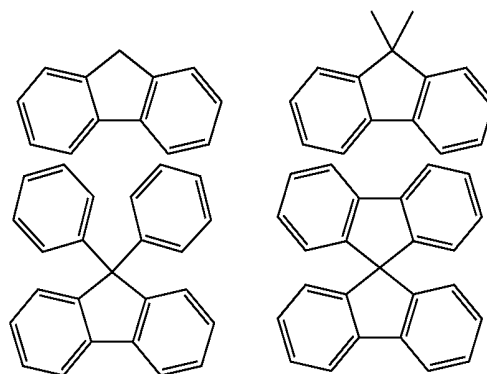
Ar_1 , Ar_2 , Ar_5 , Ar_6 and n are the same as definition of Ar_1 to Ar_5 of Formula 1.

4. The compound as set forth in claim 1, wherein in Formula 1, Ar_2 to Ar_5 may be the same as or different from each other, and each independently $C_6\text{--}C_{60}$ arylaminyl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, $C_1\text{--}C_{30}$ alkyl group, $C_2\text{--}C_{30}$ alkenyl group, $C_1\text{--}C_{30}$ alkoxy group, $C_3\text{--}C_{60}$ cycloalkyl group, $C_2\text{--}C_{30}$ heterocycloalkyl group, $C_6\text{--}C_{60}$ aryl group and $C_3\text{--}C_{60}$ heteroaryl group.

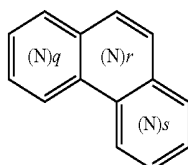
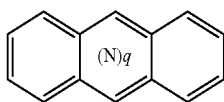
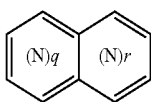
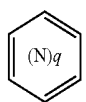
5. The compound as set forth in claim 1, wherein in Formula 1, Ar_2 to Ar_5 may be the same as or different from each other, and each independently $C_6\text{--}C_{60}$ aryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, $C_1\text{--}C_{30}$ alkyl group, $C_2\text{--}C_{30}$ alkenyl group, $C_1\text{--}C_{30}$ alkoxy group, $C_6\text{--}C_{30}$ aryloxy group, $C_1\text{--}C_{30}$ alkylthioxy group, $C_6\text{--}C_{30}$ arylthioxy group, $C_3\text{--}C_{60}$ cycloalkyl group, $C_2\text{--}C_{30}$ heterocycloalkyl group, substituted or unsubstituted $C_1\text{--}C_{30}$ alkylaminyl group, substituted or unsubstituted $C_1\text{--}C_{30}$ aralkylaminyl group, substituted or unsubstituted $C_6\text{--}C_{60}$ arylaminyl group, $C_6\text{--}C_{60}$ aryl group and $C_3\text{--}C_{60}$ heteroaryl group.

6. The compound as set forth in claim 1, wherein in Formula 1, Ar_2 to Ar_5 may be the same as or different from each other, and each independently $C_3\text{--}C_{60}$ heteroaryl group that is substituted or unsubstituted by one or more groups that are selected from the group consisting of heavy hydrogen atom, halogen group, amino group, nitrile group, nitro group, $C_1\text{--}C_{30}$ alkyl group, $C_2\text{--}C_{30}$ alkenyl group, $C_1\text{--}C_{30}$ alkoxy group, $C_6\text{--}C_{30}$ aryloxy group, $C_1\text{--}C_{30}$ alkylthioxy group, $C_6\text{--}C_{30}$ arylthioxy group, $C_3\text{--}C_{60}$ cycloalkyl group, $C_2\text{--}C_{30}$ heterocycloalkyl group, substituted or unsubstituted $C_1\text{--}C_{30}$ alkylaminyl group, substituted or unsubstituted $C_1\text{--}C_{30}$ aralkylaminyl group, substituted or unsubstituted $C_6\text{--}C_{60}$ arylaminyl group, $C_6\text{--}C_{60}$ aryl group and $C_3\text{--}C_{60}$ heteroaryl group.

7. The compound as set forth in claim 1, wherein in Formula 1, the aryl group is selected from the group consisting of phenyl group, biphenyl group, naphthyl group, phenanthryl group, anthracenyl group, pyrenyl group, crycenyl group and fluorenyl group that is represented by the following Structural Formulas:



8. The compound as set forth in claim 1, wherein in Formula 1, the heteroaryl is selected from the following Structural Formulas or condensated ring group thereof:



and in (N)q, (N)r and (N)s, q, r and s are each an integer in the range of 1 to 3

wherein (N)q, (N)r, to (N)s mean that at least one nitrogen atoms exist instead of a carbon atom in a benzene ring,

9. The compound as set forth in claim 1, wherein Ar₁ is a phenyl group.

10. The compound as set forth in claim 1, wherein the compound that is represented by Formula 1 is selected from the compounds that are represented by the compounds described in the following Table:

TABLE 1-1

Product	
1-1-No	structure
compound 1-1-1	
compound 1-1-2	

TABLE 1-1-continued

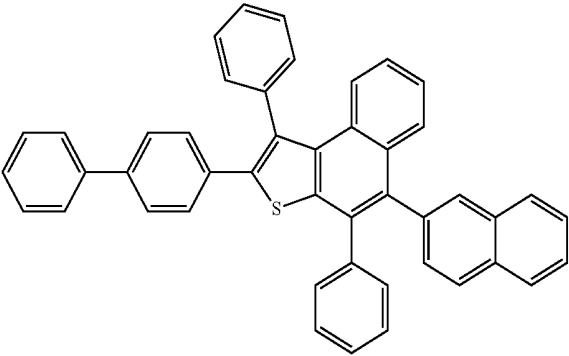
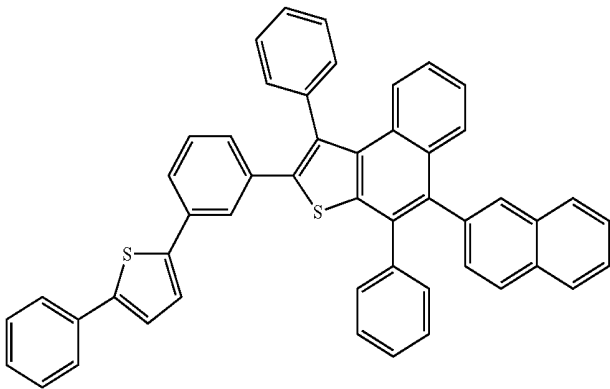
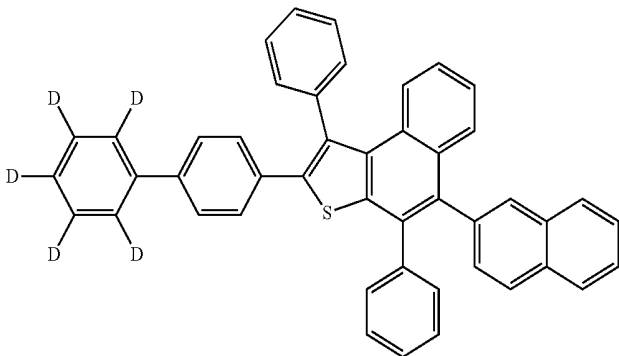
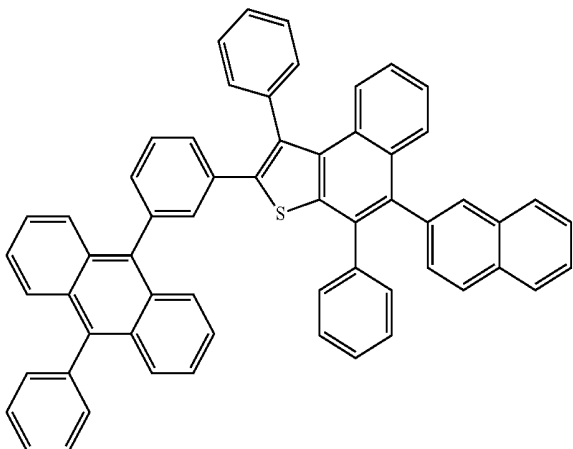
Product 1-1-No	structure
compound 1-1-3	
compound 1-1-4	
compound 1-1-5	
compound 1-1-6	

TABLE 1-1-continued

Product

1-1-No structure

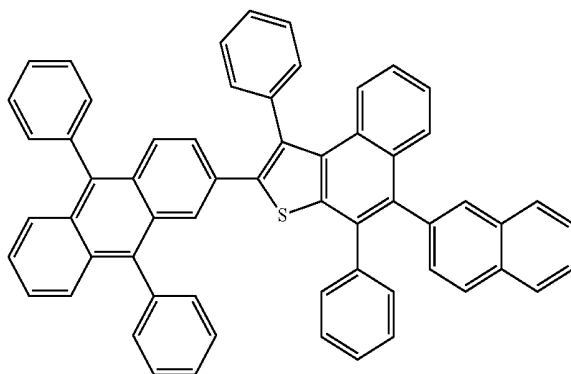
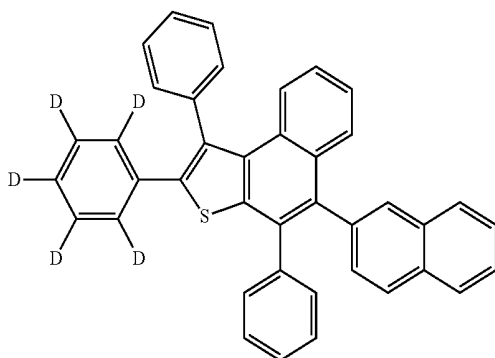
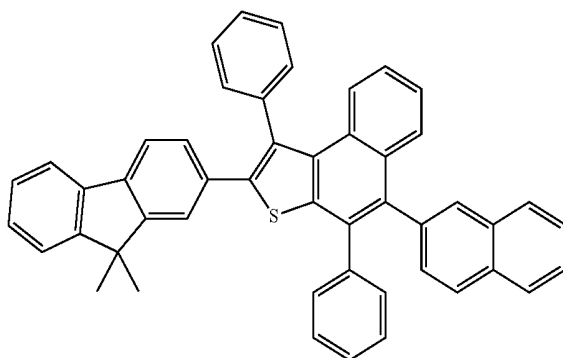
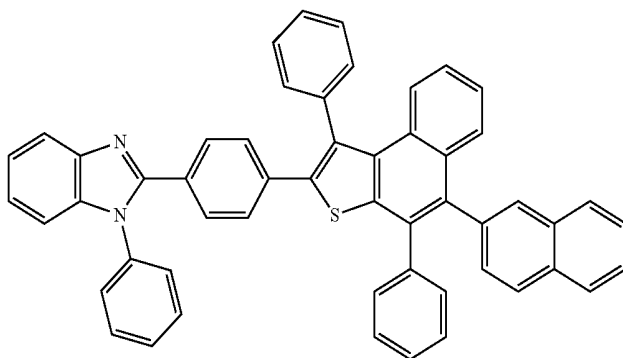
compound
1-1-7compound
1-1-8compound
1-1-9compound
1-1-10

TABLE 1-1-continued

Product

1-1-No structure

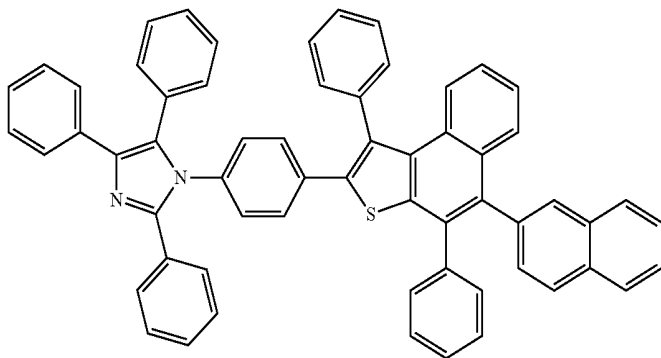
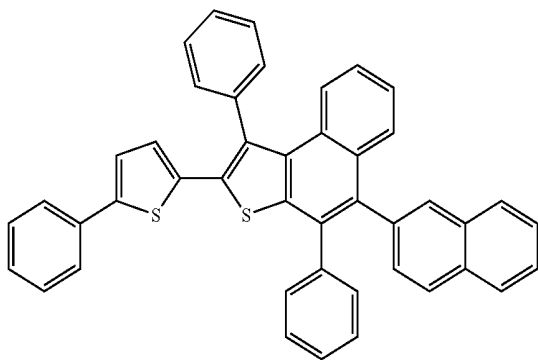
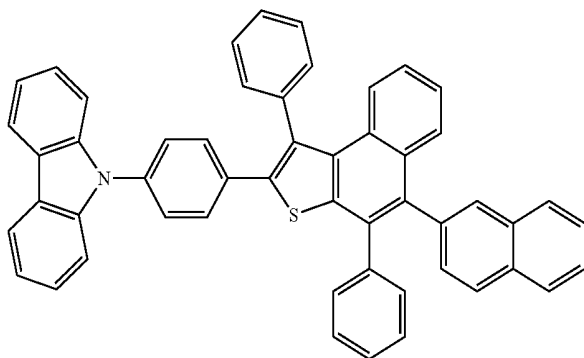
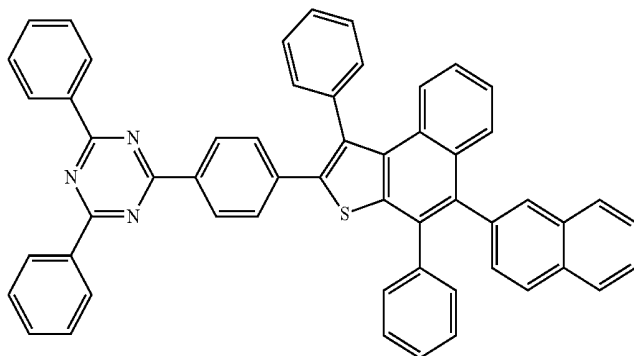
compound
1-1-11compound
1-1-12compound
1-1-13compound
1-1-14

TABLE 1-2

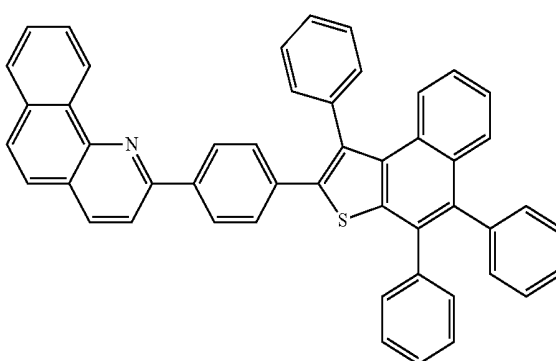
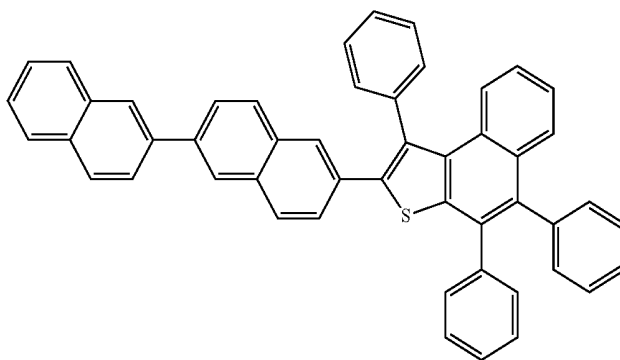
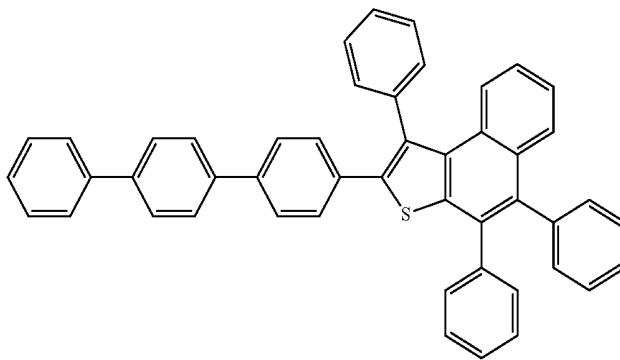
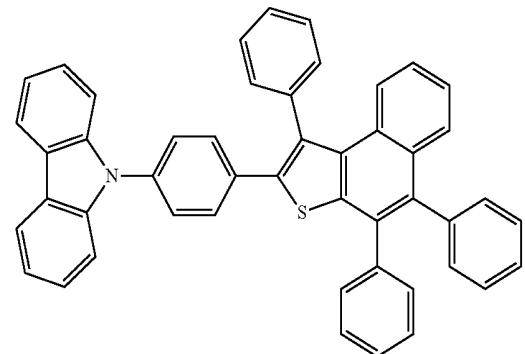
Product 1-2-No	structure
compound 1-2-1	
compound 1-2-2	
compound 1-2-3	
compound 1-2-4	

TABLE 1-2-continued

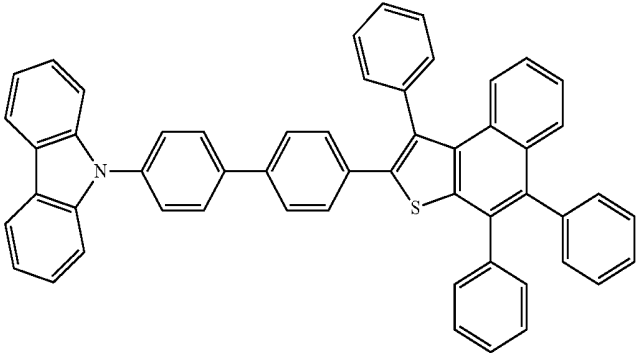
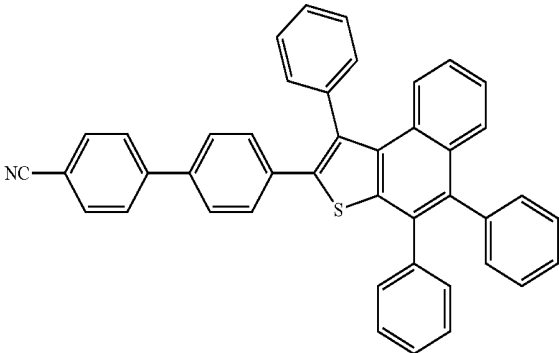
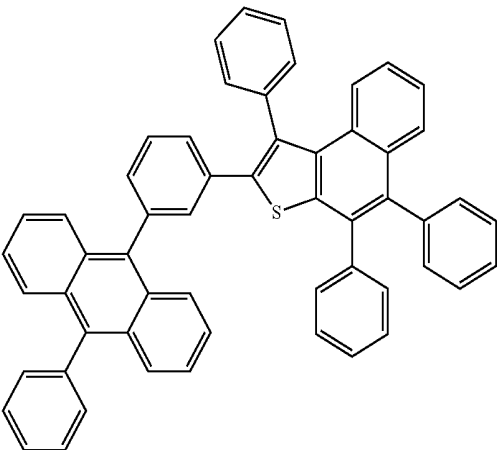
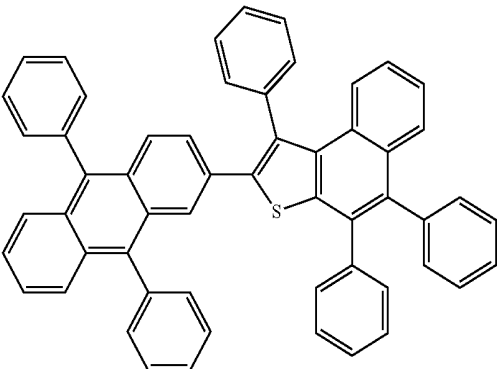
Product 1-2-No	structure
compound 1-2-5	
compound 1-2-6	
compound 1-2-7	
compound 1-2-8	

TABLE 1-2-continued

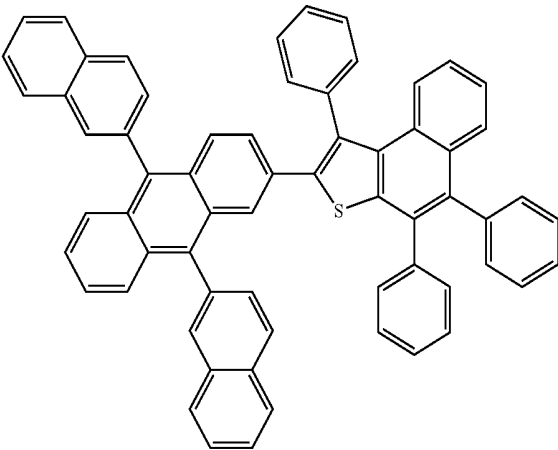
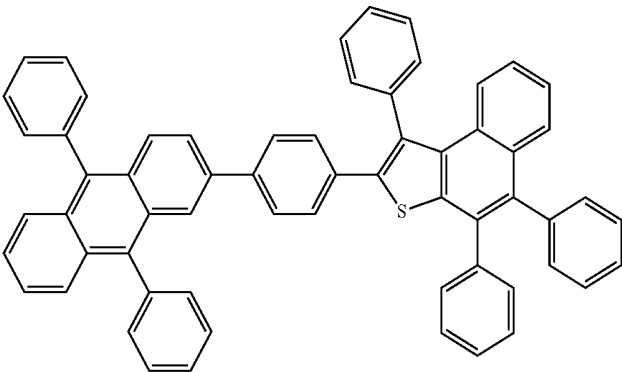
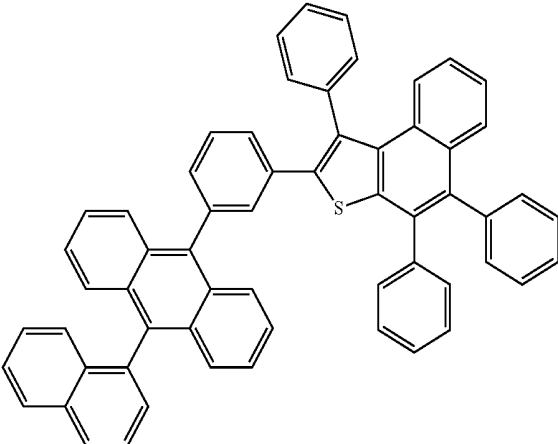
Product	structure
1-2-No	
compound 1-2-9	
compound 1-2-10	
compound 1-2-11	

TABLE 1-2-continued

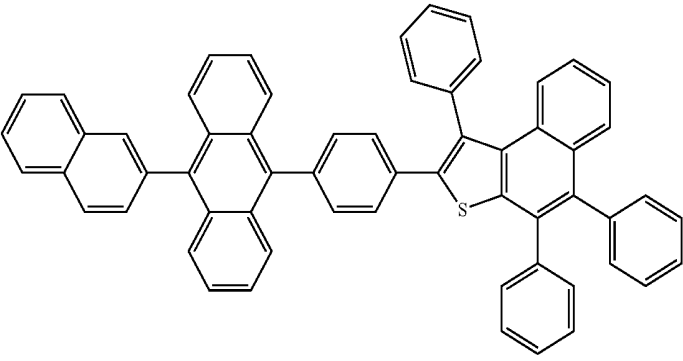
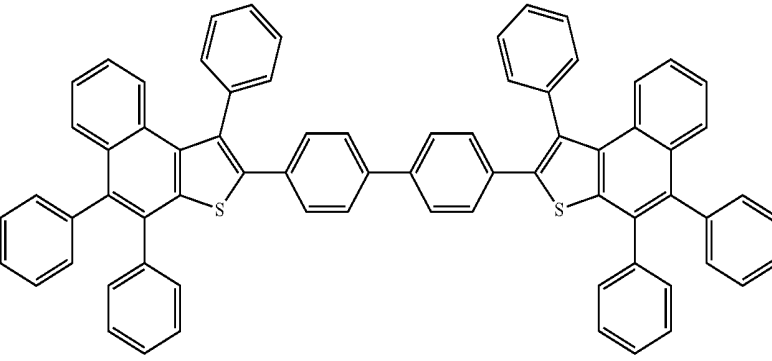
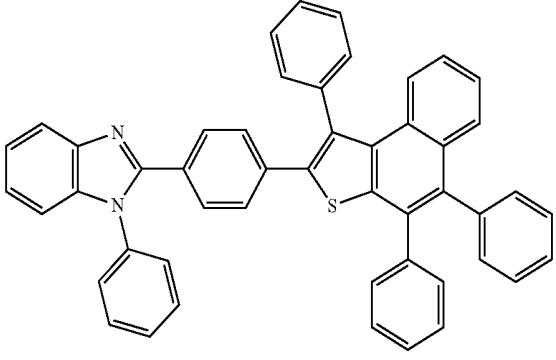
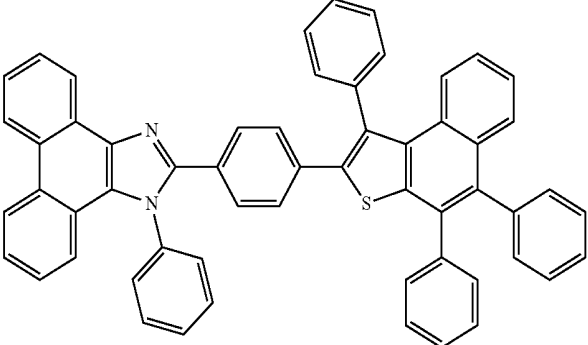
Product 1-2-No	structure
compound 1-2-12	
compound 1-2-13	
compound 1-2-14	
compound 1-2-15	

TABLE 1-2-continued

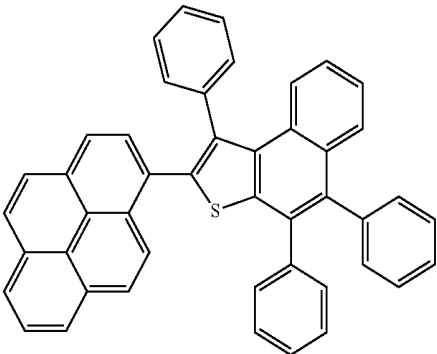
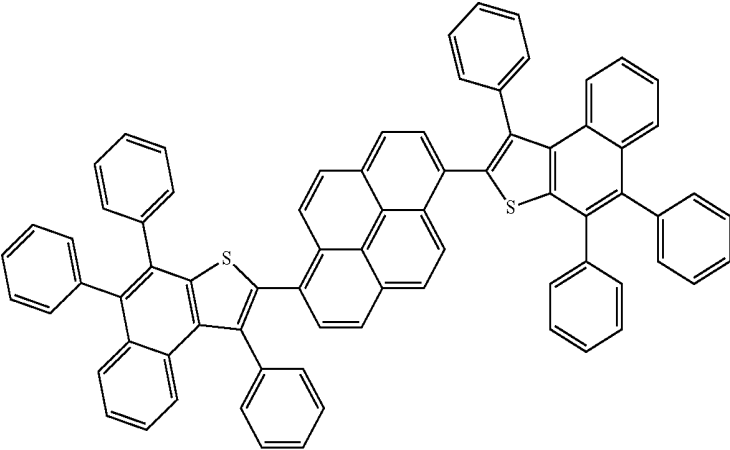
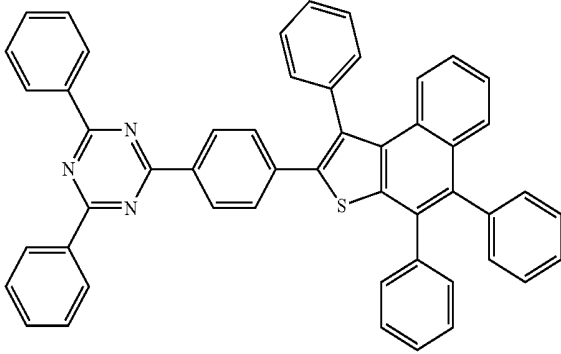
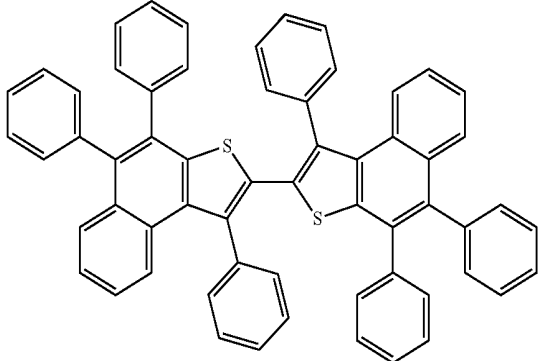
Product 1-2-No	structure
compound 1-2-16	
compound 1-2-17	
compound 1-2-16	
compound 1-2-17	

TABLE 1-2-continued

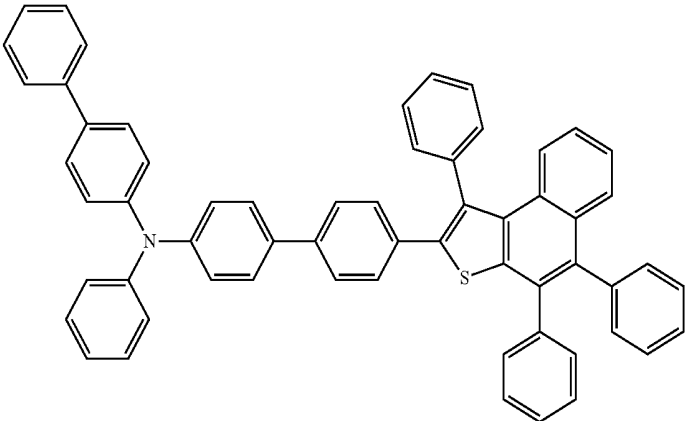
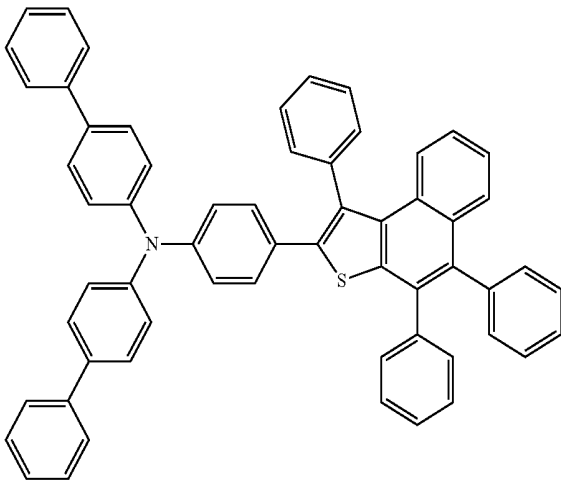
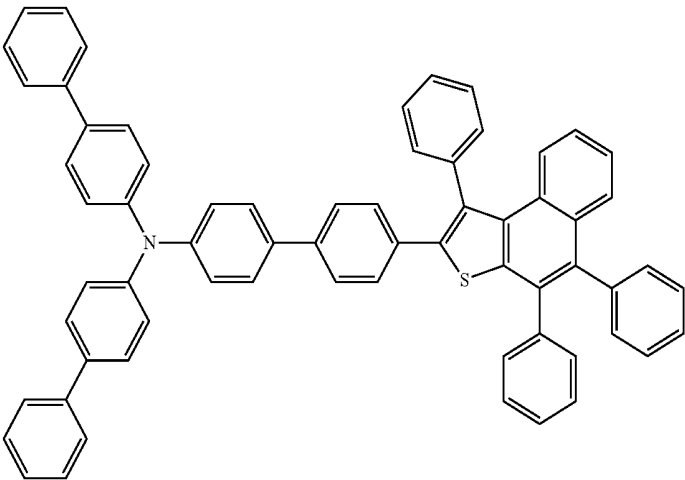
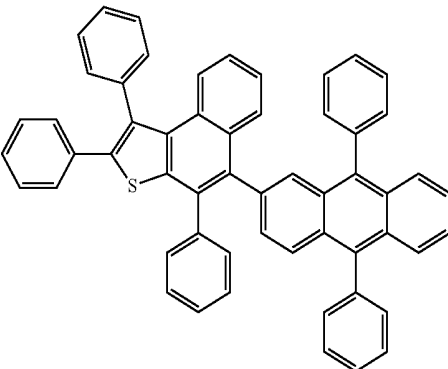
Product 1-2-No	structure
compound 1-2-18	
compound 1-2-19	
compound 1-2-20	

TABLE 1-3

Product	structure
1-3-No	
compound 1-3-1	

compound 1-3-2

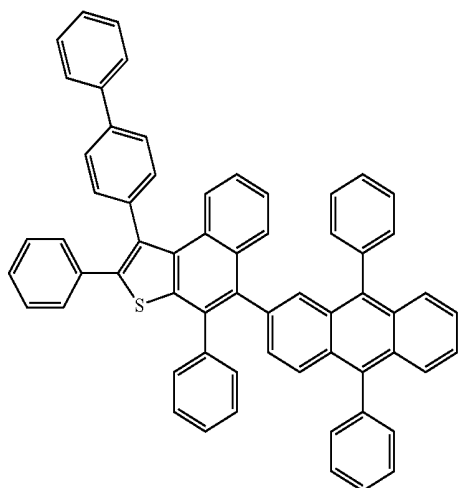


TABLE 1-3-continued

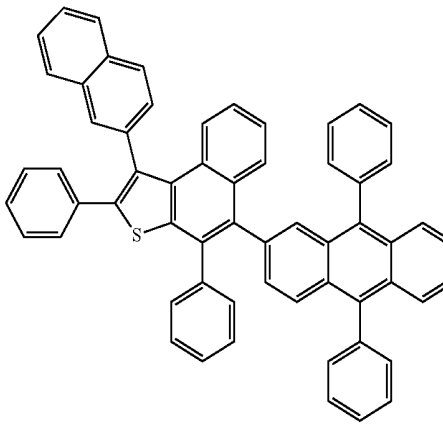
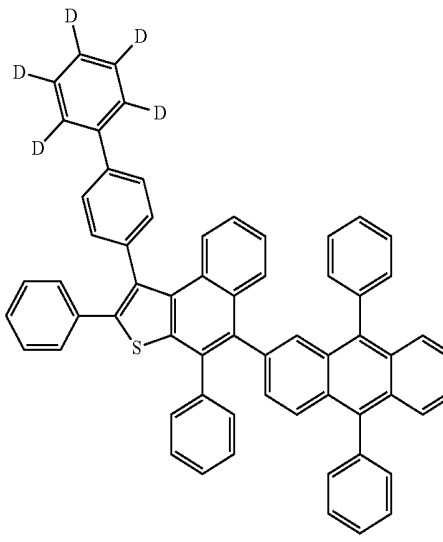
Product	structure
1-3-No	
compound 1-3-3	
compound 1-3-4	

TABLE 1-4

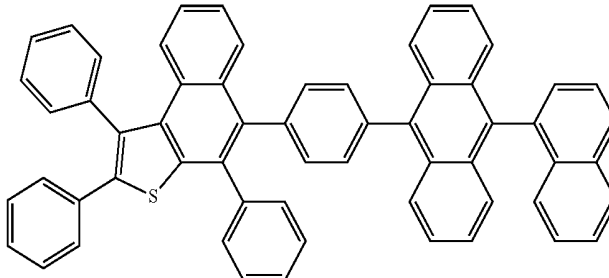
Product	structure
1-4-No	
compound 1-4-1	

TABLE 1-4-continued

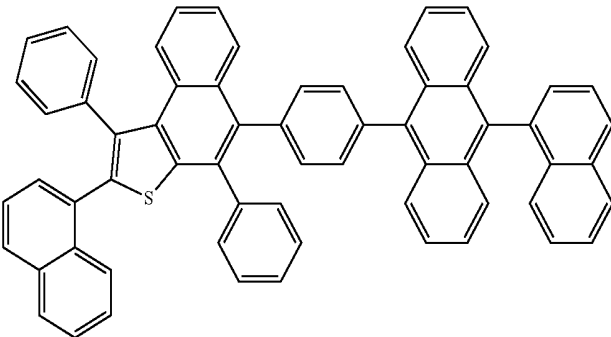
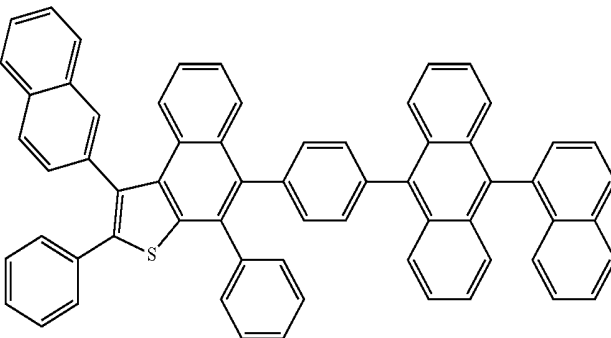
Product 1-4-No	structure
compou2nd 1-4-3	
compound 1-4-	

TABLE 1-5

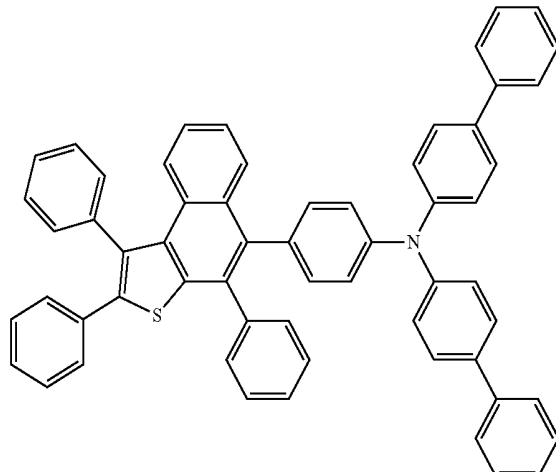
Product 1-5-No	structure
compound 1-5-1	

TABLE 1-5-continued

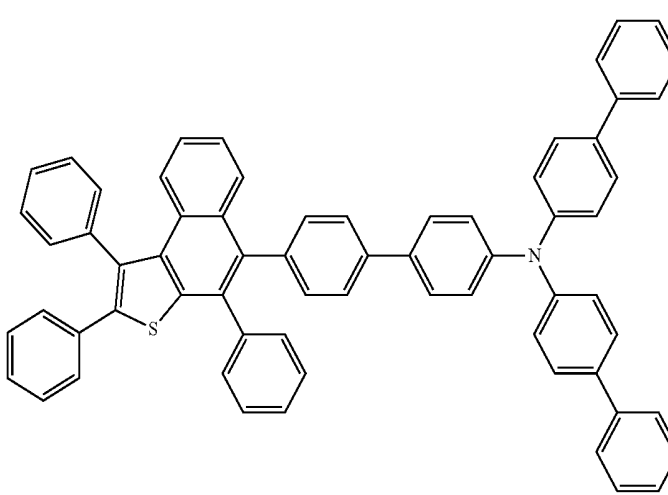
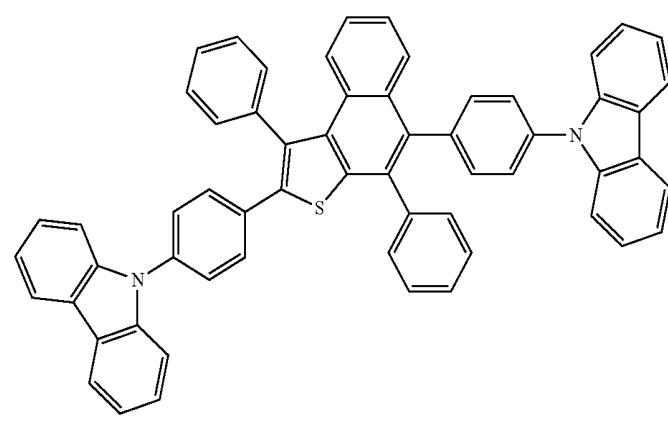
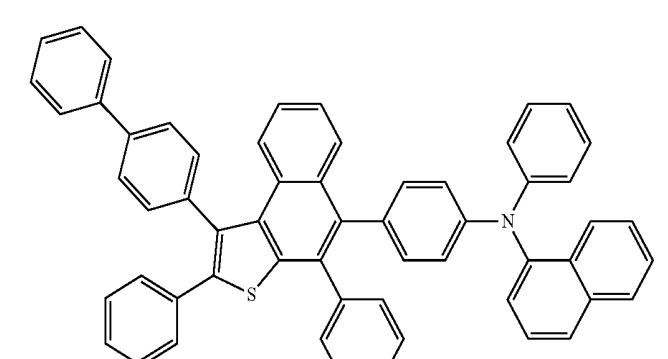
Product 1-5-No	structure
compound 1-5-2	
compound 1-5-3	
compound 1-5-4	

TABLE 1-5-continued

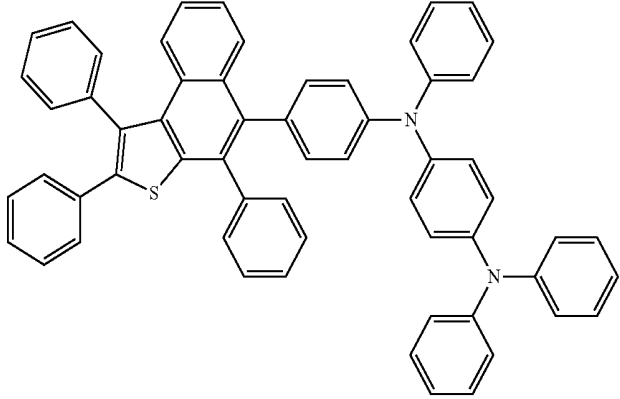
Product	structure
1-5-No	
compound 1-5-5	

TABLE 1-6

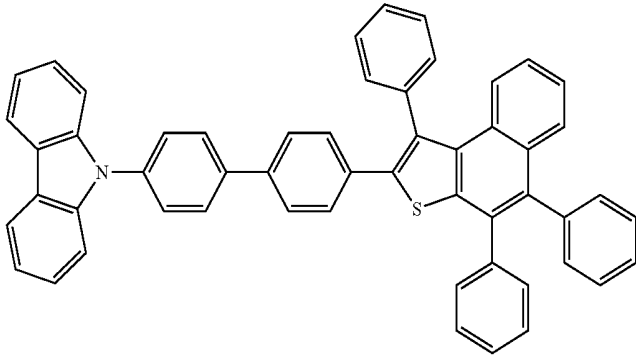
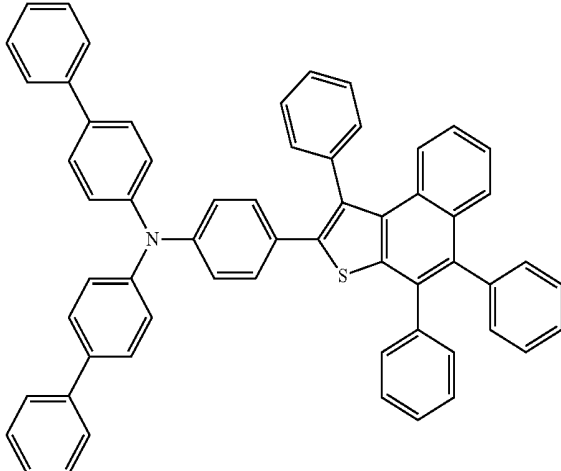
Product	structure
1-6-No	
compound 1-6-1	
compound 1-6-2	

TABLE 1-6-continued

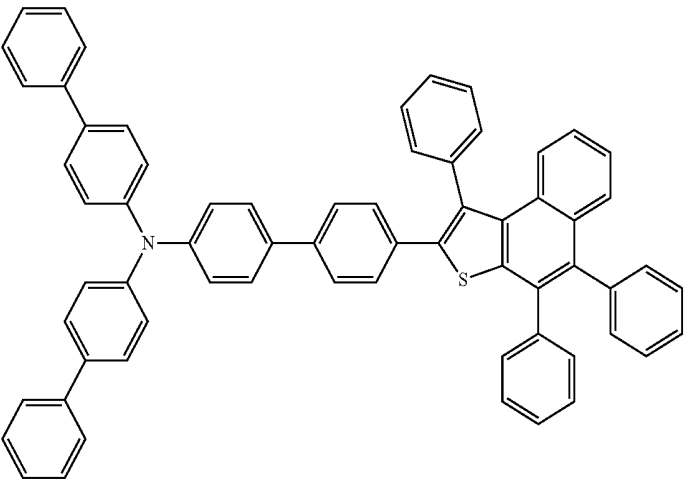
Product 1-6-No	structure
compound 1-6-3	

TABLE 1-7

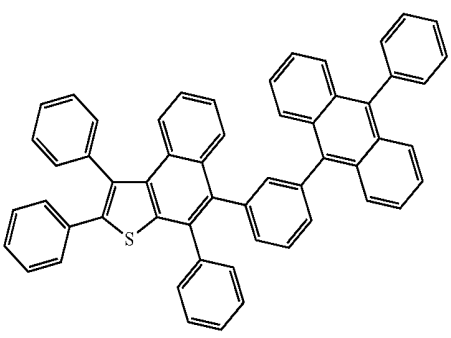
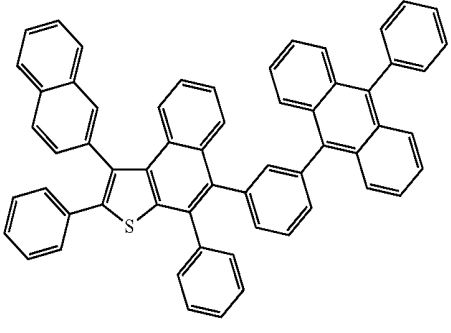
Product 1-7-No	structure
compound 1-7-1	
compound 1-7-2	

TABLE 1-7-continued

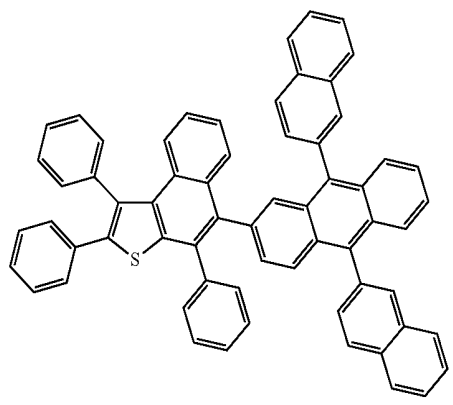
Product 1-7-No	structure
compound 1-7-3	

TABLE 2-1

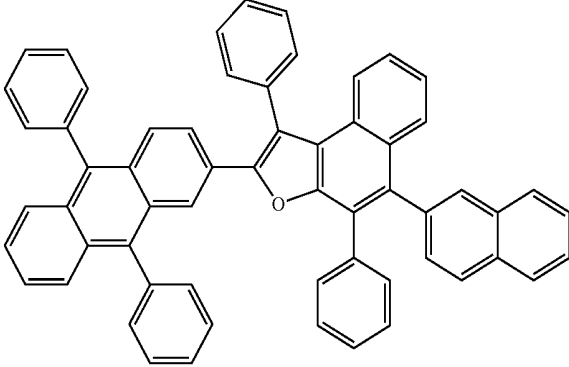
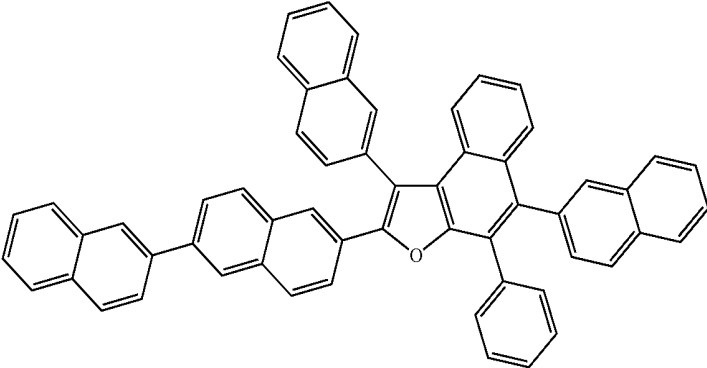
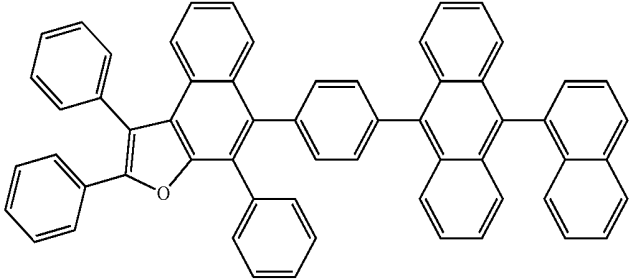
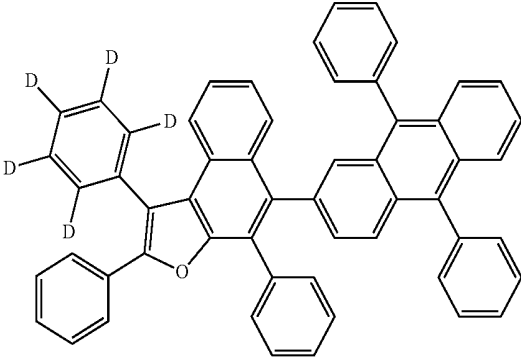
Product	structure
compound 2-1-1	
compound 2-1-2	
compound 2-1-3	
compound 2-1-4	

TABLE 2-1-continued

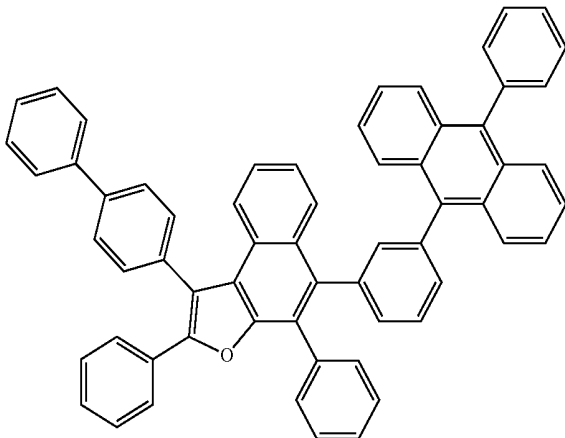
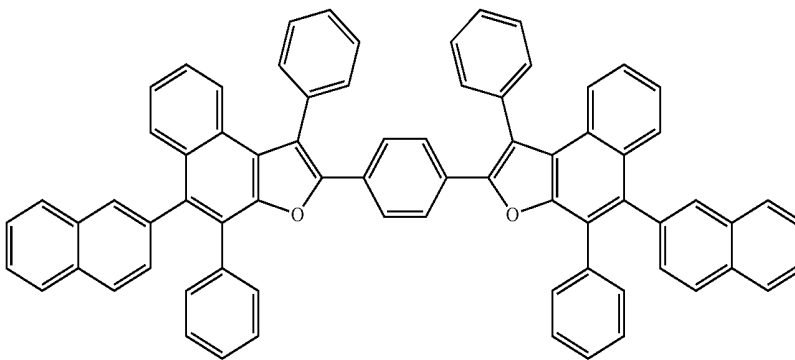
Product	
2-1-No	structure
compound 2-1-5	
compound 2-1-6	

TABLE 3-1

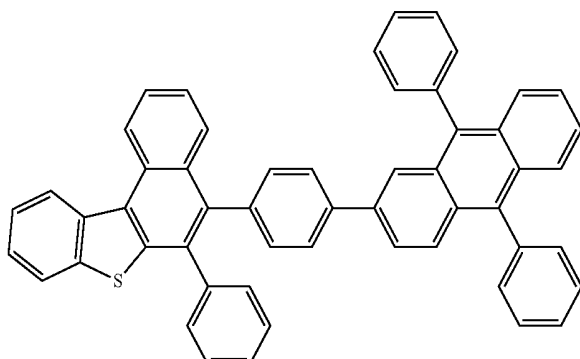
Product	
3-1-No	structure
compound 3-1-1	

TABLE 3-1-continued

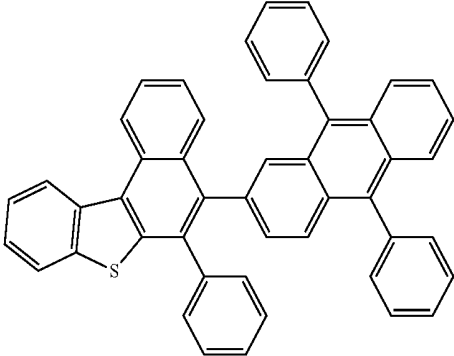
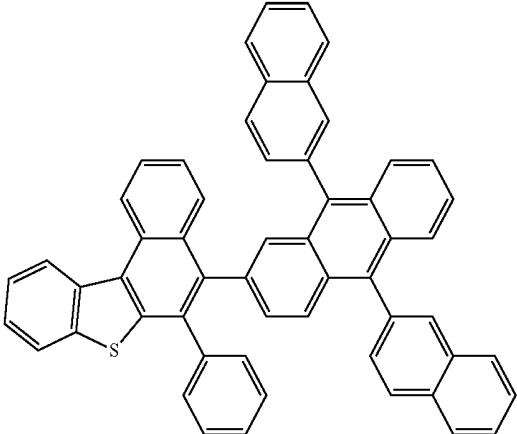
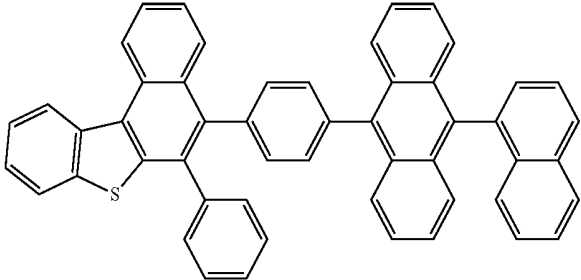
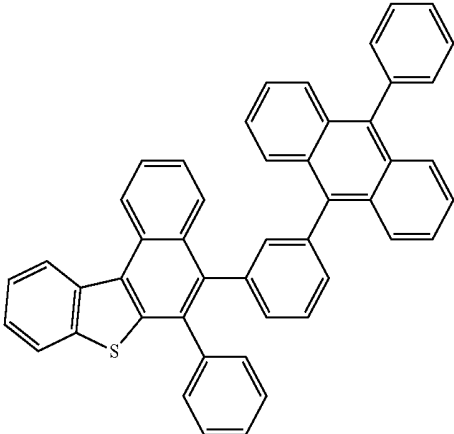
Product 3-1-No	structure
compound 3-1-2	
compound 3-1-3	
compound 3-1-4	
compound 3-1-5	

TABLE 3-1-continued

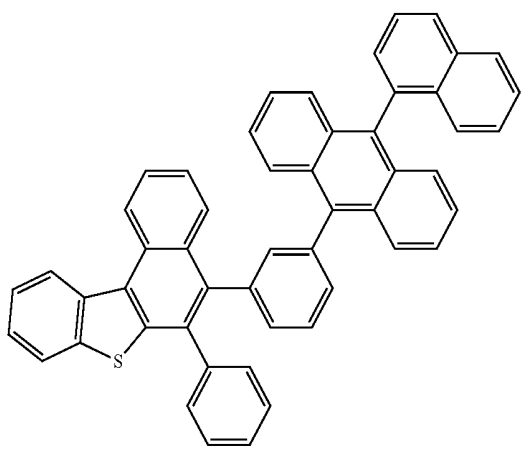
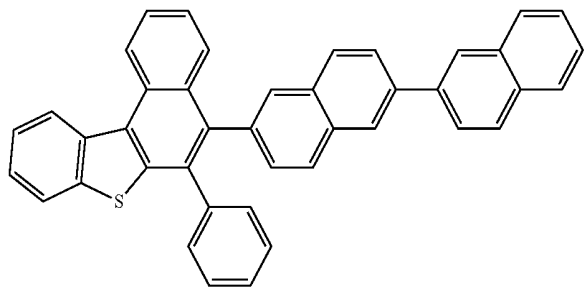
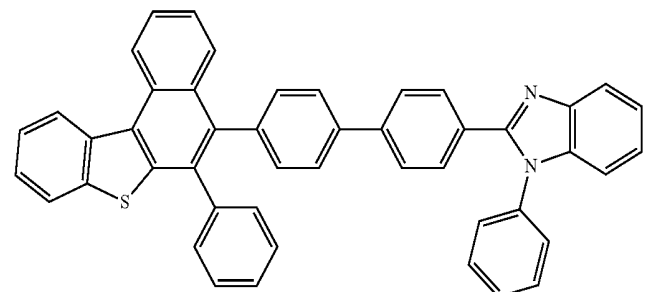
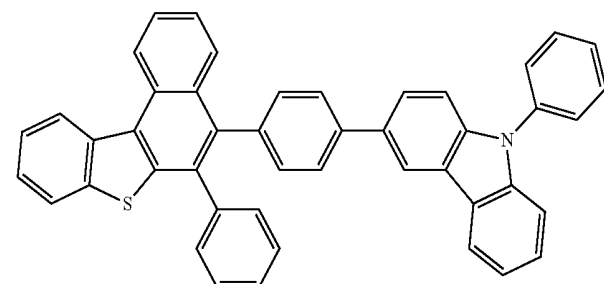
Product 3-1-No	structure
compound 3-1-6	
compound 3-1-7	
compound 3-1-8	
compound 3-1-9	

TABLE 3-1-continued

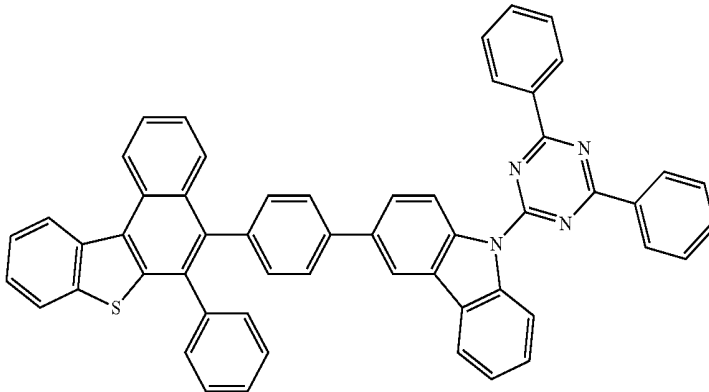
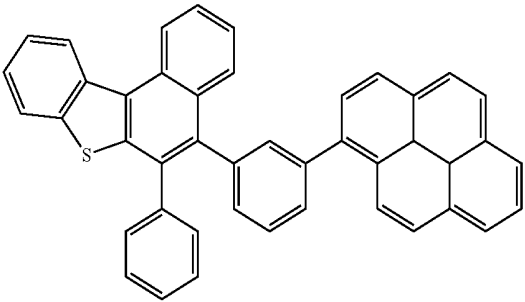
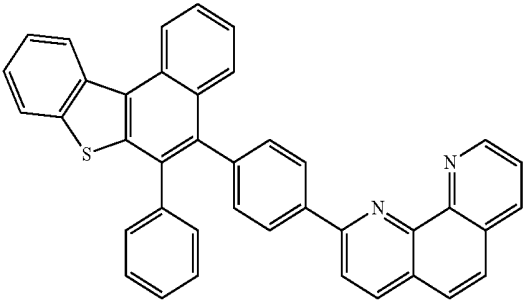
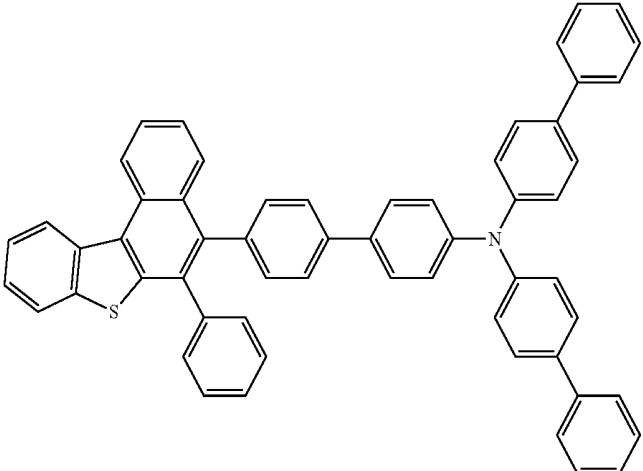
Product 3-1-No	structure
compound 3-1-10	
compound 3-1-11	
compound 3-1-12	
compound 3-1-13	

TABLE 3-1-continued

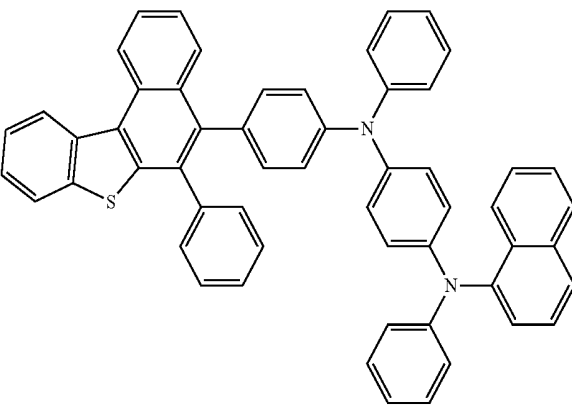
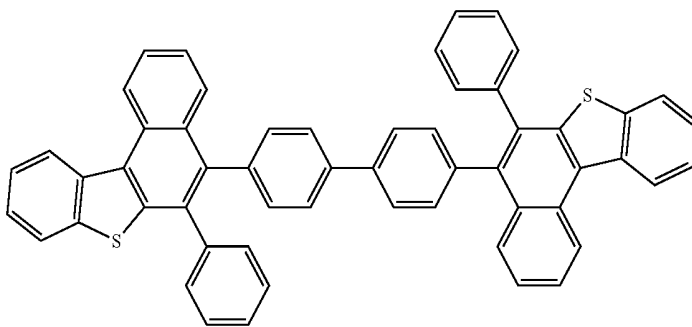
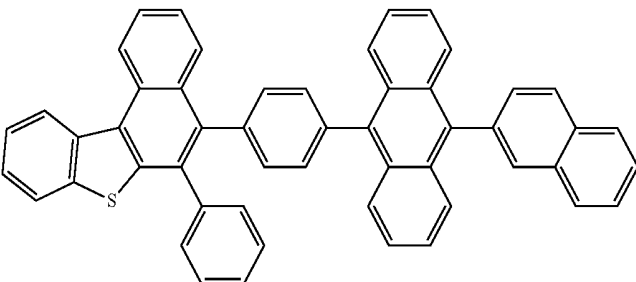
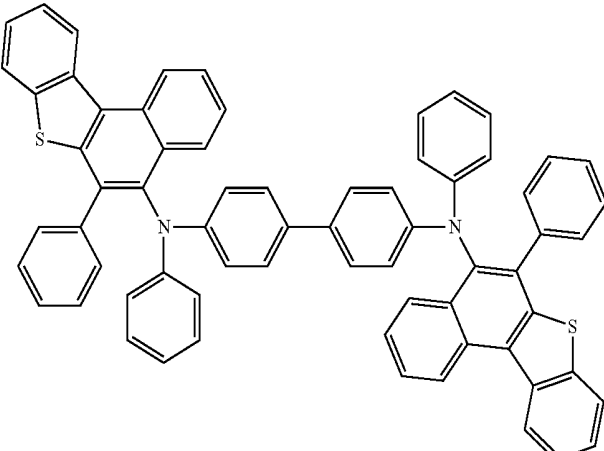
Product 3-1-No	structure
compound 3-1-14	
compound 3-1-15	
compound 3-1-16	
compound 3-1-17	

TABLE 3-1-continued

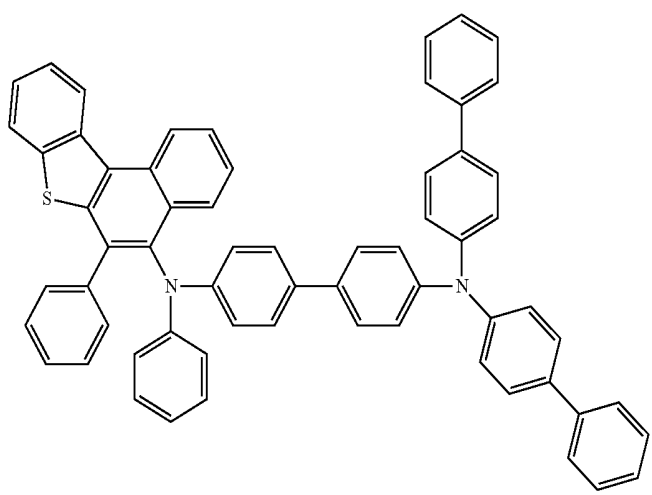
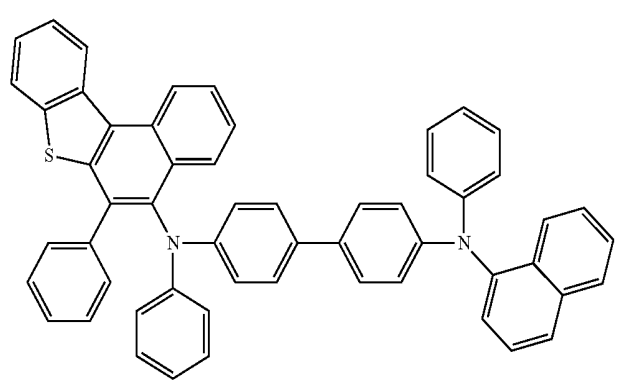
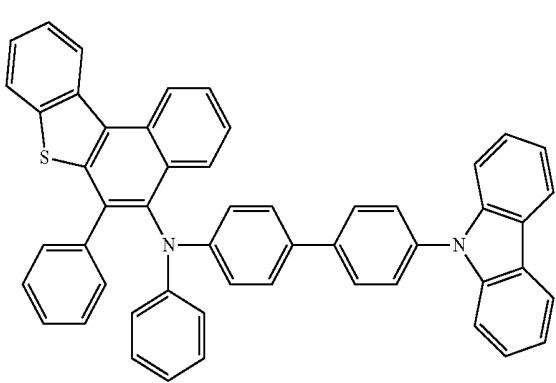
Product	structure
3-1-No	
compound 3-1-18	 <p>Chemical structure of compound 3-1-18: A central biphenyl core with two nitrogen atoms at the 4 and 4' positions. The left nitrogen is substituted with a phenyl group and a 2-phenylthiophen-5-yl group. The right nitrogen is substituted with a 4-phenylphenyl group and a 4-phenylphenyl group.</p>
compound 3-1-19	 <p>Chemical structure of compound 3-1-19: A central biphenyl core with two nitrogen atoms at the 4 and 4' positions. The left nitrogen is substituted with a phenyl group and a 2-phenylthiophen-5-yl group. The right nitrogen is substituted with a phenyl group and a fluorenyl group.</p>
compound 3-1-20	 <p>Chemical structure of compound 3-1-20: A central biphenyl core with two nitrogen atoms at the 4 and 4' positions. The left nitrogen is substituted with a phenyl group and a 2-phenylthiophen-5-yl group. The right nitrogen is substituted with a fluorenyl group and a fluorenyl group.</p>

TABLE 4-1

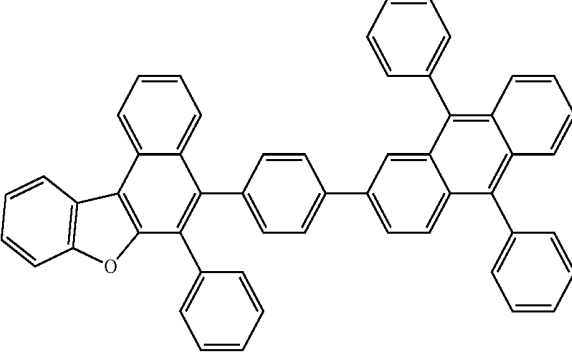
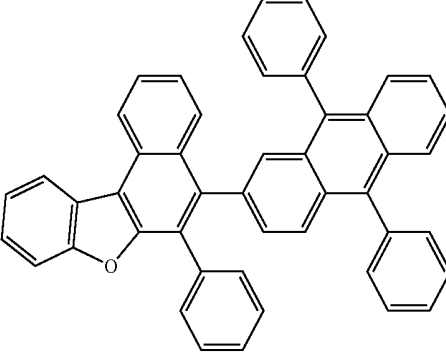
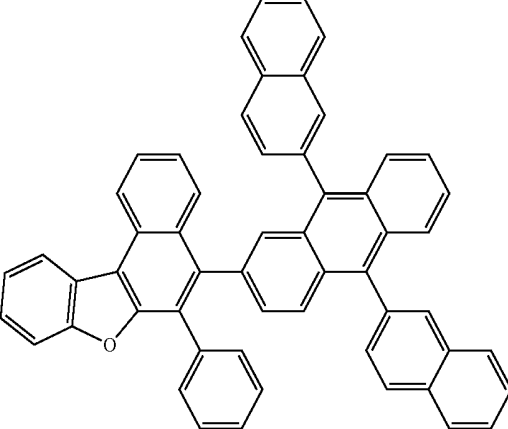
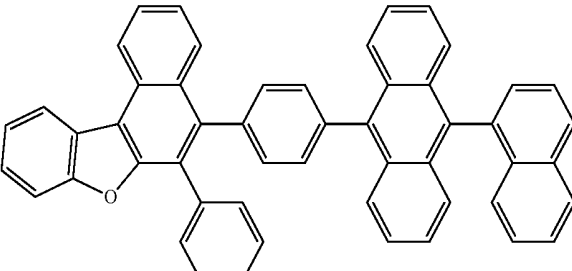
Product 4-1-No	structure
compound 4-1-1	
compound 4-1-2	
compound 4-1-3	
compound 4-1-4	

TABLE 4-1-continued

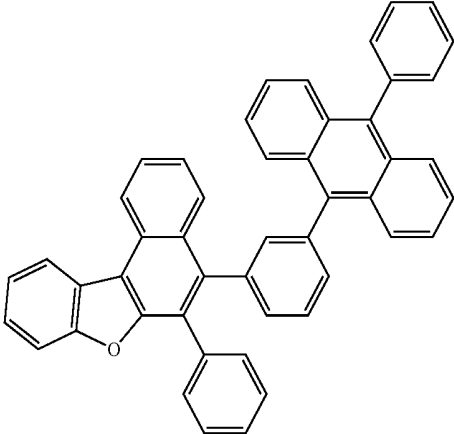
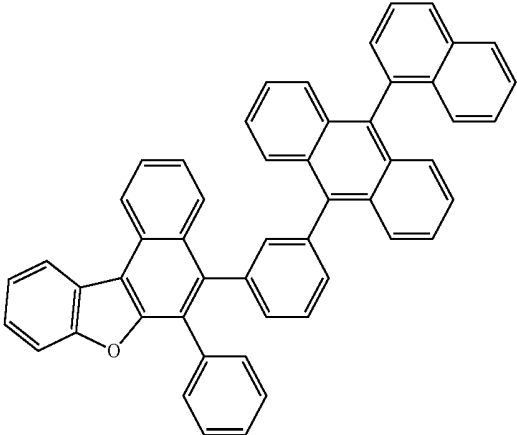
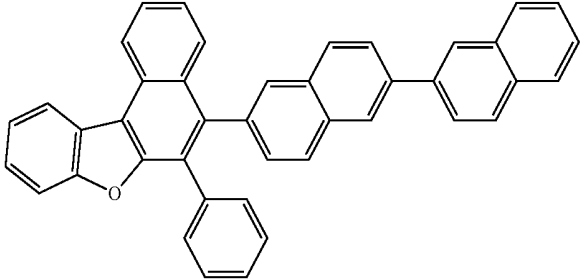
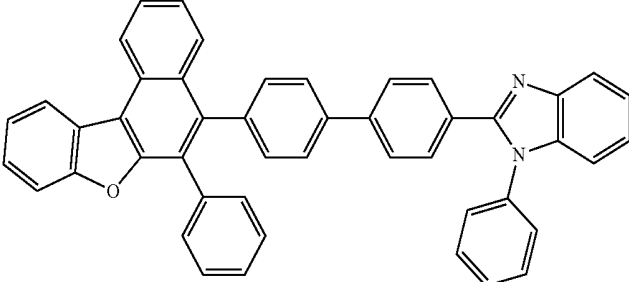
Product 4-1-No	structure
compound 4-1-5	
compound 4-1-6	
compound 4-1-7	
compound 4-1-8	

TABLE 4-1-continued

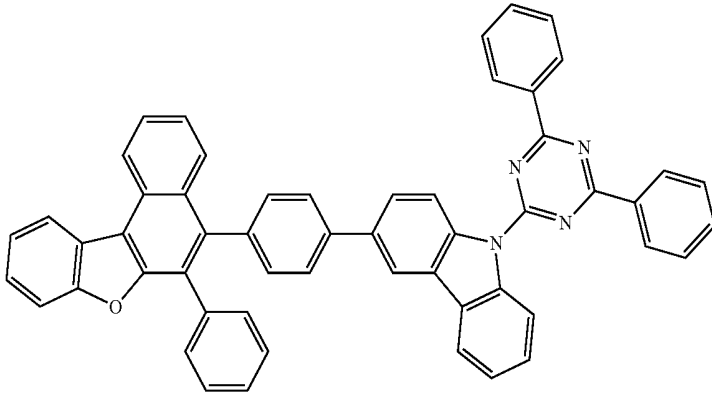
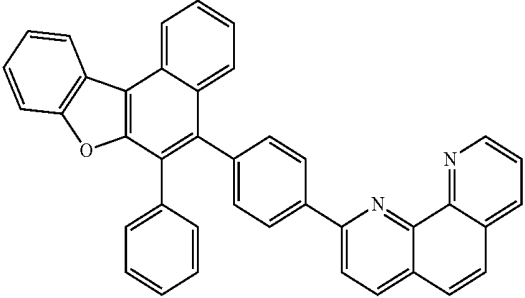
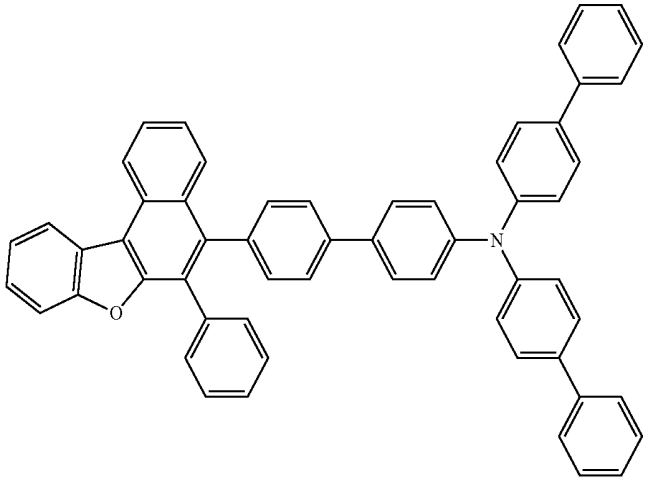
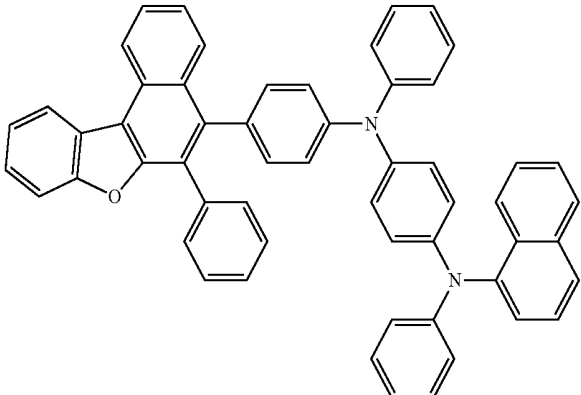
Product 4-1-No	structure
compound 4-1-9	
compound 4-1-	
compound 4-1-	
compound 4-1-	

TABLE 4-1-continued

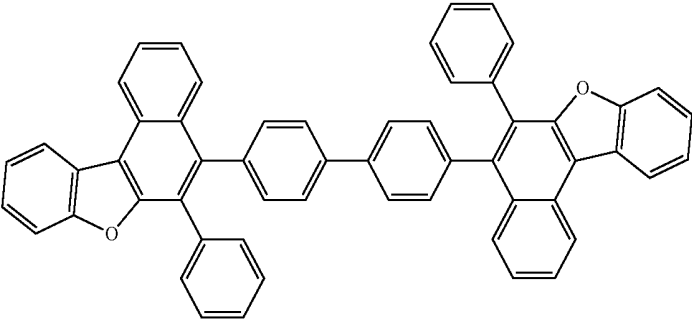
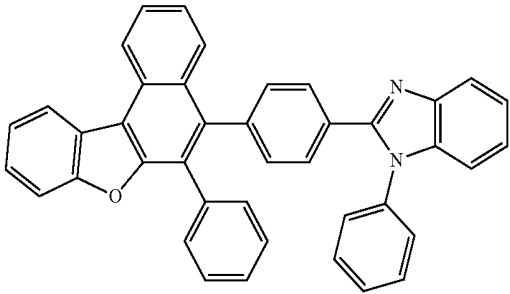
Product 4-1-No	structure
compound 4-1-	
compound 4-1-	

TABLE 5-1

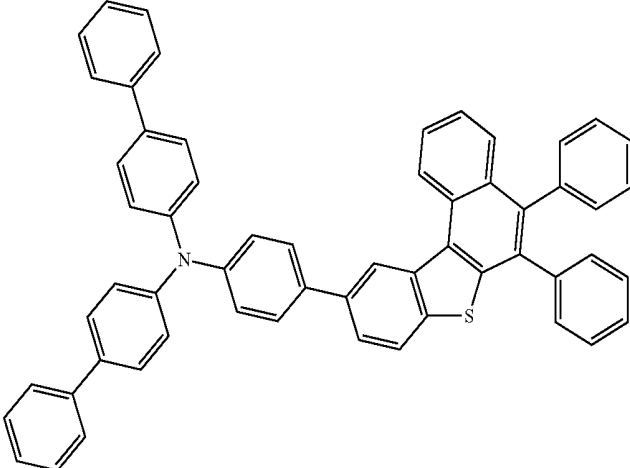
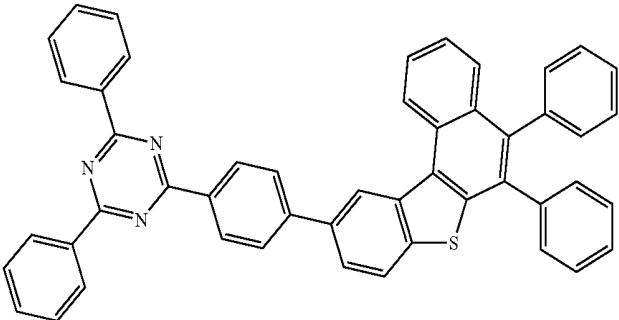
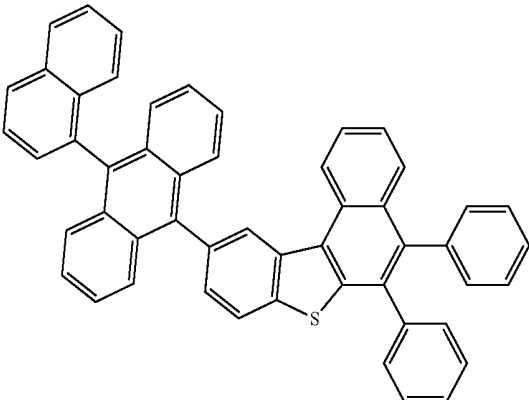
Product 5-1-No	structure
compound 5-1-1	

TABLE 5-1-continued

Product 5-1-No	structure
compound 5-1-2	
compound 5-1-3	

11. An organic electronic device which includes a first electrode, a second electrode, and one or more organic material layers that are disposed between the first electrode and the second electrode, wherein one or more layers of the organic material layers include the compound according to claim 1.

12. The organic electronic device as set forth in claim 11, wherein the organic material layer includes a hole injection layer or a hole transport layer, and the hole injection layer or hole transport layer includes the compound of Formula 1.

13. The organic electronic device as set forth in claim 12, wherein the hole injection layer or hole transport layer further includes a dopant material.

14. The organic electronic device as set forth in claim 11, wherein the organic material layer includes a light emitting layer, and the light emitting layer includes the compound of Formula 1.

15. The organic electronic device as set forth in claim 14, wherein the light emitting layer that includes the compound of Formula 1 further includes a fluorescent dopant material or phosphorescent dopant material.

16. The organic electronic device as set forth in claim 11, wherein the organic material layer includes an electron injection

layer or an electron transport layer, and the electron injection layer or electron transport layer includes the compound of Formula 1.

17. The organic electronic device as set forth in claim 16, wherein the electron injection layer or electron transport layer further includes a dopant material.

18. The organic electronic device as set forth in claim 11, wherein the organic electronic device is selected from the group consisting of an organic light emitting device, an organic solar cell, an organic photoconductor (OPC) drum and an organic transistor.

19. An organic device which includes a first electrode, a second electrode, and one or more organic material layers that are disposed between the first electrode and the second electrode, wherein one or more layers of the organic material layers include the compound according to claim 3.

20. An organic device which includes a first electrode, a second electrode, and one or more organic material layers that are disposed between the first electrode and the second electrode, wherein one or more layers of the organic material layers include the compound according to claim 10.

* * * * *

专利名称(译)	新型化合物，其制备方法和使用其的有机电子器件		
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[标]申请(专利权)人(译)	BAE JAE SOON 金姬EUN KIM JEUNG GON JANG JUN GI		
申请(专利权)人(译)	BAE JAE-SOON KIM JI-EUN KIM JEUNG-GON JANG JUN-GI		
当前申请(专利权)人(译)	LG化学有限公司.		
[标]发明人	BAE JAE SOON KIM JI EUN KIM JEUNG GON JANG JUN GI		
发明人	BAE, JAE-SOON KIM, JI-EUN KIM, JEUNG-GON JANG, JUN-GI		
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优先权	1020080093440 2008-09-23 KR		
其他公开文献	US9028977		
外部链接	Espacenet USPTO		

摘要(译)

本发明涉及一种新化合物，其制备方法以及使用该化合物的有机电子器件，并且根据本发明的新化合物可用作空穴注入，空穴传输，电子注入和传输，或者在有机发光器件和有机电子器件中的发光材料，根据本发明的器件在效率，驱动电压和稳定性方面显示出优异的性能。

